Supplemento ordinario alla "Gazzetta Ufficiale,, n. 81 dell'8 aprile 1997 - Serie generale

Spedizione in abbonamento postale (50%) - Roma

GAZZETTA UFFICIALE
DELLA REPUBBLICA ITALIANA

PARTE PRIMA **Roma - Martedì, 8 aprile 1997** SI PUBBLICA TUTTI I GIORNI NON FESTIVI

DIREZIONE E REDAZIONE PRESSO IL MINISTERO DI GRAZIA E GIUSTIZIA - UFFICIO PUBBLICAZIONE LEGGI E DECRETI - VIA ARENULA 70 - 00100 ROMA
AMMINISTRAZIONE PRESSO L'ISTITUTO POLIGRAFICO E ZECCA DELLO STATO - LIBRERIA DELLO STATO - PIAZZA G. VERDI 10 - 00100 ROMA - CENTRALINO 85081

N. 75

MINISTERO DELL'INDUSTRIA DEL COMMERCIO E DELL'ARTIGIANATO

CIRCOLARE 4 aprile 1997, n. 37877.

Legge 18 novembre 1995, n. 496, e successive modifiche. Ratifica della convenzione sulla proibizione delle armi chimiche fatta a Parigi il 13 gennaio 1993. Adempimenti connessi.

SOMMARIO

MINISTERO DELL'INDUSTRIA DEL COMMERCIO E DELL'ARTIGIANATO

CIRCOLARI

MINISTERO DELL'INDUSTRIA DEL COMMERCIO E DELL'ARTIGIANATO

CIRCOLARE 4 aprile 1997, n. 37877.

Legge 18 novembre 1995, n. 496, e successive modifiche. Ratifica della convenzione sulla proibizione delle armi chimiche fatta a Parigi il 13 gennaio 1993. Adempimenti connessi.

A tutti i Ministeri - Gabinetto
Alle camere di commercio
Alla Confindustria
Alla Confapi
Alle associazioni di categoria

La convenzione di Parigi sulla proibizione dello sviluppo, produzione, immagazzinaggio ed uso di armi chimiche e sulla loro distruzione pone a carico dei paesi firmatari numerosi ed onerosi adempimenti.

Il campo di applicazione della convenzione si estende, tra l'altro, ai composti ed ai prodotti chimici elencati nelle tabelle 1, 2, 3 allegate alla convenzione ed agli impianti descritti nella parte IX dell'allegato sulle verifiche della convenzione.

La legge n. 93 del 4 aprile 1997 introduce delle norme che prevedono il termine del 20 aprile quale data ultima per fornire al Ministero dell'industria le «Dichiarazioni iniziali».

Tali «Dichiarazioni iniziali», secondo la terminologia adottata dalla convenzione, devono contenere una serie di dati ed informazioni elencati nell'art. VI e nelle parti VI, VII, VIII e IX dell'allegato sulle verifiche della convenzione stessa.

Poiché la citata legge contempla pesanti sanzioni penali per chi omette di fornire o fornisce in modo non veritiero tali informazioni, questo Ministero ha ritenuto di dover offrire, agli operatori coinvolti, una utile guida di riferimento da compilare in conformità delle indicazioni fornite dal Segretariato tecnico dell'Organizzazione per la proibizione delle armi chimiche dell'Aja (Paesi Bassi).

Tanto premesso si riportano nell'allegato 1 i modelli da compilare, con l'avvertenza che essi dovranno essere spediti entro e non oltre il 20 aprile mediante raccomandata con avviso di ricevimento indirizzata a:

Ministero dell'industria del commercio e dell'artigianato
Direzione generale della produzione industriale
Via Molise, 2
00198 ROMA.

Per facilitare la compilazione dei modelli sono stati indicate nell'allegato 2 i composti chimici, completi di formula bruta, di numero CAS e di nome IUPAC, elencati sinteticamente nelle richiamate tabelle 1, 2, 3 allegate alla convenzione.

I modelli dovranno essere inviati in unica copia firmati in tutte le pagine dal legale rappresentante dell'azienda in caso di società o del titolare in caso di ditta individuale. Nel caso in cui la proprietà, sia in essa di persona giuridica o fisica, sia diversa dalla figura che gestisce l'azienda (caso ad esempio di affitto di azienda) il firmatario dovrà essere il gestore della stessa.

D'ordine del Ministro
Il capo di gabinetto: CINTI

ALLEGATO 1

M.I.C.A.

LINEE GUIDA

per

DICHIARAZIONI INIZIALI

relative a

COMPOSTI CHIMICI

Parte VI - VII - VIII - IX

dell' Annesso Verifiche della Convenzione

Legge 496 del 18/11/1995

Contenuto :

Cap. 1

DICHIARAZIONI

Classificazione Livello di confidenzialità

Su tutti i modelli va indicato il livello di confidenzialità dei dati.
A tal proposito vanno utilizzate 3 sigle : R, P o H.

R sta per confidenzialità ristretta e rappresenta il livello più basso;
P sta per confidenzialità protetta e rappresenta un livello medio;
H sta per altamente proptetto e rappresenta il livello di maggior riservatezza.

Pertanto, ogni dichiarante per ciascun modello allegato alla dichiarazione deve indicare uno dei tre livelli sopra riportati, in mancanza di una indicazione i dati del modello saranno classificati come non riservati.

1. DICHIARAZIONE ATTIVITA' IMPORT EXPORT RELATIVA A COMPOSTI DI TABELLA 2 e/o TABELLA 3

La dichiarazione va prodotta dalle societa' commerciali di import/export che abbiano trattato prodotti contenenti composti di tabella 2 e/o tabella 3 purche' la percentuale del composto interessato sia superiore al 15% e rientri come computo di massa totale complessiva annua, per ciascun Paese relativo a import o export, nelle soglie di obbligo per le dichiarazioni e fissate in :

a) **quantitativo annuo > 1 kg di un composto identificato da <*> , parte A, tab.2**
b) **quantitativo annuo > 100 kg di ogni altro composto di cui alla parte A, tab.2**
c) **quantitativo annuo > 1 ton di un composto di cui alla parte B, tab.2**
d) **quantitativo annuo > 30 tons di un composto di cui alla tab. 3**

Ogni dichiarazione deve contenere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/ie2 : dichiarazione per ogni composto di tabella 2**
- **mod. Mini/In/ie3 : dichiarazione per ogni composto di tabella 3**

2. DICHIARAZIONE PER SITI RELATIVI SOLO A COMPOSTI DI TABELLA 1

La dichiarazione va presentata, secondo quanto previsto ai paragrafi 8-9-10-11-12 della parte VI dell' Annesso Verifiche della Convenzione, dai seguenti soggetti :

a) Lo Stato Parte che gestisce , a fini di ricerca e/o medici e/o farmaceutici e/o di protezione (nella definizione data dalla Convenzione), un impianto unico a scala ridotta (impianto pilota) per la produzione di prodotti chimici di tabella 1 .

Il limite di produzione e' quello che non consente di superare, in qualunque momento, il quantitativo globale nazionale per tutti i composti chimici di tabella 1, prodotti e/o acquistati e/o conservati e/o trasferiti e/o utilizzati, fissato in 1 tonnellata.

b) Chi produce, a fini di difesa/protezione, in un solo impianto, diverso dall' impianto unico a scala ridotta di cui al punto precedente A , una quantita' globale annua di composti chimici di tabella 1 non superiore a 10 kg.

c) Chi produce, a fini di ricerca e/o medici e/o farmaceutici, composti chimici di tabella 1 in impianti diversi da quelli unici a scala ridotta di cui al precedente punto A.

La dichiarazione va resa per produzioni comprese , per singolo impianto, tra 100 g e 10 kg.

d) Chi effettua in laboratorio la sintesi chimica dei composti chimici di tabella 1 in quantita' globali non superiore a 100 g annui , per impianto, **non deve effettuare alcuna dichiarazione** purche' i fini siano quelli di ricerca e/o medici e/o farmaceutici e non quelli di protezione , caso questo che comporterebbe comunque la dichiarazione.

Informazioni dettagliate sulla compilazione dei modelli predisposti sono disponibili presso gli Uffici su richiesta degli interessati.

3. DICHIARAZIONE PER SITI RELATIVI SOLO A COMPOSTI DI TABELLA 2

La dichiarazione va fatta per tutti i siti produttivi che hanno prodotto, lavorato o consumato, per uno qualsiasi degli anni 1994, 1995, 1996 :

a) **quantitativo annuo > 1 kg di un composto identificato da <*> , parte A, tab.2**
b) **quantitativo annuo > 100 kg di ogni altro composto di cui alla parte A, tab.2**
c) **quantitativo annuo > 1 ton di un composto di cui alla parte B, tab.2**

Ogni dichiarazione deve comprendere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/sp : dichiarazione sito produttivo**
  (Se il dichiarante ha piu' siti produttivi da dichiarare deve presentare un modello Mini/In/sp per ogni sito)
- **mod. Mini/In/imp : dichiarazione relativa agli impianti**
  (Se in un sito ci sono piu' impianti da assoggettare a dichiarazione, per ognuno di essi va fatta una dichiarazione utilizzando un modello Mini/In/imp.
  Per piu' siti dichiarati vanno utilizzati tanti moduli Mini/In/imp per quanti sono i singoli impianti da dichiarare)
- **mod. Mini/In/comp2 : dichiarazione relativa ai composti di tab. 2**
  (Va utilizzato un modulo per ogni composto da dichiarare)

3.1. **Dichiarazione dati identificativi dichiarante** (modello di riferimento : **Mini/In**)

Per dichiarazioni inerenti a più di un composto chimico e/o piu' impianti e/o piu' siti produttivi , purche' relative allo stesso dichiarante, è sufficiente un solo modello.

3.2. **Dichiarazione del sito produttivo** (modello di riferimento : **Mini/In/sp**)

Il modello è suddiviso in due parti :

- dati identificativi
- ripartizione degli impianti del sito per tipologia di composti dichiarati

3.2.1. Tra i dati identificativi figura quello relativo alle coordinate geografiche espresse come latitudine e longitudine. In alternativa e' possibile specificare estremi topografici atti a definire con precisione l' esatta ubicazione del sito.

3.2.2. Per quanto riguarda la tabella di ripartizione degli impianti del sito, la stessa va compilata riportando, per ciascuna tipologia di composto interessante la dichiarazione, il numero di impianti compresi nel sito (per la definizione di "impianto" vedi cap.2 della presente guida).
E' evidente che l' eventuale indicazione di piu composti appartenenti a tabelle diverse configura il sito come "sito produttivo misto", secondo la definizione data al cap. 2.

3.3. **Dichiarazione relativa agli impianti** (modello di riferimento : **Mini/In/imp**)

Il modello è suddiviso in tre parti :

- dati identificativi
- dati relativi all' attività dell' impianto
- capacita' produttiva per singolo composto dichiarato

3.3.1. Tra i dati identificativi, al punto "ubicazione nel sito" figurano due sottovoci :

- struttura n.
- edificio n.

Per struttura si intende il numero identificativo dell' unita' impiantistica individuabile nel sito e relativa alla dichiarazione (esempio tipico e' quello di siti petrolchimici dove e' in uso tale identificazione per le subunita' produttive).

La sottovoce "edificio" ha lo stesso significato logistico del termine "struttura" , individua cioè una unita' produttiva autosufficiente (definita appunto "impianto" per la Convenzione, secondo quanto al cap.2 della presente guida) che risulta pero' dimensionata e confinata in una vera e propria struttura edilizia.

3.3.2. Per quanto riguarda la tabella di riporto dei "dati relativi all' attività dell' impianto, essa riporta 5 voci che significano:

3.3.2.1. *codice attivita' principale*
E' un codice compreso tra B01 e B06 (vedi capitolo 4, appendice n.3) che individua l' attività principale dell' impianto, indipendentemente dal composto considerato ai fini della dichiarazione.
Le attivita' codificate sono :

- B01 = produzione
- B02 = lavorazione
- B03 = trasformazione
- B04 = stoccagggio
- B05 = riconfezionamento/distribuzione
- B06 = R&D

Esse sono state elaborate tenendo in conto una attività industriale chimica, cioe' volta a trattare composti chimici.
In tutti quei casi di attività industriali non strettamente configurabili come chimiche ma comunque interessate alla dichiarazione di legge, i suddetti codici , se non associabili direttamente all' attività propria dell' impianto considerato, vanno riferiti alla finalità di uso (impiego) che , nell' ambito dell' impianto stesso, subisce il composto oggetto della dichiarazione.

3.3.2.2. *codice gruppo prodotti*
Questo codice individua, nell' ambito di una tabella già predisposta (vedi capitolo 4, appendice n.4), il gruppo di prodotti uguali o assimilabili a quelli trattati nell' impianto dichiarato ed oggetto dell' attività principale dello stesso.
Nel caso di attività industriali non propriamente chimiche ma comunque assoggettate alla dichiarazione di legge per l' impiego di composti sotto disciplina, la scelta del codice va fatta in relazione alla natura chimica di quest' ultimi.

3.3.2.3. *codice attività dell' impianto inerente i composti dichiarati*
Vale quanto già detto per la voce *codice attività principale* con la differenza che in questo caso l' attività va riferita al composto chimico sotto dichiarazione.

3.3.2.4. *altre attività dell 'impianto attinenti il composto dichiarato*
Queste attività riguardano :

- stoccaggio
- riconfezionamento
- ricerca e sviluppo

A tal fine se individuate vanno codificate utilizzando rispettivamente i codici B04, B05 e B06 gia' utilizzati alla voce *codice attività principale*

3.3.2.5. *carattere dell' attività dell' impianto relativamente ai composti dichiarati*
Per questa voce va barrato uno dei due termini :
esclusivo
polivalente

Il termine *esclusivo* va utilizzato solo se l' attività dell' impianto e' rivolta esclusivamente ai composti dichiarati, viceversa va specificato nella casella il termine *polivalente*.

3.3.3. Nella terza tabella, relativa a "Capacita' produttiva per singolo composto dichiarato", va indicata, per ogni singolo composto dichiarato e riferito all' impianto in oggetto, la quàntita' annuale producibile (secondo il significato attribuito al cap.2 della presente guida) .

3.4. **Dichiarazione composti chimici di tabella 2** (modello di riferimento : **Mini/In/comp2)**

La dichiarazione consta di due parti :

- dati identificativi
- dati per attività pregressa

3.4.1. I dati identificativi riguardano il nome IUPAC, il nome commerciale o utilizzato all' interno del sito produttivo, la formula di struttura ed il numero del registro CAS.

3.4.2. Per quanto attiene i "dati per attività pregressa" si tratta di riportare per ogni composto dichiarato, e per ogni specifica attività dell' impianto ad esso associato, le quantità trattate nel sito produttivo per ciascuno dei tre anni civili precedenti a quello della dichiarazione .
Trattandosi di dati espressi per sito produttivo e' evidente che se in un sito vi sono piu' impianti (come definiti dalla Convenzione e di cui al cap. 2 della presente guida) che hanno trattato il composto dichiarato in questione, le quantità da indicare nel presente modulo sono , per singola specifica attività indicata, la somma delle quantità trattate nei singoli impianti.

Per ogni anno va anche specificato lo scopo per il quale il composto in oggetto e' stato prodotto, lavorato e/o consumato.
A tal proposito utilizzare i codici già predisposti (vedi appendice n.3)

4. DICHIARAZIONE PER SITI RELATIVI SOLO A COMPOSTI DI TABELLA 3

La dichiarazione va fatta per tutti i siti produttivi che hanno prodotto per l' anno civile precedente l' entrata in vigore della Convenzione :

a) **quantitativo annuo > 30 tons di un composto di cui alla tab. 3**

Ogni dichiarazione deve comprendere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/sp : dichiarazione sito produttivo**
  (Se il dichiarante ha piu' siti produttivi da dichiarare deve presentare un modello Mini/In/sp per ogni sito)
- **mod. Mini/In/imp : dichiarazione relativa agli impianti**
  (Se in un sito ci sono piu' impianti da assoggettare a dichiarazione, per ognuno di essi va fatta una dichiarazione utilizzando un modello Mini/In/imp.
  Per piu' siti dichiarati vanno utilizzati tanti moduli Mini/In/imp per quanti sono i singoli impianti da dichiarare)
- **mod. Mini/In/comp3 : dichiarazione relativa ai composti di tab. 3**
  (Va utilizzato un modulo per ogni composto da dichiarare)

4.1. **Dichiarazione dati identificativi dichiarante** (modello di riferimento : **Mini/In)**

Vale quanto detto al punto 3.1

4.2. **Dichiarazione del sito produttivo** (modello di riferimento : **Mini/In/sp)**

Il modello e' identico a quello per i composti di tab. 2 e di cui al punto 3.2 , pertanto valgono le stesse indicazioni .

4.3. **Dichiarazione relativa agli impianti** (nodello di riferimento : **Mini/In/imp)**
Il modello e' identico a quello per i composti di tab. 2 e di cui al punto 3.3 , pertanto valgono le stesse indicazioni , fatta eccezione per i campi 3 - 4 - 5 dei "Dati relativi all' attivita' dell' impianto" ed a tutti quelli relativi alla "Capacita' produttiva per singolo composto dichiarato" che non vanno riempiti per le dichiarazioni inerenti ai composti di tabella 3 .

4.4. **Dichiarazione relativa ai composti di tabella 3** (modello di riferimento **Mini/In/comp3)**

La dichiarazione consta di due parti :

- dati identificativi
- dati per attività pregressa

4.4.1. I dati identificativi riguardano il nome IUPAC, il nome commerciale o utilizzato all' interno del sito produttivo, la formula di struttura ed il numero del registro CAS.

4.4.2. Per quanto attiene i "dati per attività pregressa" si tratta di riportare per ogni composto dichiarato, e per ogni specifica attività dell' impianto ad esso associato, le quantità trattate nel sito produttivo per l' anno civile precedente a quello della dichiarazione.

Trattandosi di dati espressi per sito produttivo e' evidente che se in un sito vi sono piu' impianti (come definiti dalla Convenzione e di cui al cap. 2 della presente guida) che hanno trattato il composto dichiarato in questione, le quantità da indicare nel presente modulo sono , per singola specifica attività indicata, la somma delle quantità trattate nei singoli impianti.

Per ogni anno va anche specificato lo scopo per il quale il composto in oggetto e' stato prodotto.
A tal proposito utilizzare i codici già predisposti (vedi capitolo 4, appendice n. 5).

5. DICHIARAZIONI PER SITI RELATIVI SOLO A COMPOSTI DOC ED PSF

La dichiarazione va fatta per tutti i siti produttivi che hanno prodotto, tramite sintesi chimica, per l' anno civile precedente l' entrata in vigore della Convenzione, :

a) **quantitativo annuo > 200 tons complessivi x sito produttivo di composti organici classificati come DOC**
b) **quantitativo annuo > 30 tons di un singolo composto chimico organico classificato come PSF**

Nel calcolare la quantità globale approssimata di DOC in un sito industriale, i dati di produzione devono essere aggregati in modo da includere :

a) in caso di produzione di due o più DOC nello stesso impianto, i dati aggregati di tutti i prodotti;
b) in caso di processi "multiple step", solo la quantità del prodotto finale a condizione che sia un DOC, o la quantità dell' ultimo intermedio della sintesi " multiple step" che sia compreso nella definizione di DOC;
c) in caso di intermedi compresi nella definizione di DOC e usati da un altro impianto del sito industriale per produrre composti chimici organici definiti non ripresi nelle Tabelle, sia la quantità dell' intermedio sia quella del prodotto finito devono essere prese in considerazione.

Ogni dichiarazione deve comprendere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/sp : dichiarazione sito produttivo**
- **mod. Mini/In/sp/notab : dichiarazione sui dati di produzione**
  (Se il dichiarante ha piu' siti produttivi da dichiarare deve presentare un modello Mini/In/sp/notab per ogni sito)

5.1. **Dichiarazione dati identificativi dichiarante** (modello di riferimento : **Mini/In**)

Vale quanto detto al punto 3.1

5.2. **Dichiarazione sito produttivo** (modello di riferimento : **Mini /In/sp**)

Vale quanto già detto al punto 3.2

5.3. **Dichiarazione sito produttivo** (modello di riferimento : **Mini/In/sp/notab)**

I dati da inserire nel modello sono tutti definiti con chiarezza per cui non necessitano di particolari spiegazioni.

6. DICHIARAZIONI PER SITI RELATIVI A PRODUZIONI PREGRESSE, AVVENUTE DOPO IL 01.01.1946 DI COMPOSTI DI TABELLA 2 DESTINATI AD UTILIZZI PER ARMI CHIMICHE

La dichiarazione va presentata per quei siti dove dopo il 1.1.1946, in un qualunque momento, sono stati prodotti composti di tabella 2 utilizzati per armi chimiche.

Ogni dichiarazione deve comprendere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/sp/excw : dichiarazione sito produttivo**
  (Se il dichiarante ha piu' siti produttivi da dichiarare deve presentare un modello Mini/In/sp/excw per ogni sito)

- **mod. Mini/In/imp/excw : dichiarazione relativa agli impianti**
  (Se in un sito ci sono piu' impianti da assoggettare a dichiarazione, per ognuno di essi va fatta una dichiarazione utilizzando un modello Mini/In/imp/excw.
  Per piu' siti dichiarati vanno utilizzati tanti moduli Mini/In/imp/excw per quanti sono i singoli impianti da dichiarare)
- **mod. Mini/In/comp2/excw : dichiarazione relativa ai composti di tab. 2**
  (Va utilizzato un modulo per ogni composto da dichiarare)

I modelli sono simili a quelli utilizzabili per dichiarazioni di siti relativi a composti di tabella 2 . Pertanto valgono le indicazioni gia' riportate al punto 3.

DICHIARAZIONI PER SITI RELATIVI A PRODUZIONI PREGRESSE, AVVENUTE DOPO IL 01.01.1946 DI COMPOSTI DI TABELLA 3 DESTINATI AD UTILIZZI PER ARMI CHIMICHE

La dichiarazione va presentata per quei siti dove dopo il 1.1.1946, in un qualunque momento, sono stati prodotti composti di tabella 3 utilizzati per armi chimiche.

Ogni dichiarazione deve comprendere :

- **mod. Mini/In : dichiarazione dati identificativi del dichiarante**
- **mod. Mini/In/sp/excw : dichiarazione sito produttivo**
  (Se il dichiarante ha piu' siti produttivi da dichiarare deve presentare un modello Mini/In/sp/excw per ogni sito)
- **mod. Mini/In/imp/excw : dichiarazione relativa agli impianti**
  (Se in un sito ci sono piu' impianti da assoggettare a dichiarazione, per ognuno di essi va fatta una dichiarazione utilizzando un modello Mini/In/imp/excw.
  Per piu' siti dichiarati vanno utilizzati tanti moduli Mini/In/imp/excw per quanti sono i singoli impianti da dichiarare)
- **mod. Mini/In/comp3/excw : dichiarazione relativa ai composti di tab. 3**
  (Va utilizzato un modulo per ogni composto da dichiarare)

I modelli sono simili a quelli utilizzabili per dichiarazioni di siti relativi a composti di tabella 3 . Pertanto valgono le indicazioni gia' riportate al punto 4

DICHIARAZIONI DI SITI MISTI

Le dichiarazioni per siti misti saranno organizzate prevedendo l' utilizzo dei modelli previsti per le dichiarazioni gia' illustrate ai punti precedenti .
Per dichiarazioni riguardanti uno stesso sito e' possibile utilizzare:

- un solo modello Mini/In/sp per dichiarazioni riguardanti composti di tabella 2 e tabella 3;
- un solo modello Mini/In/sp/excw per dichiarazioni riguardanti composti di tabella 2 e tabella 3 di produzioni pregresse per armi chimiche;

mentre va utilizzato il corrispondente modello per ogni singolo impianto e composto del sito assoggettato alla dichiarazione.

Cap. 2

DEFINIZIONI

Produzione
Per produzione di un composto chimico si intende la sua formazione attraverso una o più reazioni chimiche.

Lavorazione
Per lavorazione di un composto chimico si intende un processo fisico, come formulazione, estrazione, e purificazione, in cui un composto chimico non viene trasformato in un altro composto chimico.

Consumo
Per consumo di un composto chimico s' intende la sua trasformazione in un altro composto chimico attraverso una reazione chimica.

Importazione
Per importazione si intende l' acquisto di composti chimici da Paesi non facente parte della Convenzione.

Esportazione
Per esportazione si intende la vendita di composti chimici verso Paese non facenti parte della Convenzione.

Trasferimento
Per trasferimento si intende l' acquisto e vendita di composti chimici da/a Stati Parte della Convenzione.

Precursore
E' definito cosi' qualunque reagente chimico che prende parte ad una fase nella produzione con qualunque metodo di un composto chimico tossico.
E' incluso qualunque componente chiave di un sistema chimico binario o a multicomponente

DOC
Si definisce composto chimico organico (DOC) qualunque composto chimico appartenente alla classe dei composti del carbonio con l' esclusione degli ossidi, solfuri e carbonati metallici ed identificabile da un nome chimico, da una formula di struttura e dal numero CAS, se assegnato.
Non rientrano nella definizione i composti costituiti da solo carbonio ed idrogeno (idrocarburi) e gli esplosivi.

PSF
Sono tutti i composti DOC che contengono uno o più elementi quali : fosforo, zolfo, fluoro.

Sito produttivo
E' definito come complesso d' impianti (fabbriche, stabilimenti) cioè l' integrazione locale di uno o piu impianti sotto un unico controllo operativo e comprendente, ad un livello amministrativo intermedio, infrastrutture comuni quali :

- l' amministrazione ed altri uffici;
- officine di manutenzione e di riparazione;
- centro di assistenza medica;
- servizi;
- laboratorio centrale di analisi;
- laboratori di R&D;
- area centrale per il trattamento degli effluenti e dei rifiuti;
- magazzini di stoccaggio.

Siti produttivi misti
Sono quelli che contengono :

- uno o piu impianti che sono individualmente riferiti a più di una parte dell' Annesso delle Verifiche della Convenzione e di cui all' art. VI della stessa;
- impianti differenti riferiti a parti differenti dell' Annesso delle Verifiche della Convenzione e di cui all' art.VI della stessa.

Impianto
Per impianto (impianto di produzione, laboratorio) si intende un ' area, struttura o edificio, relativamente autonomi, che contengono una o più unità con infrastrutture ausiliarie o associate come :

- ridotta sezione amministrativa;
- aree di immagazzinaggio e/o manipolazione materie prime e prodotti,
- area di trattamento/manipolazione degli effluenti e rifiuti;
- laboratorio di controllo/analisi;
- servizio di pronto soccorso/seziona medica relativa;
- documentazione relativa ai movimenti nel sito di prodotti ad esso relativo.

Impianti misti
Sono gli impianti che sono individualmente riferiti a più di una parte dell' Annesso delle Verifiche della Convenzione e di cui all' art. VI della stessa.
Il termine vale anche per gli impianti polivalenti che producono, nello stesso processo ma in punti differenti o in momenti diversi, composti classificabili in tabella 2 e tabella 3.
Comunque, il termine non si applica al caso di un impianto che produce un composto classificato in tabella 3 attraverso una reazione multi-step che riguardi la produzione di un composto DOC nella fase iniziale.
Allo stesso modo non si applica al caso in cui, durante la produzione di un composto classificabile in tabella 3, viene simultaneamente prodotta una bassa concentrazione di un composto classificabile in tabella 2 (in questo caso sarebbe classificato come impianto per composti in tab. 3 o tab. 2 a secondo delle regole applicate per basse concentrazioni).

Impianto a scala ridotta (SSSF)
E' definito cosi' un impianto unico pilota per la produzione di composti chimici di tabella 1 in quantita' annua superiore a 10 kg.

Impianto unico per scopi di difesa
E' definito cosi' un impianto unico, distinto da quello definito SSSF (nel senso che puo' non essere un impianto pilota cioe' a carattere discontinuo e di caratteristiche tecnico-costruttive limitative), per la produzione di composti chimici di tabella 1 per quantita' annue globali non superiore a 10 kg.

Scopi di difesa/protezione
Si definisce scopo di difesa quello direttamente relativo alla protezione contro sostanze chimiche tossiche e per la protezione contro armi chimiche.

Capacità di produzione di un impianto
E' definita come il quantitativo annuo potenzialmente producibile di un composto chimico sulla base del processo tecnologico attualmente usato o, se il processo non è ancora operativo, programmato per essere usato in un adeguato impianto di produzione.
La capacità produttiva può essere effettiva (da target) o teorica. E' effettiva quando e' assunta uguale a quella massima di target dell' impianto a regime nelle condizioni reali di ottimizzazione verificata su "corse" di prova ; viceversa in assenza di tale dato sara' assunta come capacita' produttiva quella teorica da progetto (design).

Quantità
Per quantità di un composto si intende la quantità reale.
Se i prodotti contengono meno del 100% del composto chimico, va dichiarata la quantità dello stesso (o la sua %) nel prodotto.

Tabella 1
La tabella 1 riguarda i composti chimici che hanno uso civile estremamente limitato e che sono considerati ad altissimo rischio in quanto possono essere utilizzati come armi chimiche o come precursori di armi chimiche.
Alcuni dei composti in essa elencati possono avere uso lecito, su piccola scala e per piccole quantità, nel settore farmaceutico, medico o della ricerca.

Tabella 2
La tabella 2 riguarda composti chimici che hanno un basso e medio uso industriale/commerciale e che sono considerati ad alto rischio in quanto possono essere usati come armi chimiche o come precursori di armi chimiche.

Tabella 3
La tabella 3 riguarda i composti chimici che hanno un alto uso industriale/commerciale e che sono considerati a rischio in quanto possono essere utilizzati come armi chimiche o come precursori di armi chimiche.

Composti Fuori tabella
Con questa definizione si intendono i composti DOC e PSF cosi' come precedentemente definiti.

Tab. 1
Abbreviazione di tabella 1.

Tab. 2
Abbreviazione di tabella 2

Tab. 3
Abbreviazione di tabella 3.

Cap. 3

REGOLE DI APPROSSIMAZIONE per I DATI NUMERICI

Per composti classificati in Tab. 1
Le quantita' che devono essere dichiarate vanno arrotondate con accuratezza del 1%.
Per quantita' minori o uguali ad 1 grammo o si usera' l' approssimazione ad 1 gr o alla prima cifra decimale della quantita' espressa in grammi.

Per composti classificati in Tab. 2, parte A e contrassegnati da un asterisco, *
per quantità > di 10 kg arrotondare al kg più prossimo;
per quantità minori di 10 kg e maggiori di 1 kg, arrotondare i dati alla prima cifra decimale della quantità espressa in kg (esempio : 2,66 kg = 2,7; 0,14 kg = 0,1 kg) ;
per quantità minori di 1 kg arrotondare alla seconda cifra decimale la quantità espressa in kg (esempio : 0,068kg = 0,07 kg).

Per composti classificati in Tab. 2, parte A
per quantità > di 100 kg arrotondare ai 10 kg più prossimi (esempio : 266kg = 270 kg; 244kg = 240kg);
per quantità minori di 100 kg arrotondare i dati al kg più prossimo.

Per composti classificati in Tab. 2, parte B
per quantità > di 10 tonnellate arrotondare alla tonnellata più prossima;
per quantità inferiori a 10 tonnellate e maggiori di 1 tonnellata, arrotondare al 0,1 ton più prossima (esempio: 2,66 tons = 2,7 tons; 0,14 tons = 0,1 tons);
per quantità inferiori a 1 tonnellata arrotondare alla seconda cifra decimale della quantità espressa in tons.

Per composti classificati in Tab. 3
per quantità maggiori di 10 tons arrotondare alla tonnellata più prossima;
per quantità inferiori alle 10 tons arrotondare a 0,1 tons più prossimi (esempio : 2,66 tons = 2,7 tons; 0,14 tons = 0,1 tons)

Per le coordinate geografiche
L' approssimazione va fatta al secondo piu' prossimo specificando anche il sistema geografico di riferimento.

Esempio : Latitudine 00(gradi) / 00(minuti) / 00 (secondi) (Nord o Sud)
esempio : 55/45/28/N

Longitudine 00(gradi) / 00(minuti) / 00 (secondi) (Est o Ovest)
esempio : 005/32/53/E

Date
Le date vanno riportate nel seguente formato : CCYY-MM-DD.
Esempio : 1995-03-31

Periodi
I periodi vanno riportate nel seguente formato : CCYY-MM/CCYY-MM, dove il primo periodo indicato e' quello iniziale ed il secondo quello finale.
Esempio : 1994-08/1994-12

Cap. 4

TABELLE DEI CODICI

APP. 1 : Codici dei Paesi (Stati) da utilizzare per i dati import ed export

Paese	Codice
Afganistan	AFG
Albania	ALB
Algeria	DZA
Angola	AGO
Antigua e Barbuda	ATG
Argentina	ARG
Armenia	ARM
Australia	AUS
Austria	AUT
Azerbaijan	AZE
Bahamas	BHS
Bahrain	BHR
Bangladesh	BGD
Barbados	BRB
Belarus	BLR
Belgio	BEL
Belize	BLZ
Benin	BEN
Bhutan	BTN
Bolivia	BOL
Bosnia e Erzegovina	BIH
Botswana	BWA
Brasile	BRA
Brunei Darussalam	BRN
Bulgaria	BGR
Burkina Faso	BFA
Burundi	BDI
Cambogia	KHM
Cameroon	CMR
Canada	CAN
Isole di Capo Verde	CPV
Repubblica Centrale Africana	CAF
Ciad	TCD
Cile	CHL
Cina	CHN
Colombia	COL
Comora	COM
Isole di Cook	COK
Congo	COG
Costarica	CRI
Costa d' Avorio	CIV

segue App. 1 codici paesi	
Croazia	HRV
Cuba	CUB
Cipro	CYP
Repubblica Ceca	CZE
Repubblica del Popolo Democratico di Corea	PRK
Danimarca	DNK
Djibouti	DJI
Dominica	DMA
Repubblica Dominicana	DOM
Equador	ECU
Egitto	EGY
El Salvador	SLV
Guinea Equatoriale	GNQ
Estonia	EST
Etiopia	ETH
Fiji	FJI
Finlandia	FIN
Francia	FRA
Gabon	GAB
Gambia	GMB
Georgia	GEO
Germania	DEU
Ghana	GHA
Grecia	GRC
Grenada	GRD
Guatemala	GTM
Guinea	GIN
Guinea-Bissau	GNB
Guyana	GUY
Haiti	HTI
Città del Vaticano	VAT
Honduras	HND
Ungheria	HUN
Islanda	ISL
India	IND
Indonesia	IDN
Iran	IRN
Iraq	IRQ
Irlanda	IRL
Israele	ISR
Italia	ITA
Jamaica	JAM
Giappone	JPN
Giordania	JOR
Kazachistan	KAZ
Kenia	KEN
Kiribati	KIR
Kuwait	KWT
Kyrgyzstan	KGZ
Lao	LAO
Latvia	LVA
Libano	LBN

segue App. 1 codici Paesi	
Leshoto	LSO
Liberia	LBR
Libia	LBY
Liechtenstein	LIE
Lituania	LTU
Lussemburgo	LUX
Madagascar	MDG
Malawi	MWI
Malesia	MYS
Maldive	MDV
Mali	MLI
Malta	MLT
Isole Marshall	MHL
Mauritania	MRT
Mauritius	MUS
Messico	MEX
Micronesia	FSM
Principato di Monaco	MCO
Mongolia	MNG
Marocco	MAR
Mozambico	MOZ
Myanmar	MMR
Namibia	NAM
Nauru	NRU
Nepal	NPL
Olanda	ND
Nuova zelanda	NZL
Nicaragua	NIC
Niger	NER
Nigeria	NGA
Norvegia	NOR
Oman	OMN
Pakistan	PAK
Panama	PAN
Papua nuova guinea	PNG
Paraguay	PRY
Peru'	PER
Filippine	PHL
Polonia	POL
Portogallo	PRT
Qatar	QAT
Repubblica di Corea	KOR
Moldova	MDA
Romania	ROM
Federazione Russa	RUS
Ruanda	RWA
Saint Kitts and Nevis	KNA
Saint Lucia	LCA
Saint Vincent and The Grenadines	VCT
Samoa	WSM
Repubblica di San Marino	SMR
Sao Tome and Principe	STP

segue App. 1 codici Paese	
Arabia Saudita	SAU
Senegal	SEN
Seychelles	SYC
Sierra Leone	SLE
Singapore	SGP
Slovacchia	SVK
Slovenia	SVN
Isole Solomone	SLB
Somalia	SOM
Sud Africa	ZAF
Spagna	ESP
Sri Lanka	LKA
Sudan	SDN
Suriname	SUR
Swaziland	SWZ
Svezia	SWE
Svizzera	CHE
Siria	SYR
Tajikistan	TJK
Tailandia	THA
Togo	TGO
Tonga	TON
Trinidad e Tobago	TTO
Tunisia	TUN
Turchia	TUR
Turkmenistan	TKM
Tuvalu	TUV
Uganda	UGA
Ucraina	UKR
Emirati Arabi Uniti	ARE
Regno Unito di Gran Bretagna e Irlanda del Nord	GBR
Tanzania	TZA
Stati Uniti d' America	USA
Uruguay	URY
Uzbekistan	UZB
Vanuatu	VUT
Venezuela	VEN
Vietnam	VNM
Yemen	YEM
Iugoslavia	YUG
Zaire	ZAR
Zambia	ZMB
Zimbawe	ZWE

APP. 3 : Codici per attivita' principale dei siti e/o impianti dei siti

Codice	Attivita' principale
B01	Produzione
B02	Lavorazione (applicazione di un processo fisico)
B03	Consumo (trasformazione chimica)
B04	Stoccaggio
B05	Riconfezionamento e distribuzione
B06	Ricerca e sviluppo

APP. 4 : Codici per individuazione gruppi di prodotti

Codice	Descrizione prodotti chimici
511	Idrocarburi e loro derivati alogenati, solfonati, nitrati o nitrosi
512	Alcoli, fenoli, fenoli-alcoli e loro derivati alogenati, solfonati, nitrati e nitrosi.
513	Acidi carbossilici e loro anidridi, alogenuri, perossidi e perossiacidi ; loro derivati alogenati, solfonati, nitrati e nitrosi
514	Composti a funzione azotata
515	Composti organici-inorganici, composti eterociclici, acidi nucleici e loro sali e solfonammidici
516	Altri composti chimici organici
522	Elementi chimici inorganici, ossidi e loro sali alogenati
523	Sali e perossosali metallici di acidi inorganici
524	Altri composti inorganici ; composti organici ed inorganici di metalli preziosi
525	Elementi chimici radioattivi e loro composti
531	Sostanze coloranti organiche sintetiche, lacche coloranti; preparazioni a base di lacche coloranti
532	Estratti per la concia o per la tinta, prodotti sintetici per la concia
533	Pigmenti, pitture, smalti, e prodotti collegati
541	Prodotti farmaceutici e medicinali diversi dai medicamenti del gruppo 542
542	Medicamenti inclusi quelli per usi veterinari
551	Oli essenziali , fragranze, aromi e profumi
553	Preparazioni per profumeria o per toeletta o preparazioni cosmetiche (escluso i saponi)
554	Saponi, preparazioni per pulizia e lucidatura
562	Concimi (diversi dal gruppo 272)
571	Polimeri dell' etilene, in forme primarie
572	Polimeri dello stirene in forme primarie
573	Polimeri di cloruro di vinile o altre olefine alogenate in forme primarie
574	Poliacetali, altri polieteri e resine epossidiche, in forme primarie; Policarbonati, resine alchidiche, poliesteri allilici ed altri poliesteri
575	Altre materie plastiche in forme primarie
579	Cascami, ritagli e avanzi di materie plastiche
581	Tubi e loro accessori di materie plastiche
582	Lastre, fogli, pellicole , strisce e lamine di plastica
583	Monofilamenti la cui dimensione massima della sezione trasversale e' superiore a 1 mm; verghe, bastoni e profilati anche lavorati in superficie, ma non altrimenti lavorati, di materie plastiche
591	Insetticidi, rodenticidi, fungicidi, erbicidi, inibitori di germinazione e regolatori di crescita per piante, disinfettanti e prodotti simili presentati in forme o in imballaggi per la vendita al minuto oppure allo stato di preparazioni o in forma di oggetti (quali nastri, stoppini e candele solforate e carte moschicide)
592	Prodotti a base di amidi o di fecole inulina e glutine di grano; sostanze albuminoidi; colle
593	Esplosivi e prodotti pirotecnici
597	Additivi preparati per oli minerali e prodotti similari; liquidi preparati per trasmissioni idrauliche; preparazioni antigelo e preparati per lo sbrinamento; preparati lubrificanti
598	Prodotti chimici vari
599	Altri

APP. 5 : Codici per Scopi di produzione per composti dichiarati in tabella 3

Codici	Scopi di produzione
B11	Trasformazione in linea alla produzione (uso captivo)
B12	Stoccaggio e/o uso nel sito come intermedio di sintesi
B13	Trasferimento ad altra industria

APP. 6 : Codici per assegnazione delle fasce di produzione per composti dichiarati in tabella 3

Codici	Fasce di produzione
B21	30 <= P < 200 tons
B22	200 <= P < 1.000 tons
B23	1.000 <= P < 10.000 tons
B24	10.000 <= P < 100.000 tons
B25	P > 100.000 tons

APP. 7 : Codici per assegnazione fasce di produzione dei siti dichiarati relativamente alla produzione di composti DOC e PSF

Codici	Fasce di produzione (R=produzione annuale di tutti i composti chimici classificati come DOC)
B31	200 <= R < 1.000 tons
B32	1.000 <= R < 10.000 tons
B33	R > 10.000 tons

APP. 8 : Codici per dichiarare gli scopi relativi alla produzione, lavorazione e consumo dei composti chimici di tabella 1

Codici	Fasce di produzione
C01	Ricerca
C02	Medicinali
C03	Farmaceutici
C04	Protezione
C05	Eliminazione rifiuti
C06	Produzione di altri composti di tabella 1

MODELLI

per

DICHIARAZIONI INIZIALI

relative a

COMPOSTI CHIMICI

Parte VI - VII - VIII - IX

dell' Annesso Verifiche della Convenzione

Legge 496 del 18/11/1995

Modelli :

Mini/In
Mini/In/sp
Mini/In/sp/excw
Mini/In/sp/notab
Mini/In/imp
Mini/In/imp/excw
Mini/In/comp1
Mini/In/comp2
Mini/In/comp2/excw
Mini/In/comp3
Mini/In/comp/3/excw
Mini/In/ie2
Mini/In/ie3

Mod. Mini/In LEGGE 496 del 18/11/1995

Ptr. ....

DICHIARAZIONE INIZIALE per ATTIVITA' NON PROIBITE

(parte VI, VII, VIII e IX dell' Annesso Verifiche della CWC)

Classificazione livello di confidenzialità dei dati forniti : ....

Ragione sociale

Indirizzo

Cap/città

Provincia

tel

fax

Allegati alla dichiarazione

Oggetto Dichiarazione	Modello	Oggetto dei dati	Numero di modelli x dichiarazione
Produzione di composti di tab 1	Mini/In/sp Mini/In/comp1	Dichiarazione sito produttivo Dichiarazione impianto + allegati tecnici	....
Produzione, lavorazione e/o consumo di composti di tab.2 e/o produzione di composti di tab.3	Mini/In/sp Mini/In/imp Mini/In/comp2 Mini/In/comp3	Dichiarazione sito produttivo Dichiarazione relativa agli impianti Dichiarazione relativa ai composti di tab.2 Dichiarazione relativa ai composti di tab.3	.. ..
Produzione di composti chimici classificati DOC o PSF	Mini/In/sp Mini/In/sp/notab	Dichiarazione sito produttivo Dichiarazione relativa alla produzione	....
Produzione pregresse, dal 1 1.1946, di composti chimici di tab 2 e/o tab.3 destinati ad utilizzi per armi chimiche	Mini/In/sp/excw Mini/In/imp/excw Mini/In/comp2/excw Mini/In/comp3/excw	Dichiarazione per sito produttivo Dichiarazione relativa agli impianti Dichiarazione relativa ai composti di tab.2 Dichiarazione relativa ai composti di tab 3	....
Import / export di composti chimici di tab. 2 e/o di tab 3	Mini/In/ie2 Mini/In/ie3	Dichiarazione relativa composti di tab..2 Dichiarazione relativa composti di tab. 3	.. ..

Dichiarante

Data

Mod. Mini/In/sp LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

DICHIARAZIONE RELATIVA AL SITO PRODUTTIVO

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Denominazione	....
Proprietario / gestore del sito	....
Indirizzo	.... Cap/città .... Provincia ....
Ubicazione esatta : - coordinate geografiche o - estremi mappe topografiche	latitudine .... longitudine.. ....

Ripartizione degli impianti del sito x tipologia di composti dichiarati		
Classificazione dei composti dichiarati	Numero complessivo composti dichiarati per sito	Numero impianti presenti nel sito
Tabella 1	....	....
Tabella 2	....	....
Tabella 3	....	....
Nessuna tabella (composti DOC esclusi PSF)		....
Nessuna tabella (composti PSF)		....
TOTALE	....	....

Dichiarante

Data

Mod. Mini/In/sp/excw LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

DICHIARAZIONE RELATIVA AL SITO PRODUTTIVO

Per siti che comprendono impianti che dal 1.1.1946 abbiano, in un qualunque momento, prodotto composti chimici di tabella 2 e/o tabella 3 utilizzati per lo sviluppo di armi chimiche

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Denominazione	
Proprietario / gestore del sito	
Indirizzo	Cap/città Provincia
Ubicazione esatta - coordinate geografiche o - estremi mappe topografiche	latitudine longitudine

Ripartizione degli impianti del sito che per il passato (dal 1.1.1946) hanno prodotto composti di tabella 2 e/o tabella 3		
Classificazione dei composti dichiarati e prodotti dal 1 1 1946 per sviluppo armi chimiche	Numero complessivo composti dichiarati per sito	Numero impianti presenti nel sito
Tabella 2		
Tabella 3		
TOTALE		

Dichiarante

Data

Mod. Mini/In/notab LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

Sito ....

DICHIARAZIONE RELATIVA A COMPOSTI DOC e PSF

Classificazione livello di confidenzialità dei dati forniti : ....

Dati complementari identificativi del sito	
Codice attività principale del sito	....
Codice gruppo prodotti relativi all' attività principale del sito	....

Dati per siti che producono > 200 tons di composti chimici DOC	
Codice per individuazione fascia di produzione complessiva di tutti i composti DOC prodotti	....
Numero approssimato di impianti del sito che producono composti DOC inclusi i PSF	....

Dati per siti comprendenti 1 o piu' impianti che producono > 30 tons di un composto PSF	
Numero di impianti presenti nel sito che producono composti PSF	....
Indicare se l' impianto ha nell' anno precedente prodotto in un anno piu' di 200 tons di un composto chimico PSF	☐ Si ☐ No

Numero di impianti per fascia di produzione complessiva data dalla somma delle singole produzioni di ciascuno di essi per singoli composti PSF	
Numero di impianti che producono complessivamente meno di 200 tons	....
Numero di impianti che producono complessivamente da 200 a 1.000 tons	....
Numero di impianti che producono complessivamente da 1.000 a 10.000 tons	....
Numero di impianti che producono complessivamente piu' di 10.000 tons	....

Dichiarante

Data

Mod. Mini/In/imp LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

Sito produttivo di ....

DICHIARAZIONE RELATIVA ALL' IMPIANTO N. .... di ....

(SOLO PER COMPOSTI CHIMICI PRESENTI IN TABELLA 2 O IN TABELLA 3)

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Denominazione	....
Proprietario / gestore dell' impianto sito	....
Ubicazione nel sito : struttura n. edificio n.	....
Tabella di riferimento cui si riferiscono i composti trattati nell' impianto	tab.2 □ tab.3 □

Dati relativi all' attività dell' impianto		
1	Codice attività principale dell' impianto in generale	
2	Codice gruppo prodotti inerenti l' attività principale dell' impianto	
3	Codice del tipo di processo associato ai composti dichiarati e trattati sull' impianto	
4	Codice altre attivita' dell' impianto relative ai composti dichiarati	
5	Carattere dell' attività dell' impianto relativamente ai composti dichiarati	Esclusivo □ Polivalente □

(I campi 3 - 4 - 5 vanno riempiti solo per dichiarazioni riguardanti i composti di tabella 2)

Capacita' produttiva annua dell' impianto per singolo composto dichiarato

(da compilare solo per dichiarazioni riguardanti i composti di tabella 2)

Composto dichiarato (Nome IUPAC o comm.le o n. CAS)	Tabella di riferimento	Attività impianto P=produzione L=lavorazione C=consumo	Quantità annua (kg o ton)	Tipo Capacita' E= effettiva T= teorica

Dichiarante

Data

Mod. Mini/In/imp/excw LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

Sito produttivo di ....

DICHIARAZIONE RELATIVA ALL' IMPIANTO N. .... di ....

Per impianti che dal 1.1.1946 abbiano, in un qualunque momento, prodotto composti chimici di tabella 2 e/o tabella 3 utilizzati per lo sviluppo di armi chimiche

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Denominazione	....
Proprietario / gestore dell' impianto sito	....
Ubicazione nel sito : struttura n. edificio n.	....
Tabella di riferimento cui si riferiscono i composti trattati nell' impianto	tab.2 □ tab.3 □

Dati relativi all' attività attuale dell' impianto		
1	Codice attività principale dell' impianto in generale	
2	Codice gruppo prodotti inerenti l' attività principale dell' impianto	
3	Codice del tipo di processo associato ai composti dichiarati e trattati sull' impianto	
4	Codice altre attivita' dell' impianto relative ai composti dichiarati	
5	Carattere dell' attività dell' impianto relativamente ai composti dichiarati	Esclusivo □ Polivalente □

(I campi 3 - 4 - 5 vanno compilati solo per dichiarazioni riguardanti i composti di tabella 2)

Capacita' produttiva annua attuale dell' impianto per singolo composto dichiarato e prodotto in passato (compilare solo per dichiarazioni riguardanti i composti di tabella 2)				
Composto dichiarato (Nome IUPAC o comm.le o n. CAS)	Tabella di riferimento	Attività impianto P=produzione L=lavorazione C=consumo	Quantita' annua (kg o ton)	Tipo Capacita' E= effettiva T= teorica

Dichiarante

Data

Mod. Mini/In/comp1 LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

Sito produttivo di ....

DICHIARAZIONE DI IMPIANTO PER LA PRODUZIONE DI COMPOSTI DI TAB. 1

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi dell' impianto	
Classificazione produttiva secondo CWC	□ Impianto singolo su scala ridotta per produzione globale > 10 kg □ Impianto per produzione globale compresa tra 100g - 10 kg per scopi di difesa □ Impianto per produzione globale compresa tra . 100g - 10 kg per scopi medici, farmaceutici o di ricerca
Funzionalità	□ Impianto esistente □ Impianto nuovo
Denominazione del sito dove insiste l'impianto	. ..
Identificazione dell' edificio o struttura in cui l' impianto e' localizzabile nel sito	. .
Responsabile impianto (facoltativo)	. .
Indirizzo	Cap/citta . Provincia
Ubicazione esatta - coordinate geografiche o - estremi mappe topografiche	latitudine longitudine

Documentazione tecnica allegata alla dichiarazione		
	Oggetto	barrare se presentato
1	Descrizione tecnica dell' impianto	....
2	Diagrammi dettagliati (obbligatorio solo per impianti unici a scala ridotta)	....
3	Inventario delle attrezzature (obbligatorio solo per impianti unici a scala ridotta)	. . . ..
4	Volume in litri del reattore più grande (facoltativo e solo per impianti unici a scala ridotta)	.. ..
5	Volume totale in litri di tutti i reattori eccedenti un volume di 5 litri (facoltativo e solo per impianti unici a scala ridotta)	....

Dichiarante

Data

Mod. Mini/In/comp2 LEGGE 496 del 18/1'/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

Sito produttivo di .... Impianto n. .... di ....

DICHIARAZIONE COMPOSTI CHIMICI PRESENTI IN TABELLA 2

Composto .... di ....

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Nome IUPAC	
Nome commerciale o aziendale interno	
Formula di struttura	
Numero CAS	

Dati attività pregressa di 3 anni precedenti alla dichiarazione			
attività dell' impianto riferita al composto dichiarato	Quantità totale (ton) anno	Quantità totale (ton) anno	Quantità totale (ton) anno ....
Produzione			
Lavorazione			
Trasformazione			
Importazione			
Esportazione			

Dati import/export relativi al composto dichiarato per i 3 anni precedenti alla dichiarazione			
Oggetto	anno	anno	anno ....
Importazione diretta codice stato di provenienza / quantità (ton)	. .../...................... ..../...................... ..../............ . .. . /	........../......................... ..../......................... .. ../......................... ..../....	........../......................... ..../......................... ..../......................... ..../.........................
Esportazione diretta : codice stato di destinazione / quantità (ton)	........../ ..../................. ..../......................... ..../.........................	........../......................... ..../......................... ..../......................... ..../.........................	........../......................... ..../......................... ..../......................... ..../.........................

Altri dati di vendita e/o trasferimento entro il territorio nazionale			
Vendita / trasferimento entro territorio nazionale o altro luogo sotto giurisdizione italiana : (barrare la voce interessata)	☐ Altra industria ☐ Società comm.le ☐ Altro destinatario	☐ Altra industria ☐ Società comm.le ☐ Altro destinatario	☐ Altra industria ☐ Società comm.le ☐ Altro destinatario
Codice tipologia di prodotto finale derivato dal composto venduto o trasferito (indicare solo se il dato e' disponibile)	....	....	....
Altri scopi per cui il composto e' stato prodotto, lavorato e/o consumato	....	....	....

Dichiarante

Data

Mod. Mini/In/comp2/excw LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante .... pb. .... del ....
Sito produttivo di .... Impianto n. .. di ....

DICHIARAZIONE COMPOSTI CHIMICI PRESENTI IN TABELLA 2

Per composti chimici prodotti dal 1.1.1946 che sono stati utilizzati, in un qualunque momento, per lo sviluppo di armi chimiche

Composto ...... di .....

Classificazione livello di confidenzialita dei dati forniti . . ...

Dati identificativi	
Nome IUPAC	
Nome commerciale o aziendale interno	
Formula di struttura	
Numero CAS	

Periodi approssimativi di produzione e quantità prodotte	
Periodi approssimativi di produzione (CCYY-MM/CCYY-MM)	Quantità totale (ton) anno

Dati identificativi siti dove il composto prodotto nel passato e' stato consegnato				
Sito	Città	Provincia	Codice Paese	Prodotto finale realizzato con il composto

Dichiarante

Data

Mod. Mini/In/comp3 LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....
Sito produttivo di .... Impianto n. .... di ....

DICHIARAZIONE COMPOSTI CHIMICI PRESENTI IN TABELLA 3

Composto .... di ... .

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Nome IUPAC	
Nome commerciale o aziendale interno	
Formula di struttura	
Numero CAS	

Dati attività pregressa dell' anno precedente alla dichiarazione	
Oggetto	Anno ....
Codice fascia di produzione in cui rientra la quantità totale prodotta	
Codice dello scopo per cui il composto e' stato prodotto	

Dati import/export relativi al composto dichiarato per l' anno precedente alla dichiarazione	
Oggetto	anno ....
Importazione diretta : codice stato di provenienza / quantità (ton) :	................/.. ..../.. ..../.. ..../..
Esportazione diretta : codice stato di destinazione / quantità' (ton) :	................/.. ..../.. ..../.. ..../..

Dichiarante

Data

Mod. Mini/In/comp3/excw LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .. .. ptr. .. .. del ....
Sito produttivo di .... Impianto n. .... di ....

DICHIARAZIONE COMPOSTI CHIMICI PRESENTI IN TABELLA 3

Per composti chimici prodotti dal 1.1.1946 che sono stati utilizzati, in un qualunque momento, per lo sviluppo di armi chimiche

Composto ... . di ....

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi	
Nome IUPAC	
Nome commerciale o aziendale interno	
Formula di struttura	
Numero CAS	

Periodi approssimativi di produzione e quantità prodotte	
Periodi approssimativi di produzione (CCYY MM/CCYY-MM)	Quantita totale (ton) anno

Dati identificativi siti dove il composto prodotto nel passato e' stato consegnato				
Sito	Città	Provincia	Codice Paese	Prodotto finale realizzato con il composto

Dichiarante

Data

Mod. Mini/In/ ie2 LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

DICHIARAZIONE ATTIVITA' IMPORT / EXPORT RELATIVA A COMPOSTI CHIMICI PRESENTI IN TABELLA 2

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi del composto	
Nome IUPAC	
Nome commerciale o aziendale interno	
Numero CAS	

DATI IMPORT x Anno x Totale Paese (Codice Paese / quantita' annua in tons)		
Anno	Anno	Anno ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....

DATI EXPORT x Anno x Totale Paese (Codice Paese / quantita' annua in tons)		
Anno	Anno	Anno ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....
.... /	.... /	.... / ....

Dichiarante

Data

Mod. Mini/In/ ie3 LEGGE 496 del 18/11/1995

ALLEGATO ALLA DICHIARAZIONE INIZIALE

Dichiarante : .... ptr. .... del ....

DICHIARAZIONE ATTIVITA' IMPORT / EXPORT RELATIVA A COMPOSTI CHIMICI PRESENTI IN TABELLA 3

Classificazione livello di confidenzialità dei dati forniti : ....

Dati identificativi del composto	
Nome IUPAC	
Nome commerciale o aziendale interno	
Numero CAS	

DATI IMPORT x Anno x Totale Paese (Codice paese/quantita' annua in tons)	DATI EXPORT x Anno x Totale Paese (Codice paese/quantita' annua in tons)
Anno	Anno ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....
.... /	.... / ....

Dichiarante

Data

ALLEGATO 2

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

Fonte	N°CAS	Rif. tab. Convenzione	Formula bruta	Nome IUPAC
PTS-HB	51-75-2	1A06	C5H11Cl2N	Ethanamine, 2-chloro-N-(2-chloroethyl)-N-methyl-
PTS-HB	74-90-8	3A03	CHN	Hydrocyanic acid
PTS-HB	75-44-5	3A01	CCl2O	Carbonic dichloride
PTS-HB	76-06-2	3A04	CCl3NO2	Methane, trichloronitro-
PTS-HB	76-93-7	2B08	C14H12O3	Benzeneacetic acid, .alpha.-hydroxy-.alpha.-phenyl-
PTS-HB	77-81-6	1A02	C5H11N2O2P	Phosphoramidocyanidic acid, dimethyl-, ethyl ester
PTS-HB	78-38-6	2B04	C6H15O3P	Phosphonic acid, ethyl-, diethyl ester
PTS-HB	78-53-5	2A01	C10H24NO3PS	Phosphorothioic acid, S-[2-(diethylamino)ethyl] O,O-diethyl ester
PTS-HB	96-64-0	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester
PTS-HB	96-79-7	2B10	C8H18ClN	2-Propanamine, N-(2-chloroethyl)-N-(1-methylethyl)-
PTS-HB	96-80-0	2B11	C8H19NO	Ethanol, 2-[bis(1-methylethyl)amino]-
CWCEC	100-35-6	2B10	C6H14ClN	Ethanamine, 2-chloro-N,N-diethyl-2-(Diethylamino)ethyl chloride 2-(Diethylamino)-1-chloroethane 2-(N,N-Diethylamino)ethyl chloride Triethylamine, 2-chloro-.beta.-(Diethylamino)ethyl chloride Diethylaminoethyl chloride
PTS-HB	100-38-9	2B12	C6H15NS	Ethanethiol, 2-(diethylamino)-
PTS-HB	102-71-6	3B17	C6H15NO3	Triethanolamine
PTS-HB	105-59-9	3B16	C5H13NO2	Methyldiethanolamine
PTS-HB	107-44-8	1A01	C4H10FO2P	Phosphonofluoridic acid, methyl-, 1-methylethyl ester
PTS-HB	107-99-3	2B10	C4H10ClN	Ethanamine, 2-chloro-N,N-dimethyl-
PTS-HB	108-02-1	2B12	C4H11NS	Ethanethiol, 2-(dimethylamino)-
PTS-HB	111-48-8	2B13	C4H10O2S	Ethanol, 2,2'-thiobis-
PTS-HB	121-45-9	3B08	C3H9O3P	Trimethil phosphite
PTS-HB	122-52-1	3B09	C6H15O3P	Triethyl phosphite
PTS-HB	139-87-7	3B15	C6H15NO2	Ethyldiethanolamine
PTS-HB	327-98-0	2B04	C10H12Cl3O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-(2,4,5-trichlorophenyl) ester
PTS-HB	328-04-1	2B04	C11H15ClNO4PS	Phosphonothioic acid, ethyl-, O-(2-chloro-4-nitrophenyl) O-(1-methylethyl) ester
PTS-HB	329-21-5	2B04	C14H23OPS2	Phosphonodithioic acid, ethyl-, S-[4-(1,1-dimethylethyl)phenyl] O-ethyl ester
PTS-HB	329-99-7	1A01	C7H14FO2P	Phosphonofluoridic acid, methyl-, cyclohexyl ester
PTS-HB	333-43-7	2B04	C11H17OPS2	Phosphonodithioic acid, ethyl-, O-ethyl S-(4-methylphenyl) ester
CWCEC	352-52-3	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, 1-methylpropyl ester Phosphonofluoridic acid, methyl-, sec-butyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	352-53-4	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,3-dimethylbutyl ester 2-Pentanol, 4-methyl-, methylphosphonofluoridate
CWCEC	352-63-6	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, butyl ester
CWCEC	353-88-8	1A01	C2H6FO2P	Phosphonofluoridic acid, methyl-, methyl ester Methyl methylphosphonofluoridate
CWCEC	354-43-8	2B05	C2H6F2NOP	Phosphoramidic difluoride, dimethyl- N,N-Dimethylphosphoramidic difluoride
CWCEC	357-03-9	2B04	C4H11FNOP	Phosphonamidic fluoride, P-ethyl-N,N-dimethyl-
CWCEC	359-94-4	2B05	C4H10F2NOP	Phosphoramidic difluoride, diethyl- Diethylphosphoramidoyl difluoride (Diethylamino)difluorophosphine oxide
CWCEC	372-62-3	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, 2,2-dimethylpropyl ester Phosphonofluoridic acid, methyl-, neopentyl ester 1-Propanol, 2,2-dimethyl, methylphosphonofluoridate
PTS-HB	382-21-8	2A02	C4F8	1-Propene, 1,1,3,3,3-pentafluoro-2-(trifluoromethyl)-
CWCEC	430-78-4	2B04	C2H5F2P	Ethyldifluorophosphine Ethylphosphonous difluoride Phosphonous difluoride, ethyl- Ethyl Phosphinyl Difluoride Ethyl Phosphorous Difluoride
CWCEC	458-71-9	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 2-ethylhexyl ester
PTS-HB	464-07-3	2B14	C6H14O	2-Butanol, 3,3-dimethyl-
PTS-HB	465-60-1	2B04	C5H11N2OP	Aziridine, 1,1'-(methylphosphinylidene)bis-
PTS-HB	505-60-2	1A04	C4H8Cl2S	Ethane, 1,1'-thiobis[2-chloro-
PTS-HB	506-77-4	3A02	CClN	Cyanogen chloride ((CN)Cl)
PTS-HB	538-07-8	1A06	C6H13Cl2N	Ethanamine, 2-chloro-N-(2-chloroethyl)-N-ethyl-
PTS-HB	541-25-3	1A05	C2H2AsCl3	Arsonous dichloride, (2-chloroethenyl)-
PTS-HB	546-71-4	2B04	C10H14NO5P	Phosphonic acid, ethyl-, ethyl 4-nitrophenyl ester
CWCEC	546-76-9	2B04	C8H20O2PS2	3-Oxa-5-thia-8-thionia-4-phosphadecane, 4,8-dimethyl-, 4-oxide
PTS-HB	555-77-1	1A06	C6H12Cl3N	Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-
CWCEC	556-75-2	2B04	C7H17O2PS2	Phosphonothioic acid, methyl-, O-ethyl S-[2-(ethylthio)ethyl] ester O-Ethyl S-(2-ethylthioethyl) methylthiophosphonate Ethanethiol, 2-(ethylthio)-, S-ester with O-ethyl methylphosphonothioate O-Ethyl-S- beta -ethylmercaptoethylmethyl thiophosphinate O-Eth
PTS-HB	597-07-9	2B06	C4H12NO3P	Phosphoramidic acid, dimethyl-, dimethyl ester
CWCEC	616-52-4	2B04	C7H17O3P	Phosphonic acid, methyl-, mono(1,2,2-trimethylpropyl) ester 2-Butanol, 3,3-dimethyl-, hydrogen methylphosphonate Phosphonic acid, methyl-, 1,2,2-trimethylpropyl ester O-Pinacolyl hydrogen methylphosphonate O-Pinacolyl methylphosphonate Pinacolyl hydrogen
CWCEC	648-59-9	1A01	C4H10FO2P	Phosphonofluoridic acid, (1-methylethyl)-, methyl ester Phosphonofluoridic acid, isopropyl , methyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	649-13-8	2B04	C7H17FNOP	Phosphonamidic fluoride, N,N-diethyl-P-(1-methylethyl)- *Phosphonamidic fluoride, N,N-*diethyl-P-isopropyl-
CWCEC	649-68-3	2B04	C7H7F10O3P	Phosphonic acid, methyl-, bis(2,2,3,3,3-pentafluoropropyl) ester
CWCEC	650-11-3	2B04	C7H11F6O3P	Phosphonic acid, propyl-, bis(2,2,2-trifluoroethyl) ester
CWCEC	650-16-8	2B04	C6H9F6O3P	Phosphonic acid, ethyl-, bis(2,2,2-trifluoroethyl) ester
CWCEC	650-20-4	1A01	C4H10FO2P	Phosphonofluoridic acid, ethyl-, ethyl ester
CWCEC	650-35-1	2B04	C4H10FOPS2	Phosphonodithioic acid, methyl-, S-(2-fluoroethyl) O-methyl ester
CWCEC	650-72-6	2B05	C4H10ClFNOP	Phosphoramidic chloride fluoride, diethyl-
CWCEC	659-94-9	2B04	C4H10FPS2	Phosphonofluoridodithioic acid, methyl-, 1-methylethyl ester Phosphonofluoridodithioic acid, methyl-, isopropyl ester
CWCEC	660-04-8	2B04	C7H18FNO2P HO	1-Propanaminium, 2-[(fluoromethylphosphinyl)oxy]-N,N,N-trimethyl-, hydroxide Ammonium, (2-hydroxypropyl)trimethyl-, hydroxide, methylphosphonofluoridate (2-Hydroxypropyl)trimethylammonium hydroxide, methylphosphonofluoridate
CWCEC	660-11-7	2B04	C7H16FO2PS2	Phosphonothioic acid, methyl-, O-[2-(ethylthio)ethyl] O-(2-fluoroethyl) ester
PTS-HB	660-21-9	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 3,3-dimethylbutyl ester
CWCEC	661-60-9	2B04	C3H9FNOP	Phosphonamidic fluoride, trimethyl-
CWCEC	661-61-0	2B04	C3H9FNPS	Phosphonamidothioic fluoride, trimethyl-
CWCEC	663-70-7	2B04	C4H11FNPS	Phosphonamidothioic fluoride, P-ethyl-N,N-dimethyl-
CWCEC	665-03-2	1A01	C3H8FO2P	Phosphonofluoridic acid, ethyl-, methyl ester
CWCEC	665-33-8	1A01	C6H14FO2P	Phosphonofluoridic acid, (1-methylethyl)-, 1-methylethyl ester Phosphonofluoridic acid, isopropyl-, isopropyl ester Diisopropylphosphonofluoridate
CWCEC	667-02-7	2B04	C6H15FNOP	Phosphonamidic fluoride, triethyl-
CWCEC	667-03-8	2B04	C6H15FNPS	Phosphonamidothioic fluoride, triethyl-
CWCEC	673-97-2	1A01	C3H8FO2P	Phosphonofluoridic acid, methyl-, ethyl ester O-Ethyl methylphosphonofluoridate Ethyl methylphosphonofluoridate Ethyl methylphosphonofluoride
CWCEC	673-98-3	2B04	C3H8FOPS	Phosphonofluoridothioic acid, methyl-, S-ethyl ester
CWCEC	673-99-4	2B04	C3H8FPS2	Phosphonofluoridodithioic acid, methyl-, ethyl ester
CWCEC	674-95-3	1A01	C8H18FO2P	Phosphonofluoridic acid, methyl-, 1-methylhexyl ester
CWCEC	676-02-8	2B04	C6H15FNO2P	Phosphonofluoridic acid, methyl-, 3-(dimethylamino)propyl ester 3-(Dimethylamino)propyl methylphosphonofluoridate
PTS-HB	676-83-5	2B04	CH3Cl2P	Phosphonous dichloride, methyl-
PTS-HB	676-97-1	2B04	CH3Cl2OP	Phosphonic dichloride, methyl-
PTS-HB	676-98-2	2B04	CH3Cl2PS	Phosphonothioic dichloride, methyl-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	676-99-3	1B09	CH3F2OP	Phosphonic difluoride, methyl-
CWCEC	677-42-9	1B09	C3H7F2OP	Phosphonic difluoride, (1-methylethyl)- Phosphonic difluoride, isopropyl- Difluoroisopropylphosphine oxide Isopropylphosphonic difluoride
PTS-HB	677-43-0	2B05	C2H6Cl2NOP	Phosphoramidic dichloride, dimethyl-
CWCEC	681-06-1	2B04	C3H9O2PS	Phosphonothioic acid, methyl-, O,O-dimethyl ester O,O-Dimethyl methylphosphonothioate Dimethyl methanethiophosphonate Dimethoxymethylphosphine sulfide Dimethyl methylphosphonothionate
CWCEC	681-82-3	2B04	C9H18NO3PS2	Phosphonodithioic acid, (1-methylethyl)-, S-[2-(acetylamino)-2- oxoethyl] O-ethyl ester Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with 2-mercaptodiacetamide
CWCEC	682-47-3	2B04	C9H18NO3PS2	Phosphonodithioic acid, propyl-, S-[2-(acetylamino)-2-oxoethyl] O-ethyl ester Phosphonodithioic acid, propyl-, O-ethyl ester, S-ester with 2-mercaptodiacetamide
CWCEC	682-73-5	2B04	C8H16NO3PS2	Phosphonodithioic acid, ethyl-, S-[2-(acetylamino)-2-oxoethyl] O-ethyl ester Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-mercaptodiacetamide
CWCEC	682-89-3	2B04	C4H10FOPS	Phosphonofluoridothioic acid, ethyl-, O-ethyl ester
PTS-HB	683-08-9	2B04	C5H13O3P	Phosphonic acid, methyl-, diethyl ester
CWCEC	683-25-0	2B04	C5H13O3P	Phosphonic acid, methyl-, methyl propyl ester
CWCEC	683-26-1	2B04	C5H11O3P	Phosphonic acid, methyl-, methyl 2-propenyl ester Phosphonic acid, methyl-, allyl methyl ester
CWCEC	683-32-9	2B04	C6H15O3P	Phosphonic acid, methyl-, butyl methyl ester
CWCEC	688-02-8	2B04	C9H16FO5PS2	Butanedioic acid, [[(2-fluoroethoxy)methylphosphinothioyl]thio]-, dimethyl ester Succinic acid, mercapto-, dimethyl ester, O-2-fluoroethyl methylphosphonodithioate
CWCEC	690-14-2	1B09	C3H7F2OP	Phosphonic difluoride, propyl-
CWCEC	690-50-6	2B04	C8H20O2P2S2Se	Phosphonodithioic acid, ethyl-, O-ethyl ester, anhydrosulfide with O-ethyl ethylphosphonoselenothioate Phosphonoselenothioic acid, ethyl-, O-ethyl ester, anhydrosulfide with O-ethyl ethylphosphonodithioate
CWCEC	690-64-2	2B04	C5H13O3P	Phosphonic acid, methyl-, methyl 1-methylethyl ester Phosphonic acid, methyl-, isopropyl methyl ester Isopropyl methyl methylphosphonate
PTS-HB	690-88-0	2B04	C11H19Cl6O3P	Phosphonic acid, methyl-, bis(5,5,5-trichloropentyl) ester
CWCEC	691-00-9	2B04	C3H7ClFOPS	Phosphonochloridothioic acid, methyl-, O-(2-fluoroethyl) ester
CWCEC	691-01-0	2B04	C3H7BrFO2P	Phosphonofluoridic acid, methyl-, 2-bromoethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	692-62-6	2B04	C7H14NO3PS2	Phosphonodithioic acid, methyl-, S-[2-(acetylamino)-2-oxoethyl] O-ethyl ester Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercaptodiacetamide
CWCEC	710-09-8	2B04	C9H13O3P	Phosphonic acid, methyl-, methyl phenylmethyl ester Phosphonic acid, methyl-, benzyl methyl ester Benzyl methyl methanephosphonate
CWCEC	713-37-1	2B04	C9H12ClO3P	Phosphonic acid, methyl-, (2-chlorophenyl)methyl methyl ester Phosphonic acid, methyl-, o-chlorobenzyl methyl ester Benzyl alcohol, o-chloro-, methyl methylphosphonate
CWCEC	713-98-4	2B04	C9H12ClO3P	Phosphonic acid, methyl-, (4-chlorophenyl)methyl methyl ester Phosphonic acid, methyl-, p-chlorobenzyl methyl ester Benzyl alcohol, p-chloro-, methyl methylphosphonate
CWCEC	718-23-0	2B04	C11H17O3P	Phosphonic acid, methyl-, phenylmethyl propyl ester Phosphonic acid, methyl-, benzyl propyl ester
CWCEC	737-96-2	2B04	C11H13F3NO4PS	Phosphonothioic acid, ethyl-, O-ethyl O-(.alpha.,.alpha.,.alpha.- trifluoro-4-nitro-m-tolyl) ester
CWCEC	737-97-3	2B04	C11H13F3NO4PS	Phosphonothioic acid, methyl-, O-isopropyl O- (.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	737-98-4	2B04	C10H10BrF3NO4PS	Phosphonothioic acid, methyl-, O-(2-bromoethyl) O- (.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester Phosphonothioic acid, methyl-, O-2-bromoethyl O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	737-99-5	2B04	C11H13F3NO4PS	Phosphonothioic acid, methyl-, O-propyl O-(.alpha.,.alpha.,.alpha.- trifluoro-4-nitro-m-tolyl) ester
PTS-HB	740-20-5	2B04	C11H10ClF3NO4PS	Phosphonothioic acid, methyl-, O-(2-chloroallyl) O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	740-21-6	2B04	C10H9Cl2F3NO4PS	Phosphonothioic acid, methyl-, O-(2,2-dichloroethyl) O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	740-22-7	2B04	C11H10ClF3NO4PS	Phosphonothioic acid, methyl-, O-(3-chloroallyl) O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	744-02-5	2B04	C14H11F3NO4PS	Phosphonothioic acid, methyl-, O-phenyl O-(.alpha.,.alpha.,.alpha.- trifluoro-4-nitro-m-tolyl) ester
CWCEC	749-09-7	2B04	C19H19Cl2O7P	Benzoic acid, 3-chloro-4-hydroxy-, methyl ester, isopropylphosphonate
CWCEC	753-59-3	2B04	CH3F2P	Difluoromethylphosphine Methyldifluorophosphine Methylphosphonous difluoride Phosphonous difluoride, methyl-
CWCEC	753-71-9	2B04	CH3ClFOP	Phosphonic chloride fluoride, methyl-
CWCEC	753-72-0	2B04	CH3F2PS	Phosphonothioic difluoride, methyl- Difluoromethylphosphine sulfide

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	753-98-0	1B09	C2H5F2OP	Ethyl difluorophosphite Ethyldifluorophosphine oxide Ethylphosphonic difluoride Ethylphosphonyl difluoride Phosphonic difluoride, ethyl-
CWCEC	753-99-1	2B04	C2H5F2PS	Phosphonothioic difluoride, ethyl- Ethyldifluorophosphine sulfide
PTS-HB	756-79-6	2B04	C3H9O3P	Phosphonic acid, methyl-, dimethyl ester
CWCEC	757-95-9	2B04	C5H7F6O3P	Phosphonic acid, methyl-, bis(2,2,2-trifluoroethyl) ester
CWCEC	758-71-4	2B05	C4H10BrFNOP	Phosphoramidic bromide fluoride, diethyl-
CWCEC	761-93-3	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, 1-methylbutyl ester 2-Pentanol, methylphosphonofluoridate
PTS-HB	762-04-9	3B11	C4H11O3P	Diethyl phoshite
CWCEC	763-14-4	1A01	C4H10FO2P	Phosphonofluoridic acid, methyl-, propyl ester
CWCEC	763-22-4	2B04	C4H9ClFOPS	Phosphonochloridothioic acid, methyl-, O-(3-fluoropropyl) ester
CWCEC	785-76-2	2B04	C12H16NOPS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with .alpha.-mercapto-p-tolunitrile p-Tolunitrile alpha -mercapto-, S-ester with O-ethyl ethylphosphonodithioate
CWCEC	786-15-2	2B04	C13H18NOPS2	Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with .alpha.-mercapto-p-tolunitrile p-Tolunitrile, alpha -mercapto-, S-ester with O-ethyl isopropylphosphonodithioate
CWCEC	796-64-5	2B04	C11H12ClF3NO4PS	Phosphonothioic acid, ethyl-, O-(2-chloroethyl) O- (.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	800-82-8	2B04	C14H19F3NO4PS	Phosphonothioic acid, methyl-, O-hexyl O-(.alpha ,.alpha.,.alpha.- trifluoro-4 nitro-m-tolyl) ester
CWCEC	805-79-8	2B04	C19H21O7P	Benzoic acid, p-hydroxy-, ethyl ester, methylphosphonate
CWCEC	814-36-8	2B04	C10H19O5P	Methacrylic acid 2-hydroxyethyl ester, ethyl ethylphosphonate
CWCEC	817-09-4	1A06	C6H12Cl3N ClH	Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-, hydrochloride Tri(.beta.-chloroethyl)amine hydrochloride 2 2',2''-Trichlorotriethylamine hydrochloride Tris(2-chloroethyl)amine hydrochloride Triethylamine, 2,2',2''-trichloro-, hydrochloride Tris(.beta.-chlor
CWCEC	849-29-6	2B04	C11H12ClF3NO4PS	Phosphonothioic acid, methyl-, O-(3-chloropropyl) O-(.alpha ,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	852-57-3	2B04	C16H17Cl2O2PS2	Phosphonothioic acid, methyl-, O-[p-[(3,4-dichlorobenzyl)thio]phenyl] O-ethyl ester
CWCEC	854-00-2	2B04	C14H17F3NO4PS	Phosphonothioic acid, methyl-, O-cyclohexyl O- (.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	865-61-2	2B04	C2H5ClFOP	Phosphonic chloride fluoride, ethyl- Ethyl phosphorochloridofluoridite
CWCEC	867-28-7	2B04	C3H5ClNO2P	Phosphonisocyanatidic chloride, ethyl-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	867-35-6	2B04	C4H7ClNO2P	Phosphonisocyanatidic chloride, propyl-
PTS-HB	868-85-9	3B10	C2H7O3P	Dimethyl phosphite
PTS-HB	869-24-9	2B10	C6H14ClN.ClH	Ethanamine, 2-chloro-N,N-diethyl-, hydrochloride
CWCEC	870-29-1	2B04	C2H3ClNO2P	Phosphonisocyanatidic chloride, methyl-
PTS-HB	873-97-2	2B04	C6H13O3P	1,3,2-Dioxaphosphorinane, 2,5,5-trimethyl-, 2-oxide
CWCEC	886-44-2	2B04	C9H14FN2O2PS	Phosphonothioic acid, methyl-, O-ethyl O-[2-(fluoromethyl)-6-methyl- 4-pyrimidinyl] ester
CWCEC	886-63-5	2B04	C11H14NOPS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with .alpha.-mercapto-p-tolunitrile p-Tolunitrile, .alpha.-mercapto-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	889-14-5	2B04	C9H11FNO4PS	Phosphonothioic acid, methyl-, O-(2-fluoroethyl) O-(p-nitrophenyl) ester
CWCEC	893-27-6	2B04	C13H16NO2PS2	Phosphonothioic acid, methyl-, O-ethyl O-(4-p-tolyl-2-thiazolyl) ester
CWCEC	897-94-9	2B04	C12H13N2O4PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(m-nitrophenyl)-2-thiazolyl] ester
CWCEC	898-08-8	2B04	C13H17ClNO3PS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with p-chloro-N-(mercaptoacetyl)benzamide
CWCEC	905-13-5	2B04	C17H17O7P	Benzoic acid, p-hydroxy-, isopropylphosphonate (2:1) Benzoic acid, p-hydroxy-, diester with isopropylphosphonic acid
CWCEC	919-21-1	2B04	C11H25O3P	Phosphonic acid, (1-methylethyl)-, dibutyl ester
CWCEC	922-73-6	2B04	C8H16Cl3N2O2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercapto-N-[2,2,2-trichloro-1-(methylamino)ethyl]acetamide
PTS-HB	944-21-8	2B04	C10H15O2PS	Phosphonothioic acid, ethyl-, O-ethyl S-phenyl ester
CWCEC	944-22-9	2B04	C10H15OPS2	O-Ethyl S-phenyl ethylphosphonodithioate O-Ethyl S-phenyl ethyldithiophosphonate Phosphonodithioic acid, ethyl-, O-ethyl S-phenyl ester Difonate Dyfonate 10G Fonophos Difonatul Dyphonate N 2790 Dyfonat Fon
PTS-HB	993-13-5	2B04	CH5O3P	Phosphonic acid, methyl-
PTS-HB	993-43-1	2B04	C2H5Cl2PS	Phosphonothioic dichloride, ethyl-
CWCEC	995-88-0	2B04	C5H13OPS2	Phosphonodithioic acid, methyl-, S,S-diethyl ester S,S-Diethyl methylphosphonodithioate
PTS-HB	996-04-3	2B04	C7H17OPS2	Phosphonodithioic acid, methyl-, S,S-dipropyl ester
PTS-HB	996-05-4	2B04	C7H17PS3	Phosphonotrithioic acid, methyl-, dipropyl ester
CWCEC	996-09-8	2B04	C6H12NOPS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 3-mercaptopropionitrile
PTS-HB	999-34-8	2B04	C7H17PS2	Phosphonodithious acid, methyl-, dipropyl ester
CWCEC	1000-36-8	2B04	C11H25O3P	Phosphonic acid, methyl-, dipentyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1010-34-0	2B04	C7H14NO2PS2	Phosphonamidic acid, 1,3-dithiolan-2-ylideneethyl-, ethyl ester Imidocarbonic acid, (ethoxyethylphosphinyl)dithio-, cyclic ethylene ester Carbonimidodithioic acid, (ethoxyethylphosphinyl)-, cyclic 1,2-ethanediyl ester
CWCEC	1010-35-1	2B04	C7H14NOPS3	Phosphonamidothioic acid, N-1,3-dithiolan-2-ylidene-P-ethyl-, O-ethyl ester Imidocarbonic acid, (ethoxyethylphosphinothioyl)dithio-, cyclic ethylene ester 1,2-Ethanedithiol, cyclic ester with (ethoxyethylphosphinoth
CWCEC	1023-45-6	2B04	C10H16FN2O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-[2-(fluoromethyl)-6-methyl-4-pyrimidinyl] ester
PTS-HB	1066-50-8	2B04	C2H5Cl2OP	Phosphonic dichloride, ethyl-
CWCEC	1066-52-0	2B04	C2H6ClO2P	Phosphonochloridic acid, methyl-, methyl ester Methyl methylchlorophosphonate Methyl methylphosphonochloridate Methyl methanephosphonochloridate
CWCEC	1066-53-1	2B04	C2H7O3P	Phosphonic acid, methyl-, monomethyl ester Phosphonic acid, methyl-, methyl ester Methyl methanephosphonate Methyl methylphosphonate Methyl phosphonic acid monomethyl ester
CWCEC	1067-69-2	2B04	C8H19O3P	Phosphonic acid, ethyl-, bis(1-methylethyl) ester Phosphonic acid, ethyl-, diisopropyl ester Diisopropyl ethylphosphonate
CWCEC	1068-10-6	2B04	C7H16ClOPS3	Phosphonodithioic acid, ethyl-, S-[[(2-chloroethyl)thio]methyl] O-ethyl ester
CWCEC	1068-20-8	2B04	C3H3N2O3P	Phosphonic diisocyanate, methyl-
CWCEC	1068-26-4	2B04	C8H19O2PS	Phosphonothioic acid, methyl-, S-(2,2-dimethylpropyl) O-ethyl ester Phosphonothioic acid, methyl-, O-ethyl S-neopentyl ester
CWCEC	1068-35-5	2B04	C10H23O2PS	Phosphonothioic acid, methyl-, S-(4,4-dimethylpentyl) O-ethyl ester 1-Pentanethiol, 4,4-dimethyl-, S-ester with O-ethyl methylphosphonothioate LG 69
CWCEC	1068-38-8	2B04	C12H27O2PS	Phosphonothioic acid, methyl-, S-(6,6-dimethylheptyl) O-ethyl ester 1-Heptanethiol, 6,6-dimethyl-, S-ester with O-ethyl methylphosphonothioate LG 78
CWCEC	1068-39-9	2B04	C13H29O2PS	Phosphonothioic acid, methyl-, S-(7,7-dimethyloctyl) O-ethyl ester 1-Octanethiol, 7,7-dimethyl-, S-ester with O-ethyl methylphosphonothioate O-Ethyl S-(7,7-dimethyloctyl) methylthiophosphonate LG 87
CWCEC	1068-59-3	2B04	C2H5Br2P	Phosphonous dibromide, ethyl- Dibromoethylphosphine
CWCEC	1068-76-4	2B04	C11H26O5P2	Phosphonic acid, ethyl-, 1-(ethoxyethylphosphinyl)propyl ethyl ester Phosphonic acid, ethyl-, ethyl ester, ester with ethyl ethyl(1-hydroxypropyl)phosphinate
CWCEC	1070-93-5	2B04	C4H12O5P2	Phosphonic acid, methyl-, anhydride, dimethyl ester
CWCEC	1071-07-4	2B04	C7H17OPS2	Phosphonodithioic acid, methyl-, S,S-bis(1-methylethyl) ester Phosphonodithioic acid, methyl-, S,S-diisopropyl ester
CWCEC	1071-14-3	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, O-ethyl S-(2-methylpropyl) ester Phosphonothioic acid, methyl-, O-ethyl S-isobutyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1071-19-8	2B04	C9H21PS3	Phosphonotrithioic acid, methyl-, dibutyl ester
CWCEC	1071-20-1	2B04	C11H25O2PS	Phosphonothioic acid, methyl-, S-(5,5-dimethylhexyl) O-ethyl ester 1-Hexanethiol, 5,5-dimethyl-, S-ester with O-ethyl methylphosphonothioate LG 67
CWCEC	1084-00-0	2B04	C11H16ClO2PS2	Phosphonothioic acid, ethyl-, O-[p-[(chloromethyl)thio]phenyl] O-ethyl ester
CWCEC	1085-23-0	2B04	C10H14NO4PS	Phosphonothioic acid, ethyl-, O-methyl O-(4-nitro-o-tolyl) ester
PTS-HB	1085-34-3	2B04	C10H14NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) O-propyl ester
CWCEC	1085-86-5	2B04	C12H18ClO2PS2	Phosphonothioic acid, ethyl-, O-[4-[(chloromethyl)thio]-m-tolyl] O-ethyl ester
CWCEC	1086-94-8	2B04	C10H14NO5PS	Phosphonothioic acid, methyl-, O-ethyl O-(3-methoxy-4-nitrophenyl) ester
CWCEC	1086-96-0	2B04	C10H14NO5PS	Phosphonothioic acid, methyl-, O-ethyl O-(2-methoxy-4-nitrophenyl) ester
CWCEC	1087-18-9	2B04	C11H16NO4PS	Phosphonothioic acid, ethyl-, O-ethyl O-(4-nitro-o-tolyl) ester
CWCEC	1088-63-7	2B04	C11H16NO5PS	Phosphonothioic acid, ethyl-, O-ethyl O-(3-methoxy-4-nitrophenyl) ester
CWCEC	1088-75-1	2B04	C11H16NO5PS	Phosphonothioic acid, ethyl-, O-ethyl O-(2-methoxy-4-nitrophenyl) ester
CWCEC	1089-68-5	2B04	C16H19O3P	Phosphonic acid, ethyl-, di-p-tolyl ester
CWCEC	1186-37-4	2B04	C10H23O2PS	Phosphonothioic acid, methyl-, O-ethyl S-(5-methylhexyl) ester 1-Hexanethiol, 5-methyl-, S-ester with O-ethyl methylphosphonothioate
PTS-HB	1189-87-3	1A01	C5H12FO2P	Phosphonofluoridic acid, ethyl-, 1-methylethyl ester
CWCEC	1221-75-6	2B04	C12H14NO4PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 4-hydroxy-N-methylphthalimide
CWCEC	1223-30-9	2B04	C13H20ClOPS3	Phosphonodithioic acid, ethyl-, S-[2-chloro-1-(p-tolylthio)ethyl] O-ethyl ester
CWCEC	1226-86-4	2B04	C12H15ClNO3PS2	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with 2-chloro-7-hydroxy-2H-1,4-benzothiazin-3(4H)-one
CWCEC	1331-18-6	2B10	C6H14ClN	Ethanamine, 1(or 2)-chloro-N,N-diethyl- Triethylamine, chloro-
CWCEC	1331-38-0	2B11	C8H19NO	Ethanol, amino-, bis(1-methylethyl) deriv.
CWCEC	1426-08-0	1A01	C5H12FO2P	Phosphonofluoridic acid, isopropyl-, ethyl ester Ethyl isopropylphosphonofluoridate
CWCEC	1426-12-6	2B04	C5H13FNOP	Phosphonamidic fluoride, N,N-diethyl-P-methyl-
CWCEC	1426-14-8	2B04	C5H13FNO2P	Phosphonofluoridic acid, methyl-, 2-(dimethylamino)ethyl ester
CWCEC	1426-16-0	2B04	C5H13FNPS	Phosphonamidothioic fluoride, N,N-diethyl-P-methyl-
CWCEC	1426-17-1	2B04	C5H13FO4P2	Phosphonic acid, methyl-, anhydride with methylphosphonofluoridic acid, isopropyl ester
PTS-HB	1445-75-6	2B04	C7H17O3P	Phosphonic acid, methyl-, bis(1-methylethyl) ester
PTS-HB	1445-76-7	1B11	C4H10ClO2P	Phosphonochloridic acid, methyl-, 1-methylethyl ester
CWCEC	1447-22-9	2B04	C8H18ClOPS3	Phosphonodithioic acid, ethyl-, S-[2-chloro-1-(ethylthio)ethyl] O-ethyl ester
CWCEC	1478-54-2	2B04	C5H11F2O3P	Phosphonic acid, methyl-, bis(2-fluoroethyl) ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1487-78-1	2B04	C13H18NOPS2	Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with .alpha.-mercapto-o-tolunitrile o-Tolunitrile, .alpha.-mercapto-, S-ester with O-ethyl isopropylphosphonodithioate
CWCEC	1487-79-2	2B04	C12H16NOPS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with .alpha.-mercapto-o-tolunitrile o-Tolunitrile, .alpha.-mercapto-, S-ester with O-ethyl ethylphosphonodithioate
CWCEC	1487-80-5	2B04	C11H14NOPS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with .alpha.-mercapto-o-tolunitrile o-Tolunitrile, .alpha.-mercapto-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	1487-81-6	2B04	C11H14NOPS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with .alpha.-mercapto-m-tolunitrile m-Tolunitrile, .alpha.-mercapto-s-ester with O-E-methylphosphonodithioate m-Tolunitrile, .alpha.-mercapto-, S-
CWCEC	1496-38-4	2B04	C12H15F3NO4PS	Phosphonothioic acid, methyl-, O-butyl O-(.alpha.,.alpha.,.alpha.- trifluoro 4-nitro-m-tolyl) ester
CWCEC	1496-39-5	2B04	C12H15F3NO4PS	Phosphonothioic acid, methyl-, O-isobutyl O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	1496-90-8	2B04	C7H17OPS2	Phosphonodithioic acid, (1-methylethyl)-, S,S-diethyl ester Phosphonodithioic acid, isopropyl-, S,S-diethyl ester
CWCEC	1497-36-5	2B04	C9H11Cl2O2PS	Phosphonothioic acid, ethyl-, O-(2,4-dichlorophenyl) O-methyl ester
CWCEC	1497-37-6	2B04	C9H10Cl3O2PS	Phosphonothioic acid, ethyl-, O-methyl O-(2,4,6-trichlorophenyl) ester
CWCEC	1497-38-7	2B04	C9H13O2PS	Phosphonothioic acid, ethyl-, O-methyl O-phenyl ester
PTS-HB	1497-39-8	2B04	C10H14ClO2PS	Phosphonothioic acid, ethyl-, O-(4-chlorophenyl) O-ethyl ester
CWCEC	1497-40-1	2B04	C10H12Cl3O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-(2,4,6-trichlorophenyl) ester
CWCEC	1497-41-2	2B04	C10H15O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-phenyl ester Dyfonate O-analog
CWCEC	1497-42-3	2B04	C11H16ClO2PS	Phosphonothioic acid, ethyl-, O-(4-chlorophenyl) O-propyl ester Phosphonothioic acid, ethyl-, O-(p-chlorophenyl) O-propyl ester
CWCEC	1497-43-4	2B04	C11H15Cl2O2PS	Phosphonothioic acid, ethyl-, O-(2,4-dichlorophenyl) O-propyl ester
CWCEC	1497-44-5	2B04	C11H14Cl3O2PS	Phosphonothioic acid, ethyl-, O-propyl O-(2,4,6-trichlorophenyl) ester
CWCEC	1497-45-6	2B04	C11H17O2PS	Phosphonothioic acid, ethyl-, O-phenyl O-propyl ester
CWCEC	1497-63-8	2B04	C15H25O2PS	Phosphonothioic acid, ethyl-, O-[4-(1,1-dimethylethyl)phenyl] O-propyl ester Phosphonothioic acid, ethyl-, O-(p-tert-butylphenyl) O-propyl ester
CWCEC	1497-67-2	2B04	C5H12ClOPS	Phosphonochloridothioic acid, ethyl-, O-propyl ester O-Propyl ethanephosphonothionochloridate
PTS-HB	1497-68-3	2B04	C4H10ClOPS	Phosphonochloridothioic acid, ethyl-, O-ethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1497-69-4	2B04	C3H8ClOPS	Phosphonochloridothioic acid, ethyl-, O-methyl ester O-Methyl ethanephosphonothionochloridate
PTS-HB	1498-40-4	2B04	C2H5Cl2P	Phosphonous dichloride, ethyl-
CWCEC	1498-46-0	2B04	C3H7Cl2OP	Phosphonic dichloride, (1-methylethyl)- Phosphonic dichloride, isopropyl- 2-Propanephosphonyl chloride Isopropylphosphonic acid dichloride Isopropylphosphonic dichloride Dichloroisopropylphosphine oxide Isopropylphosphonyl dichloride
CWCEC	1498-54-0	2B05	C4H10Cl2NOP	Phosphoramidic dichloride, diethyl- Diethylphosphoramidic dichloride Diethylphosphoramidoyl dichloride P,P-Dichloro-N,N-diethylphosphinic amide N,N-Diethylphosphoramidic dichloride Dichloro(diethylamino)phosphine oxide Dichlorodiethylphosphoramidite
CWCEC	1498-60-8	2B04	C3H7Cl2PS	Phosphonothioic dichloride, (1-methylethyl)- Phosphonothioic dichloride, isopropyl- Isopropylphosphonothioyl dichloride Isopropylphosphonothionodichloridic acid Isopropylphosphonothioic dichloride
CWCEC	1510-34-5	2B04	C5H12FPS2	Phosphonofluoridodithioic acid, methyl-, butyl ester
PTS-HB	1511-67-7	2B04	CH4FO2P	Phosphonofluoridic acid, methyl-
CWCEC	1512-59-0	2B04	C5H12FOPS2	Phosphonodithioic acid, methyl-, O-ethyl S-2-fluoroethyl ester
CWCEC	1538-69-8	2B04	C7H17O3P	Phosphonic acid, (1-methylethyl)-, diethyl ester Phosphonic acid, isopropyl-, diethyl ester Diethyl isopropylphosphonate
CWCEC	1538-72-3	2B04	C15H17O3P	Phosphonic acid, (1-methylethyl)-, diphenyl ester Phosphonic acid, isopropyl-, diphenyl ester
CWCEC	1544-64-5	2B04	C10H14FOPS3	Phosphonodithioic acid, methyl-, O-ethyl S-[[(p-fluorophenyl)thio]methyl] ester
CWCEC	1550-15-8	2B04	C6H14FO3P	Phosphonic acid, ethyl-, ethyl 2-fluoroethyl ester
CWCEC	1550-62-5	2B04	C4H10FO2PS	Phosphonothioic acid, methyl-, S-(2-fluoroethyl) O-methyl ester
CWCEC	1592-73-0	2B04	C15H17OPS2	Phosphonodithioic acid, isopropyl-, S,S-diphenyl ester
CWCEC	1593-26-6	2B04	C9H12ClO2PS	Phosphonothioic acid, ethyl-, O-(4-chlorophenyl) O-methyl ester Phosphonothioic acid, ethyl-, O-(p-chlorophenyl) O-methyl ester
PTS-HB	1593-27-7	2B04	C10H13Cl2O2PS	Phosphonothioic acid, ethyl-, O-(2,4-dichlorophenyl) O-ethyl ester
CWCEC	1593-28-8	2B04	C13H21O2PS	Phosphonothioic acid, ethyl-, O-[4-(1,1-dimethylethyl)phenyl] O-methyl ester Phosphonothioic acid, ethyl-, O-(p-tert-butylphenyl) O-methyl ester
CWCEC	1598-82-9	2B04	C5H11F2O2PS	Phosphonothioic acid, methyl-, O,O-bis(2-fluoroethyl) ester
CWCEC	1599-00-4	2B04	C11H20FO5PS2	Succinic acid, mercapto-, diethyl ester, S-ester with O-(2-fluoroethyl) methylphosphonodithioate Succinic acid, mercapto-, diethyl ester, O-2-fluoroethyl methylphosphonodithioate
PTS-HB	1619-34-7	2B09	C7H13NO	1-Azabicyclo[2.2.2]octan-3-ol

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1641-51-6	2B04	C14H35O3PSi2	Phosphonic acid, ethyl-, bis(triethylsilyl) ester Silanol, triethyl-, ethylphosphonate (2:1) Bis(triethylsilyl) ethylphosphonate
CWCEC	1641-57-2	2B04	C8H23O3PSi2	Phosphonic acid, ethyl-, bis(trimethylsilyl) ester
CWCEC	1645-14-3	2B04	C11H14F3O3PS	Phosphonic acid, ethyl-, ethyl p-[(trifluoromethyl)thio]phenyl ester
CWCEC	1645-59-6	2B04	C7H13ClFO3PS	Acetic acid, chlorofluorothio-, anhydride with isobutyl methylphosphonate
CWCEC	1646-61-3	2B04	C8H20NO5PS4	Phosphonodithioic acid, ethyl-, S-[2-[bis(methylsulfonyl)amino]ethyl] O-ethyl ester Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-(2-mercaptoethyl)dimethanesulfonamide Stauffer N 4171 N 4171
CWCEC	1646-62-4	2B04	C6H16NO5PS4	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)dimethanesulfonamide
CWCEC	1646-63-5	2B04	C8H20NO6PS3	Phosphonothioic acid, ethyl-, O-isopropyl ester, S-ester with N-(mercaptomethyl)dimethanesulfonamide Dimethanesulfonamide, N-(mercaptomethyl)-, S-ester with O-isopropyl ethylphosphonothioate
CWCEC	1646-70-4	2B04	C8H20NO6PS3	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with N-(2-hydroxyethyl)dimethanesulfonamide Dimethanesulfonamide, N-(2-hydroxyethyl)-, o-ester with o-ethyl-ethylphosphonothioate
CWCEC	1646-72-6	2B04	C4H12FO2PSi	Phosphonofluoridic acid, methyl-, trimethylsilyl ester
CWCEC	1648-50-6	2B04	C13H17F3NO4PS	Phosphonothioic acid, methyl-, O-pentyl O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	1652-35-3	2B04	C2H6F2O3P2	Phosphonofluoridic acid, methyl-, anhydride
CWCEC	1713-91-3	2B04	C9H9Cl4OPS2	Phosphonodithioic acid, methyl-, S-(p-chlorophenyl) O-(2,2,2-trichloroethyl) ester
CWCEC	1713-92-4	2B04	C9H9Cl4O2PS	Phosphonothioic acid, methyl-, O-(2-chloroethyl) O-(2,4,6-trichlorophenyl) ester
CWCEC	1713-93-5	2B04	C9H11BrClO2PS	Phosphonothioic acid, methyl-, O-p-bromophenyl O-2-chloroethyl ester
CWCEC	1713-94-6	2B04	C11H15Cl2O2PS	Phosphonothioic acid, methyl-, O-(4-chlorobutyl) O-(p-chlorophenyl) ester
CWCEC	1713-95-7	2B04	C9H11BrClOPS2	Phosphonodithioic acid, methyl-, O-(2-bromoethyl) S-(p-chlorophenyl) ester
CWCEC	1713-96-8	2B04	C10H12Cl3OPS2	Phosphonodithioic acid, methyl-, S-(p-chlorophenyl) O-(2,3-dichloropropyl) ester
CWCEC	1733-71-7	2B04	C9H16NO2PS3	Phosphonothioic acid, ethyl-, O-ethyl S-[[(4-methyl-2-thiazolyl)thio]methyl] ester
CWCEC	1733-72-8	2B04	C9H11Cl2OPS2	Phosphonodithioic acid, methyl-, O-(2-chloroethyl) S-(4-chlorophenyl) este Phosphonodithioic acid, methyl-, O-2-chloroethyl S-p-chlorophenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1733-73-9	2B04	C9H10Cl3OPS2	Phosphonodithioic acid, methyl-, S-(4-chlorophenyl) O-(2,2-dichloroethyl) ester Phosphonodithioic acid, methyl-, S-p-chlorophenyl O-2,2-dichloroethyl ester
CWCEC	1733-74-0	2B04	C9H10Cl3O2PS	Phosphonothioic acid, methyl-, O-(2-chloroethyl) O-(3,4-dichlorophenyl) ester Phenol, 3,4-dichloro-, O-ester with O-(2-chloroethyl) methylphosphonothioate
CWCEC	1739-48-6	2B04	C7H18FGeO2P	Germane, triethyl[(fluoromethylphosphinyl)oxy]- Phosphonofluoridic acid, methyl-, O-triethylgermyl deriv
CWCEC	1739-49-7	2B04	C4H12FGeO2P	Germane, [(fluoromethylphosphinyl)oxy]trimethyl- Phosphonofluoridic acid, methyl-, O-trimethylgermyl deriv
CWCEC	1743-67-5	2B04	C12H16F3O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-[(trifluoromethyl)thio]-m-tolyl] ester
CWCEC	1744-68-9	2B04	C11H13ClF3O2PS2	Phosphonothioic acid, ethyl-, O-[3-chloro-4-[(trifluoromethyl)thio]phenyl] O-ethyl ester
CWCEC	1748-47-6	2B04	C10H16NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[(2-pyridylthio)methyl] ester
CWCEC	1751-10-6	2B04	C7H18NO5PS4	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)dimethanesulfonamide
CWCEC	1751-13-9	2B04	C7H18FO2PSi	Phosphonofluoridic acid, methyl-, triethylsilyl ester
CWCEC	1751-37-7	2B04	C11H16NO4PS2	Phosphonothioic acid, methyl-, O-ethyl O-[3-(ethylthio)-4-nitrophenyl] ester
CWCEC	1756-00-9	2B04	C4H7ClNO2P	Phosphonisocyanatidic chloride, isopropyl-
CWCEC	1763-36-6	2B04	C5H12FO2PS	Phosphonothioic acid, methyl-, O-ethyl O-(2-fluoroethyl) ester Phosphonothioic acid, methyl-, ethyl 2-fluoroethyl ester
CWCEC	1773-87-1	2B04	C14H23O2PS	Phosphonothioic acid, ethyl-, O-[4-(1,1-dimethylethyl)phenyl] O-ethyl ester Phosphonothioic acid, ethyl-, O-p-tert-butylphenyl O-ethyl ester
CWCEC	1776-74-5	2B04	C13H16NO2PS	Phosphonothioic acid, ethyl-, O-ethyl O-7-quinolyl ester
CWCEC	1776-75-6	2B04	C12H14NO2PS	Phosphonothioic acid, methyl-, O-ethyl O-7-quinolyl ester
CWCEC	1776-76-7	2B04	C12H13ClNO2PS	Phosphonothioic acid, methyl-, O-5-chloro-8-quinolyl O-ethyl ester
CWCEC	1776-77-8	2B04	C14H18NO3P	Phosphonic acid, isopropyl-, ethyl 8-quinolyl ester
CWCEC	1776-78-9	2B04	C14H18NO3P	Phosphonic acid, isopropyl-, ethyl 5-quinolyl ester
CWCEC	1776-79-0	2B04	C13H16NO2PS	Phosphonothioic acid, ethyl-, O-ethyl O-5-quinolyl ester
CWCEC	1776-80-3	2B04	C13H16NO3P	Phosphonic acid, ethyl-, ethyl 8-quinolyl ester
CWCEC	1776-81-4	2B04	C12H14NO3P	Phosphonic acid, methyl-, ethyl 8-quinolyl ester
CWCEC	1776-82-5	2B04	C12H14NO3P	Phosphonic acid, methyl-, ethyl 5-quinolyl ester
CWCEC	1777-13-5	2B04	C7H17Hg2O3P	Mercury, Hg-butyl-Hg'-ethyl-Hg,Hg'-[(methylphosphinylidene)dioxy]di-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1789-95-3	2B04	C9H21O3P	Phosphonic acid, propyl-, dipropyl ester Dipropyl propylphosphonate Dipropyl propanephosphonate
CWCEC	1796-48-1	2B04	C10H24O5P2	Phosphonic acid, methyl-, bimol. monoanhydride, diisobutyl ester Phosphonic acid, methyl-, isobutyl ester, anhydride
CWCEC	1804-71-3	2B04	C12H19N2O3PS2	Phosphonamidothioic acid, N,N-diethyl-P-methyl-, O-[4-(methylthio)-3-nitrophenyl] ester
CWCEC	1804-72-4	2B04	C10H15N2O3PS2	Phosphonamidothioic acid, trimethyl-, O-[4-(methylthio)-3- nitrophenyl] ester
CWCEC	1813-45-2	2B04	C6H12Cl2FO2PS	Phosphonothioic acid, methyl-, O-butyl S-(dichlorofluoromethyl) ester
CWCEC	1832-54-8	2B04	C4H11O3P	Phosphonic acid methyl-, mono(1-methylethyl) ester Phosphonic acid, methyl-, isopropyl ester Phosphonic acid, methyl-, monoisopropyl ester Isopropyl methanephosphonate O-Isopropyl hydrogen methylphosphonate
CWCEC	1832-68-4	2B04	C17H37O3P	Phosphonic acid, methyl-, dioctyl ester Dioctyl methylphosphonate
PTS-HB	1866-98-4	1A03	C9H23NO2PS.I	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy)phosphinyl]thio]-, iodide
CWCEC	1868-79-7	2B04	C6H16FNO2P.HO	Choline, hydroxide methylphosphonofluoridate
CWCEC	1869-33-6	2B04	C11H11Cl2F3NO4PS	Phosphonothioic acid, ethyl-, O-2,2-dichloroethyl O-(.alpha.,.alpha.,.alpha.-trifluoro-4-nitro-m-tolyl) ester
CWCEC	1883-50-7	2B04	C10H22NO3PS2	Phosphonothioic acid, ethyl-, O-ethyl, S-ester with 2-[(mercaptomethyl)thio]-N-propylacetamide Phosphonothioic acid, ethyl-, O-ethyl ester, S-ester with N-isopropyl-2-[(mercaptomethyl)thio]acetamide
CWCEC	1883-51-8	2B04	C8H17O4PS2	Acetic acid, [(mercaptomethyl)thio]-, methyl ester, O-ethyl ethylphosphorothioate Acetic acid, [(mercaptomethyl)thio]-, methyl ester, S-ester with O-ethyl ethylphosphonothioate
CWCEC	1883-52-9	2B04	C12H17O4PS2	Acetic acid, [(mercaptomethyl)thio]-, phenyl ester, S-ester with O-ethyl methylphosphonothioate
CWCEC	1883-53-0	2B04	C12H18NO2PS3	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with 2-[(mercaptomethyl)thio]acetanilide Acetanilide, 2-[(mercaptomethyl)thio]-S-ester with O-methyl ethylphosphonodithioate
CWCEC	1883-54-1	2B04	C10H22NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-[(2-mercaptoethyl)thio]-N,N-dimethylacetamide
CWCEC	1883-55-2	2B04	C9H20NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-[(2-mercaptoethyl)thio]-N-methylacetamide Acetamide, 2-[(2-mercaptoethyl)thio]-N-methyl-S-ester with O-ethyl ethylphosphonodithioate
CWCEC	1883-56-3	2B04	C9H20NO2PS3	Phosphonodithioic acid, ethyl-, O-isopropyl ester, S-ester with 2-[(mercaptomethyl)thio]-N-methylacetamide

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	1883-57-4	2B04	C7H16NO2PS3	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with 2-[(mercaptomethyl)thio]-N-methylacetamide
CWCEC	1883-58-5	2B04	C10H21O3PS3	Acetic acid, [(2-mercaptoethyl)thio]-, ethyl ester, S-ester with O-ethyl ethylphosphonodithioate
CWCEC	1883-59-6	2B04	C10H21O3PS3	Acetic acid, [(mercaptomethyl)thio]-, ethyl ester, S-ester with O-isopropyl ethylphosphonodithioate
CWCEC	1883-60-9	2B04	C8H17O3PS3	Acetic acid, [(mercaptomethyl)thio]-, ethyl ester, S-ester with O-methyl ethylphosphonodithioate
CWCEC	1883-61-0	2B04	C9H19O3PS3	Acetic acid, [(mercaptomethyl)thio]-, ethyl ester, S-ester with O-ethyl ethylphosphonodithioate
CWCEC	1883-66-5	2B04	C8H18NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[[[2-(methylamino)-2-oxoethyl]thio]methyl] ester Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-[(mercaptomethyl)thio]-N-methylacetamide Stauffer N
CWCEC	1903-33-9	2B04	C6H15O3P.C2H4O2	Acetic acid, compd. with diethyl ethylphosphonate (1:1) Phosphonic acid, ethyl-, diethyl ester, compd. with acetic acid (1:1)
CWCEC	1908-15-2	2B04	C10H24O5P2	Phosphonic acid, ethyl-, 1-(ethoxyethylphosphinyl)ethyl ethyl ester Phosphonic acid, ethyl , ethyl ester, ester with ethyl ethyl(1-hydroxyethyl)phosphinate
PTS-HB	1942-52-5	2B12	C6H15NS.ClH	Ethanethiol, 2-(diethylamino)-, hydrochloride
PTS-HB	1942-78-5	2B04	C11H16ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chloro-3-methylphenyl) O-ethyl ester
PTS-HB	1942-80-9	2B04	C10H14ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chloro-m-tolyl) O-methyl ester
CWCEC	1942-81-0	2B04	C12H18ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chloro-3-methylphenyl) O-propyl ester N 4989 Phosphonodithioic acid, ethyl-, S-(4-chloro-m-tolyl) O-propyl ester
PTS-HB	1978-17-2	2B04	C7H18FNO2P.I	Ammonium, (3-hydroxypropyl)trimethyl-, iodide, methylphosphonofluoridate
CWCEC	1993-87-9	2B04	C5H9ClFO3PS	Acetic acid, chlorofluorothio-, anhydride with ethyl methylphosphonate
CWCEC	2013-94-7	2B04	C11H13Cl2F3NO2P	Phosphonamidic acid, N-(2,3-dichlorophenyl)-P-ethyl-N- (trifluoromethyl)-, ethyl ester
CWCEC	2014-02-0	2B04	C10H11Cl2F3NO2P	Phosphonamidic acid, N-(2,5-dichlorophenyl)-P-methyl-N-(trifluoromethyl)-, ethyl ester
CWCEC	2014-04-2	2B04	C9H9Cl2F3NO2P	Phosphonamidic acid, N-(3,4-dichlorophenyl)-P-methyl-N-(trifluoromethyl)-, methyl ester
CWCEC	2021-82-1	2B04	C6H11ClFO3PS	Acetic acid, chlorofluorothio-, compd. with acetic acid (1:1) Acetic acid, chlorofluorothio-, anhydride with isopropyl methylphosphonate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	2025-13-0	2B04	C10H20NO2PS3	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with 1-[[(mercaptomethyl)thio]acetyl]pyrrolidine Pyrrolidine, 1-[[(mercaptomethyl)thio]acetyl]-S-ester with O-methyl ethylphosphonodithioate Pyrrolid
CWCEC	2025-14-1	2B04	C9H20NO2PS3	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-isopropyl-2-[(mercaptomethyl)thio]acetamide Acetamide, N-isopropyl-2-[(mercaptomethyl)thio]-S-ester with O-methyl ethylphosphonodithioate Phos
CWCEC	2043-66-5	2B04	C7H16NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-mercapto-N-methylthioacetamide
CWCEC	2053-81-8	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, 2-methylpropyl ester Phosphonofluoridic acid, methyl-, isobutyl ester Isobutyl fluoromethylphosphinate Isobutyl methylphosphonofluoridate
CWCEC	2086-20-6	2B04	C13H16NO3P	Phosphonic acid, ethyl-, ethyl 5-quinolyl ester
CWCEC	2086-21-7	2B04	C12H14NO2PS	Phosphonothioic acid, methyl-, O-ethyl O-8-quinolinyl ester Phosphonothioic acid, methyl-, O-ethyl O-8-quinolyl ester
CWCEC	2106-70-9	2B04	C5H12FO3P	Phosphonic acid, methyl-, ethyl 2-fluoroethyl ester
CWCEC	2171-87-1	2B04	C2H6FO2P	Phosphonofluoridic acid, ethyl-
CWCEC	2181-51-3	2B04	C16H13F6O3P	Phosphonic acid, ethyl-, bis(.alpha.,.alpha.,.alpha. -trifluoro-m-tolyl)ester
CWCEC	2189-28-8	2B04	C11H12Cl3F3NO2P	Phosphonamidic acid, P-ethyl-N-(2,3,5-trichlorophenyl)-N-(trifluoromethyl)-, ethyl ester
CWCEC	2194-30-1	2B04	C6H11F2O3PS	Acetic acid, difluorothio-, anhydride with isopropyl methylphosphonate
CWCEC	2210-48-2	2B04	C15H17O5P	Phosphonic acid, (1-methylethyl)-, bis(4-hydroxyphenyl) ester Phosphonic acid, isopropyl-, bis(p-hydroxyphenyl) ester
CWCEC	2210-56-2	2B04	C13H21N2O4PS	Phosphonothioic acid, ethyl-, O-[.alpha.-(dimethylamino)-4-nitro-o- tolyl] O-ethyl ester
CWCEC	2210-58-4	2B04	C17H28NO2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-(methylthio)-.alpha.2-1-pyrrolidinyl-2,5-xylyl] ester
CWCEC	2241-52-3	2B04	C10H14NO4PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(methylthio)-3- nitrophenyl] ester
CWCEC	2261-83-8	1A01	C6H14FO2P	Phosphonofluoridic acid, ethyl-, 2-methylpropyl ester Phosphonofluoridic acid, ethyl-, isobutyl ester
CWCEC	2262-90-0	2B04	C13H24FO5PS2	Succinic acid, mercapto-, diisopropyl ester, O-2-fluoroethyl methylphosphonodithioate
PTS-HB	2275-83-4	2B04	C6H13N2OP	Aziridine, 1,1'-(ethylphosphinylidene)bis-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	2275-86-7	2B04	C7H15N2OP	Aziridine, 1,1'-(propylphosphinylidene)bis-
CWCEC	2302-80-9	2B04	C4H9Cl2OP	Phosphonic dichloride, butyl- Butyldichlorophosphine oxide Butylphosphonic dichloride Butylphosphonyl dichloride
CWCEC	2358-59-0	2B04	C21H33O4P	Testosterone, methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, ester with testosterone
CWCEC	2358-60-3	2B04	C20H29O4P	Estradiol, 17-(methyl methylphosphonate) Phosphonic acid, methyl-, 3-hydroxyestra-1,3,5(10)-trien-17.beta.-yl methyl ester
CWCEC	2358-61-4	2B04	C21H31O4P	Estra-1,3,5(10)-trien-17.beta.-ol, 3-methoxy-, methyl methylphosphonate Phosphonic acid, methyl-, 3-methoxyestra-1,3,5(10)-trien-17.beta.-yl methyl ester
CWCEC	2358-62-5	2B04	C20H27O4P	Estrone, methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, ester with estrone
CWCEC	2358-63-6	2B04	C22H34O6P2	Estradiol, bis(methyl methylphosphonate) Phosphonic acid, methyl-, estra-1,3,5(10)-trien-3,17.beta.-ylene ester, dimethyl ester
CWCEC	2358-64-7	2B04	C21H33O4P	Androst-5-en-17-one, 3.beta.-hydroxy-, methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, ester with 3.beta.-hydroxyandrost-5-en-17-one
CWCEC	2358-65-8	2B04	C23H37O4P	Pregn-5-en-20-one, 3.beta.-hydroxy-, methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, ester with 3.beta.-hydroxypregn-5-en-20-one
CWCEC	2387-52-2	2B04	C16H27N2O4PS	Phosphonothioic acid, ethyl-, O-[.alpha.2-(diethylamino)-4-nitro-2,5-xylyl] O-ethyl ester 2,5-Xylenol, .alpha.2-(diethylamino)-4-nitro-, O-ester with O-ethyl ethylphosphonothioate
CWCEC	2387-55-5	2B04	C15H21Cl3NO3PS	Phosphonothioic acid, ethyl-, O-ethyl O-[3,4,6-trichloro-2-(4-morpholinylmethyl)phenyl] ester Phosphonothioic acid, ethyl-, O-ethyl O-[3,4,6-trichloro-.alpha - morpholino-o-tolyl] ester
CWCEC	2404-03-7	2B06	C6H16NO3P	Diethyl dimethylphosphoramidate Diethyl-N,N-dimethylphosphoroamidate Dimethylphosphoramidic acid diethyl ester N,N-Dimethyl-O,O'-diethylphosphoramidate Phosphoramidic acid, dimethyl-, diethyl ester
CWCEC	2404-04-8	2B06	C8H20NO3P	Phosphoramidic acid, dimethyl-, bis(1-methylethyl) ester Phosphoramidic acid, dimethyl-, diisopropyl ester Diisopropyl dimethylphosphoramidate
CWCEC	2404-58-2	2B04	C10H23O3P	Phosphonic acid, ethyl-, dibutyl ester
CWCEC	2404-73-1	2B04	C9H21O3P	Phosphonic acid, methyl-, dibutyl ester Dibutoxymethylphosphine oxide Dibutyl methanephosphonate Dibutyl methylphosphonate
CWCEC	2404-80-0	2B04	C5H14NO2P	Phosphonamidic acid, trimethyl-, ethyl ester
CWCEC	2404-81-1	2B04	C7H18NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, ethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	2452-70-2	2B04	C11H25O3P	Phosphonic acid, methyl-, bis(3-methylbutyl) ester Isopentyl alcohol, methylphosphonate (2:1) Phosphonic acid, methyl-, diisopentyl ester Diisoamyl methylphosphonate Diisopentyl methylphosphonate Diisoamylmethylphosphate
CWCEC	2452-71-3	2B04	C11H25O3P CHNS	Phosphonic acid, methyl-, diisopentyl ester, compd. with thiocyanic acid (1:1) Thiocyanic acid compd. with methylphosphonic acid diisopentyl ester Phosphonic acid, methyl-, diisopentyl ester, compd. with HSCN
CWCEC	2455-45-0	2B04	C6H15O2PS	Phosphonothioic acid, ethyl-, O,O-diethyl ester O,O-Diethyl ethylphosphonothioate O,O-Di-ethyl ethylthiophosphinate Phosphonothioic acid, ethyl-, diethyl ester
CWCEC	2477-50-1	2B04	C12H14NO2PS	Phosphonothioic acid, methyl-, O-ethyl O-5-quinolinyl ester Phosphonothioic acid, methyl-, O-ethyl O-5-quinolyl ester
PTS-HB	2478-92-4	1A03	C8H21NO2PS.I	Ethanaminium, 2-[(ethoxymethylphosphinyl)thio]-N,N,N-trimethyl-, iodide
PTS-HB	2478-93-5	1A03	C8H20NO2PS.C2H2O4	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl]-O-(1-methylethyl) ester, ethanedioate (1:1)
PTS-HB	2478-96-8	1B10	C8H20NO3P.C2H2O4	Phosphonic acid, methyl-, 2-(dimethylamino)ethyl 1-methylethyl ester, ethanedioate (1:1)
CWCEC	2478-97-9	2B04	C9H23NO3P.I	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy)phosphinyl]oxy]-,iodide Choline, iodide, isopropyl methylphosphonate
CWCEC	2511-07-1	2B04	C6H16NO2P	Phosphonamidic acid, trimethyl-, isopropyl ester
CWCEC	2511-08-2	2B04	C7H18NO2P	Phosphonamidic acid, trimethyl-, butyl ester
PTS-HB	2511-10-6	2B04	C5H13O2PS	Phosphonothioic acid, methyl-, O,S-diethyl ester
PTS-HB	2511-11-7	2B04	C6H15O2PS	Phosphonothioic acid, ethyl-, O,S-diethyl ester
PTS-HB	2511-12-8	2B04	C5H13O2PS	Phosphonothioic acid, ethyl-, O-ethyl S-methyl ester
CWCEC	2511-13-9	2B04	C7H17O2PS	Phosphonothioic acid, propyl-, O,S-diethyl ester
PTS-HB	2511-15-1	2B04	C10H23O2PS	Phosphonothioic acid, ethyl-, O,S-dibutyl ester
PTS-HB	2511-17-3	2B04	C5H15N2OP	Phosphonic diamide, pentamethyl-
CWCEC	2511-18-4	2B04	C9H23N2OP	Phosphonic diamide, N,N,N',N'-tetraethyl-P-methyl- N,N,N',N'-Tetraethylmethylphosphondiamide
CWCEC	2511-27-5	2B04	C6H16NO2P	Phosphonamidic acid, trimethyl-, propyl ester
CWCEC	2524-01-8	2B04	C3H7Cl2PS	Phosphonothioic dichloride, propyl- Propylphosphonothioic dichloride
CWCEC	2524-15-4	2B04	C2H6ClOPS	Phosphonochloridothioic acid, methyl-, O-methyl ester O-Methyl methanephosphonothionochloridate
CWCEC	2524-16-5	2B04	C3H8ClOPS	Phosphonochloridothioic acid, methyl-, O-ethyl ester Methylthionophosphonic acid O-ethyl ester chloride Ethyl methanephosphonothionochloridate O-Ethyl methanephosphonothionochloridate O-Ethyl methylphosphonochloridothioate O-Ethyl (chloromethyl)thiophosph

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	2524-17-6	2B04	C4H10ClOPS	Phosphonochloridothioic acid, methyl-, O-(1-methylethyl) ester Phosphonochloridothioic acid, methyl-, O-isopropyl ester O-Isopropyl methanethiophosphonic chloride O-Isopropyl methanephosphonothionochloridate
CWCEC	2562-54-1	2B04	C8H20O2PS2.CH3O4S	3-Oxa-5-thia-8-thionia-4-phosphadecane, 4,8-dimethyl-, methyl sulfate, 4-oxide GD 42 Sulfonium, ethyl(2-mercaptoethyl)methyl-, methyl sulfate, S-ester with O-ethyl methylphosphonothioate O-Ethyl S-(.beta.-ethylthioethyl)methylpho
CWCEC	2592-65-6	2B04	C11H19N2O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-(2-ethyl-6-methyl-4- pyrimidinyl) ester Bayer 46676
CWCEC	2621-03-6	2B04	C6H16O4P2S	Thiodiphosphonic acid ((HO)HP(O)OHP(S)(OH)), dimethyl-, diethyl ester Phosphonic acid, methyl-, anhydride with methylphosphonothioic acid, O,O-diethyl ester Phosphonothioic acid, methyl-, anhydride with methylphosphonic acid,
CWCEC	2623-64-5	2B04	C11H18N2O3P.I	Pyridinium, 4-(4,6-dimethyl-3,5-dioxa-2-aza-4-phosphahept-1-en-1-yl)- 1-methyl-, iodide, P-oxide Pyridinium, 4-formyl-1-methyl-, iodide, O-(isopropoxymethylphosphinyl)oxime 4-PPAM 4-Formyl-1-methylpyridin
PTS-HB	2625-76-5	1A04	C3H6Cl2S	Ethane, 1-chloro-2-[(chloromethyl)thio]-
PTS-HB	2636-23-9	2B04	C11H17O3PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(ethylsulfinyl)phenyl] ester
PTS-HB	2641-09-0	1A03	C7H18NO2PS.C2H2O4	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-ethyl ester, ethanedioate (1:1)
CWCEC	2648-75-1	2B04	C29H51O3P	Cholest-5-en-3-ol (3.beta.)-, methyl methylphosphonate Cholesterol, methyl methylphosphonate Phosphonic acid, methyl-, cholesteryl methyl ester
CWCEC	2648-76-2	2B04	C39H57O5P	Androst-5-en-17-one, 3,3'-[(methylphosphinylidene)bis(oxy)]bis-, (3.beta.) (3'.beta.)- Androst-5-en-17-one, 3.beta.-hydroxy-, methylphosphonate
PTS-HB	2665-30-7	2B04	C13H12NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) O-phenyl ester
PTS-HB	2667-49-4	2B04	C8H9Cl2O2PS	Phosphonothioic acid, methyl-, O-(2,4-dichlorophenyl) O-methyl ester
PTS-HB	2703-13-1	2B04	C10H15O2PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(methylthio)phenyl] ester
CWCEC	2711-22-0	2B04	C10H10ClF3NO4PS	Phosphonothioic acid, methyl-, O-2-chloroethyl O- (.alpha.,.alpha.,.alpha.-trifluoro-4 nitro-m-tolyl) ester
CWCEC	2720-15-2	2B04	C6H12NOPS3	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with 3-[(mercaptomethyl)thio]propionitrile
CWCEC	2720-16-3	2B04	C8H16NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 3-[(mercaptomethyl)thio]propionitrile
PTS-HB	2720-17-4	2B04	C10H12BrCl2O2PS	Phosphonothioic acid, ethyl-, O-(4-bromo-2,5-dichlorophenyl) O-ethyl ester
PTS-HB	2720-18-5	2B04	C10H12BrCl2O2PS	Phosphonothioic acid, methyl-, O-(4-bromo-2,5-dichlorophenyl) O-(1-methylethyl) ester
PTS-HB	2720-19-6	2B04	C9H10BrCl2O2PS	Phosphonothioic acid, ethyl-, O-(4-bromo-2,5-dichlorophenyl) O-methyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	2720-20-9	2B04	C8H8BrCl2O2PS	Phosphonothioic acid, methyl-, O-(4-bromo-2,5-dichlorophenyl) O-methyl ester Phenol, 4-bromo-2,5-dichloro-, O-ester with O-methyl methylphosphonothioate
PTS-HB	2725-68-0	2B04	CH3Cl4P	Phosphorane, tetrachloromethyl-
CWCEC	2736-46-1	2B04	C4H5N2O3P	Phosphonic diisocyanate, ethyl- Ethylphosphinyl diisocyanate
CWCEC	2736-47-2	2B04	C5H7N2O3P	Phosphonic diisocyanate, (1-methylethyl)- Phosphonic diisocyanate, isopropyl-
CWCEC	2789-07-3	2B04	C12H16F3O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-[(trifluoromethyl)thio]-o- tolyl] ester
PTS-HB	2797-10-6	2B04	C6H16FNO2P.I	Ethanaminium, 2-[(fluoromethylphosphinyl)oxy]-N,N,N-trimethyl-, iodide
CWCEC	2798-63-2	2B04	C13H33O3PSi2	Phosphonic acid, methyl-, bis(triethylsilyl) ester Silanol, triethyl-, methylphosphonate (2:1) Bis(triethylsilyl) methylphosphonate
CWCEC	2799-58-8	2B04	C5H11Cl2O3P	Phosphonic acid, methyl-, bis(2-chloroethyl) ester Bis(2-chloroethyl) methylphosphonate
CWCEC	2824-65-9	2B04	C9H10BrCl2O2PS	Phosphonothioic acid, methyl-, O-(4-bromo-2,5-dichlorophenyl) O-ethyl ester Phenol, 4-bromo-2,5-dichloro-, O-ester with O-ethyl methylphosphonothioate
CWCEC	2829-04-1	2B04	C7H14N3OPS3	Phosphonodithioic acid, methyl-, O-ethyl S-[[(4-methyl-4H-1,2,4- triazol-3-yl)thio]methyl] ester
CWCEC	2829-05-2	2B04	C8H16N3OPS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[[(4-methyl-4H-1,2,4- triazol-3-yl)thio]methyl] ester
CWCEC	2829-09-6	2B04	C6H12N3OPS2	Phosphonodithioic acid, methyl-, O-ethyl S-(4-methyl-4H-1,2,4- triazol-3-yl) ester
CWCEC	2829-10-9	2B04	C12H17ClNO2PS3	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-[[(p-chlorophenyl)thio]methyl]-2-mercaptoacetamide
CWCEC	2829-11-0	2B04	C13H19ClNO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-[[(p-chlorophenyl)thio]methyl]-2-mercaptoacetamide
CWCEC	2829-12-1	2B04	C14H21ClNO2PS3	Phosphonodithioic acid, propyl-, O-ethyl ester, S-ester with N-[[(p-chlorophenyl)thio]methyl]-2-mercaptoacetamide
CWCEC	2829-14-3	2B04	C9H20NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-[(ethylthio)methyl]-2-mercaptoacetamide
CWCEC	2829-15-4	2B04	C8H18NO2PS3	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-[(ethylthio)methyl]-2-mercaptoacetamide
CWCEC	2829-16-5	2B04	C10H22NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-[(ethylthio)methyl]-2-mercaptopropionamide
CWCEC	2884-00-6	2B04	C8H20O2PS2.CH3O3S	Sulfonium, ethyl(2-mercaptoethyl)methyl-, methanesulfonate, S-ester with O-ethyl methylphosphonothioate Ethyl(2-mercaptoethyl)methylsulfonium methanesulfonate, S-ester with O-ethyl methylphosphonothioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	2893-43-8	2B11	C5H13NO	Ethanol, 2-(ethylmethylamino)-
CWCEC	2893-56-3	2B11	C7H17NO	Ethanol, 2-(ethylpropylamino)- 2-(Ethylpropylamino)ethanol
CWCEC	2893-61-0	2B11	C7H17NO	Ethanol, 2-[ethyl(1-methylethyl)amino]- Ethanol, 2-(ethylisopropylamino)-
CWCEC	2893-62-1	2B11	C7H17NO.C6H3N3O7	Ethanol, 2-(ethylisopropylamino)-, picrate
CWCEC	2893-64-3	2B11	C7H17NO.C6H3N3O7	Ethanol, 2-(ethylpropylamino)-, picrate
CWCEC	2894-73-7	2B04	C9H14NOPS2	Phosphonodithioic acid, methyl-, O-ethyl S-(2-pyridinylmethyl) ester Phosphonodithioic acid, methyl-, O-ethyl S-(2-pyridylmethyl) ester
CWCEC	2916-99-6	2B04	C12H18NO2PS3	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercapto-N-[(phenylthio)methyl]acetamide Acetamide, 2-mercapto-N-[(phenylthio)methyl]-, S-ester with O-ethyl methylphosphonodithioate
PTS-HB	2917-21-7	2B04	C9H11ClNO4PS	Phosphonothioic acid, ethyl-, O-(2-chloro-4-nitrophenyl) O-methyl ester
CWCEC	2928-76-9	2B04	C9H20NO2PS3	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-[(ethylthio)methyl]-2-mercaptopropionamide
CWCEC	2929-20-6	2B04	C11H13ClNO2PS2	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with [(2-chloro-4-hydroxyphenyl)thio]acetonitrile
CWCEC	2929-26-2	2B04	C13H18NO2PS2	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with [(4-hydroxy-o-tolyl)thio]acetonitrile
CWCEC	2975-59-9	2B04	C11H14NO2PS2	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with [(p-hydroxyphenyl)thio]acetonitrile Phosphonothioic acid, O-ethyl ester, O-ester with [(p-hydroxyphenyl)thio]acetonitrile
CWCEC	2975-60-2	2B04	C12H16NO2PS2	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with [(p-hydroxyphenyl)thio]acetonitrile
CWCEC	2984-63-6	2B04	C11H17O2PS2	Phosphonodithioic acid, ethyl-, O-ethyl S-(p-methoxyphenyl) ester Benzenethiol, p-methoxy-, S-ester with O-ethyl ethylphosphonodithioate
PTS-HB	2984-64-7	2B04	C10H14ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chlorophenyl) O-ethyl ester
PTS-HB	2984-65-8	2B04	C10H15OPS2	Phosphonodithioic acid, ethyl-, O-methyl S-(4-methylphenyl) ester
PTS-HB	2984-66-9	2B04	C13H21OPS2	Phosphonodithioic acid, ethyl-, S-(p-tert-butylphenyl) O-methyl ester
CWCEC	2984-67-0	2B04	C12H19OPS2	Phosphonodithioic acid, propyl-, O-ethyl S-p-tolyl ester
PTS-HB	2984-68-1	2B04	C8H11OPS2	Phosphonodithioic acid, methyl-, O-methyl S-phenyl ester
PTS-HB	2984-70-5	2B04	C9H13OPS2	Phosphonodithioic acid, ethyl-, O-methyl S-phenyl ester
CWCEC	2984-71-6	2B04	C11H17OPS2	Phosphonodithioic acid, propyl-, O-ethyl S-phenyl ester
CWCEC	2984-73-8	2B04	C12H19OPS2	Phosphonodithioic acid, ethyl-, O-isopropyl S-p-tolyl ester
CWCEC	2984-74-9	2B04	C15H25OPS2	Phosphonodithioic acid, ethyl-, S-(p-tert-butylphenyl) O-isopropyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	2991-41-5	2B04	C7H18FNO2P.HO	Ammonium, (3-hydroxypropyl)trimethyl-, hydroxide, methylphosphorofluoridate (3-Hydroxypropyl)trimethylammonium hydroxide, methylphosphorofluoridate
CWCEC	2992-08-7	2B04	C6H16FNO2P.Cl	Choline, chloride, methylphosphonofluoridate
CWCEC	2992-95-2	1A01	C5H12FO2P	Phosphonofluoridic acid, ethyl-, propyl ester
PTS-HB	3001-98-7	2B04	C7H14O6P2	2,4,8,10-Tetraoxa-3,9-diphosphaspiro[5.5]undecane, 3,9-dimethyl-, 3,9-dioxide
CWCEC	3015-73-4	2B04	C11H16NO5P	Phosphonic acid, propyl-, ethyl 4-nitrophenyl ester Phosphonic acid, propyl-, ethyl p-nitrophenyl ester
CWCEC	3019-68-9	2B04	C19H21O7P	Benzoic acid, p-hydroxy-, methyl ester, isopropylphosphonate (2:1) Phosphonic acid, isopropyl-, diester with methyl p-hydroxybenzoate Benzoic acid, p-hydroxy-, methyl ester, isopropylphosphonate
CWCEC	3024-08-6	2B04	C10H14NO4PS2	Phosphonothioic acid, methyl-, O-ethyl O-[3-(methylthio)-4- nitrophenyl] ester
CWCEC	3049-62-5	2B04	C12H16N3OPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 3-(mercaptomethyl)-1,2,3-benzotriazine-4(3H)-thione
CWCEC	3070-09-5	2B04	C10H12Cl3O2PS	Phosphonothioic acid, methyl-, O-(1-methylethyl) O-(2,4,5-trichlorophenyl) ester Phosphonothioic acid, methyl-, O-isopropyl O-(2,4,5-trichlorophenyl) ester
CWCEC	3070-10-8	2B04	C9H10Cl3O2PS	Phosphonothioic acid, methyl-, O-ethyl O-(2,4,5-trichlorophenyl) ester Phenol, 2,4,5-trichloro-, O-ester with O-ethyl methylphosphonothioate
PTS-HB	3099-88-5	2B04	C11H17OPS2	Phosphonodithioic acid, ethyl-, O-ethyl S-o-tolyl ester
CWCEC	3099-89-6	2B04	C11H17OPS2	Phosphonodithioic acid, ethyl-, O-ethyl S-m-tolyl ester
CWCEC	3101-75-5	2B04	C12H15ClNO2PS2	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with [(2-chloro-4-hydroxyphenyl)thio]acetonitrile
CWCEC	3167-69-9	2B06	C8H20NO3P	Phosphoramidic acid, diethyl-, diethyl ester Diethyl diethylphosphoramidate Diethyl N,N-diethylphosphoramidate Diethylphosphoramidic acid diethyl ester
PTS-HB	3186-12-7	2B04	C11H17O2PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(ethylthio)phenyl] ester
PTS-HB	3186-14-9	2B04	C9H13O2PS2	Phosphonothioic acid, methyl-, O-methyl O-[4-(methylthio)phenyl] ester
CWCEC	3190-83-8	2B04	C16H18NOPS3	Phosphonodithioic acid, methyl-, O-ethyl S-phenothiazin-10-ylmethyl ester
CWCEC	3208-47-7	2B04	C11H14NOPS3	Phosphonodithioic acid, methyl-, S-(2-benzothiazolylmethyl) O-ethyl ester
PTS-HB	3238-75-3	2B11	C8H19NO	Ethanol, 2-(dipropylamino)-
PTS-HB	3239-63-2	2B04	C10H15OPS2	Phosphonodithioic acid, methyl-, O-phenyl S-propyl ester
CWCEC	3240-55-9	2B04	C9H8Cl5O2PS	Phosphonothioic acid, ethyl-, O-methyl O-(pentachlorophenyl) ester
CWCEC	3240-56-0	2B04	C11H12Cl5O2PS	Phosphonothioic acid, ethyl-, O-(pentachlorophenyl) O-propyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	3247-32-3	2B04	C10H17N2O2PS2	Phosphonothioic acid, ethyl-, O-[2-(ethylthio)-6-methyl-4- pyrimidinyl] O-methyl ester BAY 39193
CWCEC	3305-16-6	2B04	C9H13O3PS2	Phosphonothioic acid, methyl-, O-methyl O-[4-(methylsulfinyl)phenyl] ester Phosphonothioic acid, methyl-, O-methyl O-[p-(methylsulfinyl)phenyl] ester BAY 30554 Phenol, p-(methylsulfinyl)-, O-ester with O-methyl methylphosphonothioate
PTS-HB	3309-71-5	2B04	C11H17O4PS2	Phosphonothioic acid, methyl-, O-ethyl O-[4-(ethylsulfonyl)phenyl] ester
CWCEC	3320-37-4	2B04	C11H12Cl3F3NO2P	Phosphonamidic acid, P-ethyl-N-(2,4,5-trichlorophenyl)-N-(trifluoromethyl)-, ethyl ester
CWCEC	3337-81-3	2B04	C12H19N2O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[6-methyl-2-(2-propenylthio)- 4-pyrimidinyl] ester Phosphonothioic acid, ethyl-, O-[2-(allylthio)-6-methyl-4-pyrimidinyl] O-ethyl ester
CWCEC	3337-82-4	2B04	C12H19N2O4PS2	Acetic acid, [(4-hydroxy-6-methyl-2-pyrimidinyl)thio]-, ethyl ester, O-ester with O-methylethylphosphonothioate Phosphonothioic acid, ethyl-, O-methyl ester, O-ester with ethyl [(4-hydroxy-6-methyl-2-pyrimid
CWCEC	3337-83-5	2B04	C9H16N3O2PS	Phosphonothioic acid, ethyl-, O-(2-amino-6-methyl-4-pyrimidinyl) O-ethyl ester
CWCEC	3337-84-6	2B04	C8H14N3O2PS	Phosphonothioic acid, ethyl-, O-(2-amino-6-methyl-4-pyrimidinyl) O-methyl ester
CWCEC	3347-31-7	2B04	C5H13OPS2	Phosphonodithioic acid, methyl-, O,S-diethyl ester O,S-Diethyl methyldithiophosphonate
CWCEC	3347-32-8	2B04	C6H15OPS2	Phosphonodithioic acid, ethyl-, O,S-diethyl ester
CWCEC	3348-62-7	2B04	C6H16O6P2	Phosphonic acid, methyl-, monomethyl ester, anhydride with diethyl phosphate Ethyl phosphate, (EtO)2(HO)PO, anhydride with methyl methylphosphonate Phosphonic acid, methyl-, anhydride with diethyl phosphate, methyl ester Isohypophosphoric acid, methyl-, d
PTS-HB	3348-63-8	2B04	C4H12O6P2	Phosphonic acid, methyl-, monomethyl ester, anhydride with dimethyl phosphate
CWCEC	3371-31-1	2B04	C11H12Cl3O2PS	Phosphonothioic acid, methyl-, O-[2-chloro-1-(2,4- dichlorophenyl)vinyl] O ethyl ester
CWCEC	3393-47-3	2B04	C18H24O4P2S4	Phosphonothioic acid, methyl-, O-ethyl ester, O,O-diester with 4,4'-dithiodiphenol
CWCEC	3393-53-1	2B04	C22H32O4P2S4	Phosphonothioic acid, ethyl-, O-ethyl ester, O,O-diester with 4,4'-dithiodi-m-cresol
CWCEC	3393-55-3	2B04	C20H28O4P2S4	Phosphonothioic acid, methyl-, O-ethyl ester, O,O-diester with 4,4'-dithiodi-m-cresol
CWCEC	3438-21-9	2B04	C39H57O5P	Testosterone, methylphosphonate
CWCEC	3438-22-0	2B04	C37H45O5P	Estrone, 3,3'-(methylphosphonate)
CWCEC	3450-34-8	2B04	C3H9ClNPS	Phosphonamidothioic chloride, trimethyl-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	3450-35-9	2B04	C5H13ClNPS	Phosphonamidothioic chloride, N,N-diethyl-P-methyl-
CWCEC	3470-63-1	2B04	C8H20O4P2S2	Phosphonothioic acid, ethyl-, O-ethyl ester, anhydride with O,O-diethyl phosphorothioate, (+)- Ethyl phosphorothioate, (EtO)2(HO)PS, anhydride with O-ethyl ethylphosphonothioate, (+)- Phosphorothioic aci
CWCEC	3479-32-1	2B04	C7H13O3P	Phosphonic acid, methyl-, di-2-propenyl ester Phosphonic acid, methyl-, diallyl ester Diallyl methylphosphonate
CWCEC	3494-50-6	2B04	C20H28O4P2S4	Phosphonothioic acid, ethyl-, O,O'-(dithiodi-p-phenylene) O,O'-diethyl ester Phosphonothioic acid, ethyl-, O-ethyl ester, O,O-diester with 4,4'-dithiodiphenol
CWCEC	3494-52-8	2B04	C20H26Cl2O4P2S4	Phosphonothioic acid, ethyl-, O,O'-[dithiobis(3-chloro-p-phenylene)] O,O'-diethyl ester
PTS-HB	3520-76-1	2B04	C8H22N2O4P2 2Na	Phosphonamidic acid, N,N'-1,2-ethanediylbis[P-(1-methylethyl)-, disodium salt
CWCEC	3541-62-6	2B04	C9H12ClOPS2	Phosphonodithioic acid, methyl-, S-(p-chlorophenyl) O-ethyl ester
CWCEC	3541-63-7	2B04	C9H12ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chlorophenyl) O-methyl ester Phosphonodithioic acid, ethyl-, S-(p-chlorophenyl) O-methyl ester O-Methyl S-(p-chlorophenyl) ethylphosphonodithioate
CWCEC	3541-64-8	2B04	C8H10ClOPS2	Phosphonodithioic acid, methyl-, S-(p-chlorophenyl) O-methyl ester
CWCEC	3561-80-6	2B04	C12H17N2OPS2	Phosphonodithioic acid, ethyl-, S-(2-benzimidazolylmethyl) O-ethyl ester
PTS-HB	3563-36-8	1A04	C6H12Cl2S2	Ethane, 1,2-bis[(2-chloroethyl)thio]-
PTS-HB	3563-52-8	2B04	C10H13ClNO4PS	Phosphonothioic acid, ethyl-, O-(2-chloro-4-nitrophenyl) O-ethyl ester
CWCEC	3576-59-8	2B04	C11H21Cl2O3P	Phosphonic acid, propyl-, 2,2-dichlorovinyl hexyl ester
CWCEC	3576-60-1	2B04	C8H15Cl2O3P	Phosphonic acid, propyl-, 2,2-dichloroethenyl propyl ester Phosphonic acid, propyl-, 2,2-dichlorovinyl propyl ester
CWCEC	3584-88-1	2B04	C16H37NO5P2	Phosphoramidic acid, butyl(propoxypropylphosphinyl)-, dipropyl ester
CWCEC	3647-65-2	2B04	C10H10Cl5O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-(pentachlorophenyl) ester
CWCEC	3659-48-1	2B04	C17H15Cl2O7P	Benzoic acid, 3-chloro-4-hydroxy-, isopropylphosphonate
CWCEC	3659-49-2	2B04	C12H14NO3PS	Phosphonothioic acid, methyl-, O-ethyl O-(3-phenyl-5-isoxazolyl) ester
CWCEC	3659-50-5	2B04	C13H16NO3PS	Phosphonothioic acid, ethyl-, O-ethyl O-(3-phenyl-5-isoxazolyl) ester
CWCEC	3663-48-7	2B04	C17H33O7P	Phosphonic acid, methyl-, bis[3-(2,2-dimethyl-1,3-dioxolan-4-yl)propyl] ester
CWCEC	3663-49-8	2B04	C7H17O7P	Phosphonic acid, methyl-, bis(2,3-dihydroxypropyl) ester Glycerol, 1,1'-diester with methylphosphonic acid Glycerol, 1,1'-(methylphosphonate) Glycerol, 1,1'-methylphosphonate
CWCEC	3663-59-0	2B04	C6H11N2O2PS2	Phosphonothioic acid, methyl-, O-ethyl O-3-methyl-1,2,4-thiadiazol-5-yl ester
CWCEC	3663-60-3	2B04	C6H11N2O3PS	Phosphonic acid, methyl-, ethyl 3-methyl-1,2,4-thiadiazol-5-yl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	3675-84-1	2B04	C13H29O2PS	Phosphonothioic acid, methyl-, S-decyl O-ethyl ester O-Ethyl S-decyl methylthiophosphonate
CWCEC	3675-85-2	2B04	C11H25O2PS	Phosphonothioic acid, methyl-, O-ethyl S-octyl ester O-Ethyl S-octyl methylthiophosphonate LG 66
CWCEC	3675-86-3	2B04	C10H23O2PS	Phosphonothioic acid, methyl-, O-ethyl S-heptyl ester O-Ethyl S-heptyl methylthiophosphonate LG 65
CWCEC	3675-87-4	2B04	C9H21O2PS	Phosphonothioic acid, methyl-, O-ethyl S-hexyl ester O-Ethyl S-hexyl methylthiophosphonate LG 63 O-Ethyl S-hexyl methylphosphonothioate
CWCEC	3675-88-5	2B04	C8H19O2PS	Phosphonothioic acid, methyl-, O-ethyl S-pentyl ester O-Ethyl S-pentyl methylthiophosphonate LG 64 O-Ethyl S-pentyl methylphosphonothioate
CWCEC	3675-93-2	2B04	C9H21O2PS	Phosphonothioic acid, methyl-, S-(3,3-dimethylbutyl) O-ethyl ester 1-Butanethiol, 3,3-dimethyl-, S-ester with O-ethyl methylphosphonothioate O-Ethyl S-(3,3-dimethylbutyl) methylthiophosphonate LG 56 LG 56 (pesticide)
CWCEC	3734-88-1	2B04	C15H33O2PS2	Phosphonothioic acid, methyl-, S-[2-(decylthio)ethyl] O-ethyl ester Ethanethiol, 2-(decylthio)-, S-ester with O-ethyl methylphosphonothioate O-Ethyl S-[.beta.-(decylthio)ethyl] methylthiophosphonate
CWCEC	3734-89-2	2B04	C11H17O2PS2	Phosphonothioic acid, ethyl-, O-methyl O-[3-methyl-4-(methylthio)phenyl] ester Phosphonothioic acid, ethyl-, O-methyl O-[4-(methylthio)-m-tolyl] ester m-Cresol, 4-(methylthio)-, O-ester with O-methyl ethylphosphonothioate Bayer
CWCEC	3734-96-1	2A01	C10H24NO3PS.C7H8O3S	Phosphorothioic acid, S-[2-(diethylamino)ethyl] O,O-diethyl ester, p-toluenesulfonate Chipman 6200
PTS-HB	3734-97-2	2A01	C10H24NO3PS.C2H2O4	Phosphorothioic acid, S-[2-(diethylamino)ethyl] O,O-diethyl ester, ethanedioate (1:1)
PTS-HB	3735-97-5	2B04	C10H14NO5P	Phosphonic acid, methyl-, 1-methylethyl 4-nitrophenyl ester
CWCEC	3735-98-6	2B04	C9H12NO5P	Phosphonic acid, methyl-, ethyl 4-nitrophenyl ester Phosphonic acid, methyl-, ethyl p-nitrophenyl ester Ethyl 4-nitrophenyl methylphosphonate O-Ethyl p-nitrophenyl methylphosphonate Ethyl p-nitrophenyl methylphosphonate
CWCEC	3759-39-5	2B04	C9H21O3P	Phosphonic acid, (1-methylethyl)-, bis(1-methylethyl) ester Phosphonic acid, isopropyl-, diisopropyl ester Isopropylphosphonic acid diisopropyl ester
CWCEC	3773-45-3	2B04	C16H36O2PS2:CH3O4S	3-Oxa-5-thia-8-thionia-4-phosphaoctadecane, 4,8-dimethyl-, methyl sulfate, 4-oxide Sulfonium, decyl(2-mercaptoethyl)methyl-, methyl sulfate, S-ester with O-ethylmethylphosphonothioate Gd 108 O-Ethyl S-[.
CWCEC	3788-49-6	2B04	C10H24BrNO5P2	Phosphoramidic acid, [(2-bromoethoxy)ethylphosphinyl]ethyl-, diethyl ester Phosphonamidic acid, N,P-diethyl-N-phosphono-, P-2-bromoethyl P',P'-diethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	3788-93-0	2B04	C11H15Cl2OPS2	Phosphonodithioic acid, methyl-, O-(4-chlorobutyl) S-(4-chlorophenyl) ester Phosphonodithioic acid, methyl-, O-4-chlorobutyl S-p-chlorophenyl ester
CWCEC	3791-55-7	2B04	C6H14ClO2PS	Phosphonothioic acid, ethyl-, S-(2-chloroethyl) O-ethyl ester Ethanethiol, 2-chloro-, S-ester with O-ethyl ester ethylphosphonothioate
CWCEC	3791-57-9	2B04	C9H12NO4PS	Phosphonothioic acid, methyl-, S-ethyl O-(4-nitrophenyl) ester, (.+-.)- Phosphonothioic acid, methyl-, S-ethyl O-(p-nitrophenyl) ester, (.+-.)- (.+-.)-S-Ethyl O-p-nitrophenyl methylphosphonothioate
CWCEC	3791-58-0	2B04	C10H14NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) S-propyl ester, (.+-.)- Phosphonothioic acid, methyl-, O-(p-nitrophenyl) S-propyl ester, (.+-.)- S-Propyl-p-nitrophenyl methylphosphonothiolate, (.+-.)-
CWCEC	3791-59-1	2B04	C11H16NO4PS	Phosphonothioic acid, methyl-, S-butyl O-(4-nitrophenyl) ester, (.+-.)- Phosphonothioic acid, methyl-, S-butyl O-(p-nitrophenyl) ester, (.+-.)-
CWCEC	3791-60-4	2B04	C12H18NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) S-pentyl ester, (.+-.)- Phosphonothioic acid, methyl-, O-(p-nitrophenyl) S-pentyl ester, (.+-.)- (.+-.)-O-p-Nitrophenyl S-pentyl methylphosphonothioate
PTS-HB	3873-20-9	2B04	C7H18FNO2P.I	Ammonium, (2-hydroxypropyl)trimethyl-, iodide, methylphosphonofluoridate
CWCEC	3901-46-0	2B04	C7H13N2O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-3-methyl-1,2,4-thiadiazol-5-yl ester
CWCEC	3913-28-8	2B04	C11H12NO4PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 4-hydroxyphthalimide
CWCEC	3913-35-7	2B04	C14H18NO4PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 4-hydroxy-N-propylphthalimide
CWCEC	3913-38-0	2B04	C14H16NO4PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with N-allyl-4-hydroxyphthalimide
CWCEC	3913-41-5	2B04	C14H18NO4PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 4-hydroxy-N-isopropylphthalimide
CWCEC	3931-88-2	2B04	C2H5Br2PS	Phosphonothioic dibromide, ethyl- Ethylphosphonothioic dibromide
CWCEC	3935-36-2	2B04	C15H24ClN2O4PS	Phosphonothioic acid, ethyl-, O-[4-chloro-.alpha.-(diethylamino)-5-nitro-o tolyl] O-ethyl ester o-Cresol, 4-chloro-.alpha.-(diethylamino)-5-nitro-, O-ester with O-ethyl ethylphosphonothioate
PTS-HB	3954-73-2	2B04	C12H14ClF3NO4PS	Phosphonothioic acid, methyl-, O-(4-chlorobutyl) O-[4-nitro-3-(trifluoromethyl)phenyl] ester
CWCEC	3976-59-8	2B04	C13H25O7P	Tartronic acid, diethyl ester, ester with propyl propylphosphonate Phosphonic acid, propyl-, propyl ester, ester with diethyl tartronate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	3976-60-1	2B04	C13H25O7P	Tartronic acid, diethyl ester, ester with isopropyl isopropylphosphonate Phosphonic acid, isopropyl-, isopropyl ester, ester with diethyl tartronate
CWCEC	3981-45-1	2B04	C6H17N2PS	Phosphonothioic diamide, P-ethyl-N,N,N',N'-tetramethyl-
CWCEC	4036-22-0	2B04	C11H21O7P	Tartronic acid, diethyl ester, ethyl ethylphosphonate Phosphonic acid, ethyl-, ethyl ester, ester with diethyl tartronate
CWCEC	4051-14-3	2B04	C8H10NO4PS	Phosphonothioic acid, methyl-, S-methyl O-(4-nitrophenyl) ester, (.+-.)- Phosphonothioic acid, methyl-, S-methyl O-(p-nitrophenyl) ester, (.+-.)- S-Methyl-p-nitrophenyl methylphosphonothiolate, (.+-.)-
CWCEC	4072-79-1	2B04	C5H15N2O3P	Phosphonic acid, methyl-, bis(2-aminoethyl) ester Ethanol, 2-amino-, methylphosphonate Ethanol, 2-amino-, methylphosphonate (ester)
CWCEC	4081-13-4	2B04	C11H14NO3PS	Phosphonothioic acid, methyl-, O-(4-cyano-2-methoxyphenyl) O-ethyl ester Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with vanillonitrile
CWCEC	4103-99-5	2B04	C10H21O3PS3	Propionic acid, 3-(ethylthio)-2-mercapto-, ethyl ester, S-ester with O-ethylmethylphosphonodithioate Phosphonodithioic acid, methyl-, O-ethyl S-ester with ethyl 3-(ethylthio)-2-mercaptopropionate
CWCEC	4126-91-4	2B04	C13H21O3P	Phosphonic acid, methyl-, benzyl neopentyl ester 1-Propanol, 2,2-dimethyl-, benzyl methylphosphonate
CWCEC	4145-92-0	2B04	C14H28O6P2S5	Acetic acid, thiobis[mercapto-, dimethyl ester, S,S-diester with O-ethyl ethylphosphonodithioate
CWCEC	4167-38-8	2B04	C21H41O7P	Phosphonic acid, methyl-, bis[4-(2-ethyl-2-methyl-1,3-dioxolan-4-yl)butyl] ester 1,3-Dioxolane-4-butanol, 2-ethyl-2-methyl-, methylphosphonate (2:1)
CWCEC	4167-39-9	2B04	C19H33O7P	Phosphonic acid, methyl-, bis(1,4-dioxaspiro[4.5]dec-2-ylmethyl) ester 1,4-Dioxaspiro[4.5]decane-2-methanol, methylphosphonate
CWCEC	4186-22-5	2B04	C10H23O2PS3	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with hydroxy-2-propanone, diethylmercaptole
CWCEC	4202-85-1	2B04	C13H29O7P	Phosphonic acid, methyl-, bis(5,6-dihydroxyhexyl) ester 1,2,6-Hexanetriol, 6,6'-(methylphosphonate) 1,2,6-Hexanetriol, 6,6'-methylphosphonate
PTS-HB	4206-94-4	2B04	CH5O2P	Phosphinic acid, methyl-
CWCEC	4230-65-3	2B04	C11H15ClNO4PS	Phosphonothioic acid, methyl-, O-(4-chlorobutyl) O-(p-nitrophenyl) ester 1-Butanol, 4-chloro-, o-ester with o-p-nitrophenyl methylphosphonothioate
CWCEC	4230-66-4	2B04	C10H13ClNO4PS	Phosphonothioic acid, methyl-, O-(3-chloropropyl) O-(p-nitrophenyl) ester
CWCEC	4230-67-5	2B04	C9H11BrNO4PS	Phosphonothioic acid, methyl-, O-(2-bromoethyl) O-(p-nitrophenyl) ester
CWCEC	4230-68-6	2B04	C10H13BrNO4PS	Phosphonothioic acid, ethyl-, O-(2-bromoethyl) O-(p-nitrophenyl) ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4230-69-7	2B04	C10H13BrNO4PS	Phosphonothioic acid, methyl-, O-(3-bromopropyl) O-(p-nitrophenyl) ester 1-Propanol, 3-bromo-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-70-0	2B04	C9H11ClNO4PS	Phosphonothioic acid, methyl-, O-(2-chloroethyl) O-(p-nitrophenyl) ester
CWCEC	4230-71-1	2B04	C10H13ClNO4PS	Phosphonothioic acid, ethyl-, O-(2-chloroethyl) O-(p-nitrophenyl) ester
CWCEC	4230-72-2	2B04	C13H19ClNO4PS	Phosphonothioic acid, methyl-, O-(6-chlorohexyl) O-(p-nitrophenyl) ester 1-Hexanol, 6-chloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-73-3	2B04	C10H12Cl2NO4PS	Phosphonothioic acid, methyl-, O-(2,3-dichloropropyl) O-(p-nitrophenyl) ester 1-Propanol, 2,3-dichloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-74-4	2B04	C10H12Cl2NO4PS	Phosphonothioic acid, methyl-, O-[2-chloro-1-(chloromethyl)ethyl] O-(p-nitrophenyl) ester 2-Propanol, 1,3-dichloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-76-6	2B04	C9H10Cl2NO4PS	Phosphonothioic acid, methyl-, O-(2,2-dichloroethyl) O-(p-nitrophenyl) ester Ethanol, 2,2-dichloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-77-7	2B04	C11H15ClNO4PS	Phosphonothioic acid, propyl-, O-(2-chloroethyl) O-(p-nitrophenyl) ester
CWCEC	4230-79-9	2B04	C9H9F3NO4PS	Phosphonothioic acid, methyl-, O-(p-nitrophenyl) O-(2,2,2-trifluoroethyl) ester Ethanol, 2,2,2-trifluoro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-80-2	2B04	C9H9Cl3NO4PS	Phosphonothioic acid, methyl-, O-(p-nitrophenyl) O-(2,2,2-trichloroethyl) ester Ethanol, 2,2,2-trichloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4230-81-3	2B04	C11H15ClNO4PS	Phosphonothioic acid, isopropyl-, O-(2-chloroethyl) O-(p-nitrophenyl) ester
CWCEC	4241-30-9	2B04	C9H20FOPS	Phosphonofluoridothioic acid, methyl-, O-(1-methylheptyl) ester 2-Octanol, methylphosphonofluoridothioate
CWCEC	4241-31-0	2B04	C7H16FOPS	Phosphonofluoridothioic acid, methyl-, O-(1,3-dimethylbutyl) ester 2-Pentanol, 4-methyl-, methylphosphonofluoridothioate
CWCEC	4241-33-2	2B04	C8H16FOPS	Phosphonofluoridothioic acid, methyl-, O-cycloheptyl ester Cycloheptanol, methylphosphonofluoridothioate
CWCEC	4241-34-3	2B04	C7H14FOPS	Phosphonofluoridothioic acid, methyl-, O-cyclohexyl ester O-Cyclohexyl methylphosphonofluoridothioate
CWCEC	4241-35-4	2B04	C6H12FOPS	Phosphonofluoridothioic acid, methyl-, O-cyclopentyl ester Cyclopentanol, methylphosphonofluoridothioate
CWCEC	4241-36-5	2B04	C5H12FOPS	Phosphonofluoridothioic acid, methyl-, O-butyl ester O-Butyl methylphosphonofluoridothioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4241-37-6	2B04	C4H10FOPS	Phosphonofluoridothioic acid, methyl-, O-(1-methylethyl) ester Phosphonofluoridothioic acid, methyl-, O-isopropyl ester O-Isopropyl methylphosphonofluoridothioate
CWCEC	4241-38-7	2B04	C4H10FOPS	Phosphonofluoridothioic acid, methyl-, O-propyl ester
CWCEC	4241-39-8	2B04	C3H8FOPS	Phosphonofluoridothioic acid, methyl-, O-ethyl ester O-Ethyl methylphosphonofluoridothioate
CWCEC	4259-16-9	2B04	C9H20NO2P	Phosphonamidic acid, trimethyl-, cyclohexyl ester
CWCEC	4259-18-1	2B04	C10H24NO2P	Phosphonamidic acid, P-ethyl-N,N-dimethyl-, hexyl ester
PTS-HB	4261-68-1	2B10	C8H18ClN.ClH	2-Propanamine, N-(2-chloroethyl)-N-(1-methylethyl)-, hydrochloride
CWCEC	4365-59-7	2B04	C10H12Cl2NO4PS	Phosphonothioic acid, methyl-, O-(3,3-dichloropropyl) O-(p-nitrophenyl) ester 1-Propanol, 3,3-dichloro-, O-ester with O-p-nitrophenyl methylphosphonothioate
CWCEC	4375-69-3	2B04	C14H28O6P2S5	Acetic acid, thiobis[mercapto-, diethyl ester, S,S-diester with O-ethylmethylphosphonodithioate Phosphonodithioic acid, O-ethyl, methyl, S,S-diester with diethyl thiobis[mercaptoacetate]
CWCEC	4405-78-1	2B04	C14H17Cl4N2O3PS	Phthalamic acid, 3,4,5,6-tetrachloro-N,N-dimethyl-, anhydride with P-ethyl-N,N-dimethylphosphonamidothioic acid Phosphonamidothioic acid, P-ethyl-N,N-dimethyl-, anhydride with 3,4,5,6-tetrachloro-N,N-dimethy
CWCEC	4409-51-2	2B04	C6H15N2O2PS	Carbamic acid, dimethyl-, anhydride with trimethylphosphonamidothioic acid Phosphonamidothioic acid, trimethyl-, anhydride with dimethylcarbamic acid
CWCEC	4409-54-5	2B04	C4H12NO3PS2	Amidosulfurous acid, dimethyl-, anhydride with O-methyl methylphosphonothioate Phosphonothioic acid, methyl-, O-methyl ester, anhydride with dimethylamidosulfurous acid Phosphonothioic acid, methyl-, O-m
CWCEC	4422-41-7	2B04	C16H32O6P2S5	Acetic acid, thiobis[mercapto-, diethyl ester, S,S-diester with O-ethylethylphosphonodithioate
CWCEC	4470-77-3	2B04	C11H15ClNO4PS	Phosphonothioic acid, ethyl-, O-3-chloropropyl O-p-nitrophenyl ester
CWCEC	4519-65-7	2B04	C3H3N2OPS2	Phosphonic diisothiocyanate, methyl-
CWCEC	4519-93-1	2B04	C5H11Cl2PS2	Phosphonochloridodithioic acid, ethyl-, 2-chloropropyl ester
CWCEC	4520-40-5	2B04	C10H16NO3P	Phosphonic acid, methyl-, m-(dimethylamino)phenyl methyl ester
CWCEC	4520-41-6	2B04	C12H20NO3P	Phosphonic acid, ethyl-, m-(dimethylamino)phenyl ethyl ester
CWCEC	4520-43-8	2B04	C10H14NO4PS	Phosphonothioic acid, ethyl-, O-ethyl S-p-nitrophenyl ester
CWCEC	4526-11-8	2B04	C11H27NO4P2	Phosphonamidic acid, N,N-diethyl-P-methyl-, anhydride with dipropyl phosphite Propyl phosphite, (PrO)2(HO)P, anhydride with N,N-diethyl-P-methylphosphonamidic acid Phosphonamidic acid, N,N-diethyl-P-met

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4526-12-9	2B04	C13H31NO4P2	Phosphonamidic acid, N,N-diethyl-P-methyl-, anhydride with dibutyl phosphite Butyl phosphite ((BuO)2(HO)P), anhydride with N,N-diethyl-P-methylphosphonamidic acid Phosphonamidic acid, N,N-diethyl-P-meth
CWCEC	4526-13-0	2B04	C13H33N3O2P2	Phosphonamidic acid, N,N-diethyl-P-methyl-, anhydride with tetraethylphosphorodiamidous acid Phosphorodiamidous acid, tetraethyl-, anhydride with N,N-diethyl-P-methylphosphonamidic acid
CWCEC	4526-14-1	2B04	C15H28N2O2P2	Phosphonamidic acid, N,N-diethyl-P-methyl-, anhydride with N,N-diethyl-P-phenylphosphonamidous acid Phosphonamidous acid, N,N-diethyl-P-phenyl-, anhydride with N,N-diethyl-P-methylphosphonamidic acid
CWCEC	4526-22-1	2B04	C10H25NO3P2S	Phosphonic acid, methyl-, monoanhydride with N,N-diethyl-P-methylphosphonamidothioic acid, isobutyl ester Phosphonamidothioic acid, N,N-diethyl-P-methyl-, anhydride with obutyl methylphosphonate Phospho
CWCEC	4529-56-0	2B04	C10H16NO2P	Phosphonamidic acid, trimethyl-, m-tolyl ester
CWCEC	4529-58-2	2B04	C12H20NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, m-tolyl ester
CWCEC	4529-60-6	2B04	C10H16NO2P	Phosphonamidic acid, trimethyl-, p-tolyl ester
CWCEC	4529-61-7	2B04	C12H20NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, p-tolyl ester
CWCEC	4532-03-0	2B04	C8H10NO5P	Phosphonic acid, methyl-, methyl o-nitrophenyl ester
CWCEC	4532-04-1	2B04	C10H14NO5P	Phosphonic acid, ethyl-, ethyl o-nitrophenyl ester
CWCEC	4532-07-4	2B04	C8H10NO5P	Phosphonic acid, methyl-, methyl m-nitrophenyl ester
PTS-HB	4535-76-6	2B11	C8H19NO.ClH	Ethanol, 2-(dipropylamino)-, hydrochloride
CWCEC	4535-77-7	2B11	C8H19NO	Ethanol, 2-(isopropylpropylamino)-
PTS-HB	4535-86-8	2B10	C8H18ClN.ClH	1-Propanamine, N-(2-chloroethyl)-N-propyl-, hydrochloride
PTS-HB	4535-88-0	2B10	C5H12ClN.ClH	Ethanamine, 2-chloro-N-ethyl-N-methyl-, hydrochloride
CWCEC	4535-89-1	2B10	C8H18ClN.ClH	Propylamine, N-(2-chloroethyl)-N-isopropyl-, hydrochloride
CWCEC	4537-61-5	2B04	C11H17O3P	Phosphonic acid, ethyl-, ethyl phenylmethyl ester Phosphonic acid, ethyl-, benzyl ethyl ester
CWCEC	4537-62-6	2B04	C16H19O3P	Phosphonic acid, ethyl-, dibenzyl ester
CWCEC	4553-70-2	2B04	C13H21O7P	2-Propenoic acid, 2-methyl-, (methylphosphinylidene)bis(oxy-2,1-ethanediyl) ester Phosphonic acid, methyl-, bis(2-hydroxyethyl) ester dimethacrylate Ethy ene glycol. methylphosphonate (2:1) dimethacrylate Methacrylic acid, 2-hyd
CWCEC	4581-09-3	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-(1-ethylpropyl) S-(5-ethyltetrahydro-2-oxo-3-furanyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-1-ethylpropylmethylphosphonodithioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4581-10-6	2B04	C13H23O3PS2	Phosphonodithioic acid, methyl-, O-cyclohexyl S-(5-ethyltetrahydro-2-oxo-3-furanyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with cyclohexylmethylphosphonodithioate
CWCEC	4581-11-7	2B04	C17H33O3PS2	Phosphonodithioic acid, methyl-, O-decyl S-(5-ethyltetrahydro-2-oxo- 3-furanyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with decylmethylphosphonodithioate
PTS-HB	4584-46-7	2B10	C4H10ClN.ClH	Ethanamine, 2-chloro-N,N-dimethyl-, hydrochloride
CWCEC	4606-72-8	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-(2-methylpropyl) S-(tetrahydro-5-methyl-2-oxo-3-furanyl) ester Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isobutylmethylphosphonodithioate
CWCEC	4606-75-1	2B04	C10H18ClO3PS2	Phosphonodithioic acid, methyl-, O-butyl S-[5- (chloromethyl)tetrahydro-2-oxo-3-furanyl] ester Valeric acid, 5-chloro-4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-butylmethylphosphonodithioate
CWCEC	4606-76-2	2B04	C9H16BrO3PS2	Phosphonodithioic acid, methyl-, S-(4-bromotetrahydro-2-oxo-3- furanyl) O-butyl ester Butyric acid, 3-bromo-4-hydroxy-2-mercapto-, .gamma.-lactone, ester with O-butylmethylphosphonodithioate
CWCEC	4606-77-3	2B04	C13H21O4PS3	Phosphonotrithioic acid, methyl-, bis(5-ethyltetrahydro-2-oxo-3- furanyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, thylphosphonotrithioate
CWCEC	4606-78-4	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-butyl S-(tetrahydro-6-methyl-2- oxo-2H pyran-3-yl) ester Hexanoic acid,·5-hydroxy-2-mercapto-, .delta.-lactone, S-ester with O-butylmethylphosphonodithioate
CWCEC	4625-66-5	2B04	C10H19O4PS	Phosphonothioic acid, methyl-, O-butyl S-(tetrahydro-5-methyl-2-oxo- 3-furanyl) ester Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with butyl methylphosphonothioate
CWCEC	4625-67-6	2B04	C9H17O4PS	Phosphonothioic acid, methyl-, O-(1-methylethyl) S-(tetrahydro-5-methyl-2-oxo-3-furanyl) ester Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isopropylmethylphosphonothioate
CWCEC	4625-76-7	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-ethyl S-(5-ethyltetrahydro-2-oxo- 3-furanyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with ethylmethylphosphonodithioate
CWCEC	4625-77-8	2B04	C11H21O3PS2	Phosphorodithioic acid, methyl-, S-(5-ethyltetrahydro-2-oxo-3- furanyl) O-(1-methylpropyl)ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with sec-butylmethylphosphonodithioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4625-78-9	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, S-(5-ethyltetrahydro-2-oxo-3- furanyl) O-(3-methylbutyl)ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with isopentylmethylphosphonodithioate
CWCEC	4625-79-0	2B04	C13H25O3PS2	Phosphonodithioic acid, methyl-, S-(5-ethyltetrahydro-2-oxo-3- furanyl) O-(4-methylpentyl) ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isohexylmethylphosphonodithioate
CWCEC	4625-80-3	2B04	C9H17O3PS2	Phosphonodithioic acid, ethyl-, S-(5-ethyltetrahydro-2-oxo-3- furanyl) O-methyl ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with methylethylphosphonodithioate
CWCEC	4625-81-4	2B04	C11H21O3PS2	Phosphonodithioic acid, ethyl-, S-(5-ethyltetrahydro-2-oxo-3- furanyl) O-propyl ester Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with propylethylphosphonodithioate
CWCEC	4626-50-0	2B04	C10H18BrO3PS2	Phosphonodithioic acid, methyl-, S-[5-(bromomethyl)tetrahydro-2-oxo- 3-furanyl] O-butyl ester Valeric acid, 5-bromo-4-hydroxy-2-mercapto-, .gamma.-lactone, ester with O-butylmethylphosphonodithioate
PTS-HB	4628-12-0	2B04	C11H25O3P	Phosphonic acid, propyl-, dibutyl ester
CWCEC	4633-08-3	2B04	C9H17O2PS3	Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, isopropyl methylphosphonotrithioate
CWCEC	4633-10-7	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-pentyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-pentylmethylphosphonodithioate
CWCEC	4633-11-8	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-isopentyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isopentylmethylphosphonodithio
CWCEC	4633-12-9	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-1-methylbutyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-1-methylbutylmethylphospho
CWCEC	4633-13-0	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-1-ethylpropyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-1-ethylpropylmethylphospho
CWCEC	4633-14-1	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-sec-butyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-sec-butylmethylphosphonodithio

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4633-15-2	2B04	C11H19O3PS2	Phosphonodithioic acid, methyl-, O-cyclopentyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-cyclopentylmethylphosphonodi
CWCEC	4633-16-3	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-neopentyl ester, S-ester with dihydro-3 mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-iactone, S-ester with O-neopentylmethylphosphonodithio
CWCEC	4633-17-4	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-hexyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-hexylmethylphosphonodithioate
CWCEC	4633-18-5	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-isohexyl ester, S-ester with .dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isohexylmethylphosphonodithioat
CWCEC	4633-19-6	2B04	C12H21O3PS2	Phosphonodithioic acid, methyl-, O-cyclohexyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-cyclohexylmethylphosphonodith
CWCEC	4633-20-9	2B04	C14H27O3PS2	Phosphonodithioic acid, methyl-, O-1-methylheptyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone 2-Octanol, O-ester with methylphosphonodithioic acid S-ester with 4-hydroxy-2-mercaptovaleric acid gamma.-lactone V
CWCEC	4633-22-1	2B04	C8H15O3PS2	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone , S-ester with O-methylethylphosphonodithioate
CWCEC	4633-23-2	2B04	C11H21O3PS2	Phosphonodithioic acid, ethyl-, O-butyl ester S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-butylethylphosphonodithioate
CWCEC	4633-24-3	2B04	C11H21O3PS2	Phosphonodithioic acid, ethyl-, O-isobutyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isobutylethylphosphonodithioate
CWCEC	4633-25-4	2B04	C9H17O3PS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-ethylethylphosphonodithioate
CWCEC	4633-26-5	2B04	C10H19O3PS2	Phosphonodithioic acid, ethyl-, O-propyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-propylethylphosphonodithioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4633-27-6	2B04	C10H19O3PS2	Phosphonodithioic acid, ethyl-, O-isopropyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isopropylethylphosphonodithioat
CWCEC	4633-28-7	2B04	C13H25O3PS2	Phosphonodithioic acid, ethyl-, O-hexyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-hexylethylphosphonodithioate
CWCEC	4633-29-8	2B04	C11H21O3PS2	Phosphonodithioic acid, ethyl-, O-sec-butyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-sec-butylethylphosphonodithioat
CWCEC	4633-30-1	2B04	C12H23O3PS2	Phosphonodithioic acid, ethyl-, O-pentyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-pentylethylphosphonodithioate
CWCEC	4633-31-2	2B04	C12H21O3PS2	Phosphonodithioic acid, ethyl-, O-cyclopentyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-cyclopentylethylphosphonodith
CWCEC	4633-32-3	2B04	C13H23O3PS2	Phosphonodithioic acid, ethyl-, O-cyclohexyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-cyclohexylethylphosphonodithio
CWCEC	4633-33-4	2B04	C10H19O3PS2	Phosphonodithioic acid, propyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-ethylpropylphosphonodithioate
CWCEC	4633-34-5	2B04	C10H19O3PS2	Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with 4-hydroxy-2-mercaptovalericacid .gam
CWCEC	4633-37-8	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-butyl ester, S-ester with dihydro-3-mercapto-3-methyl-2(3H)-furanone Butyric acid, 4-hydroxy-2-mercapto-2-methyl-, .gamma.-lactone, S-ester with O-butylmethylphosphonodithi
CWCEC	4637-80-3	2B04	C7H13O3PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-ethyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-mer
CWCEC	4637-81-4	2B04	C7H13O4PS	Phosphonothioic acid, methyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-ethyl methylphosphonothioate Butyric acid, 4-hydroxy-2-mercapt

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4637-82-5	2B04	C6H11O3PS2	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-methyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-m
CWCEC	4637-93-8	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-butyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-5-methyl-, S-ester with O-butyl methylphosphonodithioate Valeric aci
CWCEC	4637-97-2	2B04	C7H13O3PS2	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-5-methyl-, S-ester with O-methyl methylphosphonodithioate Valeric a
CWCEC	4637-98-3	2B04	C8H15O3PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-5-methyl-, S-ester with O-ethyl methylphosphonodithioate Valeric aci
CWCEC	4637-99-4	2B04	C8H15O2PS3	Phosphonotrithioic acid, methyl-, ethyl tetrahydro-5-methyl-2-oxo-3-furyl ester Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, ethyl methylphosphonotrithioate
CWCEC	4638-00-0	2B04	C9H17O4PS	Phosphonothioic acid, methyl-, O-propyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-propylmethylphosphonothioate
CWCEC	4638-01-1	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-propylmethylphosphonodithioate
CWCEC	4638-02-2	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-isopropyl ester, S-ester with dihydro-3-mercapto-5-methyl-2(3H)-furanone Valeric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isopropylmethylphosphonodithio
CWCEC	4638-52-2	2B04	C8H15O3PS2	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-methylmethylphosphonodithioate
CWCEC	4638-53-3	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-propylmethylphosphonodithioate
CWCEC	4638-54-4	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-isopropyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-isopropylmethylphosphonodithioa

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4638-55-5	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-butyl S-(5-ethyltetrahydro- .alpha.-oxo 3-furanyl) ester JF 2080 Phosphonodithioic acid, methyl-, O-butyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hex
CWCEC	4638-56-6	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-isobutyl ester, S-ester with 5-ethyld hydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-isobutylmethylphosphonodithioate
CWCEC	4638-57-7	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-pentyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-pentylmethylphosphonodithioate
CWCEC	4638-58-8	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-(1-methylbutyl) ester, S-ester 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-1-methylbutylmethylphosphonodi
CWCEC	4638-59-9	2B04	C12H21O3PS2	Phosphonodithioic acid, methyl-, O-cyclopentyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-cyclopentylmethylphosphonodit
CWCEC	4638-60-2	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-neopentyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone 1-Propanol, 2,2-dimethyl-, O-ester with methylphosphonodithioic acid S-ester with 4-hydroxy-2-merca
CWCEC	4638-61-3	2B04	C13H25O3PS2	Phosphonodithioic acid, methyl-, O-hexyl ester, S-ester with 5-ethyldihydro 3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-hexylmethylphosphonodithioate
CWCEC	4638-62-4	2B04	C10H19O3PS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-ethylethylphosphonodithioate
CWCEC	4638-63-5	2B04	C11H21O3PS2	Phosphonodithioic acid, ethyl-, O-isopropyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-isopropylethylphosphondithioate
CWCEC	4638-64-6	2B04	C12H23O3PS2	Phosphonodithioic acid, ethyl-, O-butyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-butylethylphosphonodithioate
CWCEC	4638-65-7	2B04	C12H23O3PS2	Phosphonodithioic acid, ethyl-, O-isobutyl ester, S-ester with 5-ethyldihydro-3-mercapto-2(3H)-furanone Hexanoic acid, 4-hydroxy-2-mercapto-, .gamma. lactone, S-ester with O-isobutylethylphosphonodithioate
CWCEC	4645-94-7	2B04	C9H14NO2P	Phosphonamidic acid, trimethyl-, phenyl ester
CWCEC	4645-95-8	2B04	C11H18NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, phenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	4645-96-9	2B04	C15H26NO2P	Phosphonamidic acid, N,N-dibutyl-P-methyl-, phenyl ester
CWCEC	4645-98-1	2B04	C10H16NO2P	Phosphonamidic acid, trimethyl-, o-tolyl ester
CWCEC	4653-49-0	2B04	C3H9ClNOP	Phosphonamidic chloride, trimethyl-
PTS-HB	4672-38-2	2B04	C3H9O3P	Phosphonic acid, propyl-
CWCEC	4675-22-3	2B04	C9H13O5PS	Phosphonic acid, methyl-, methyl (4-methylsulfonyl)phenyl ester Phenol, p-(methylsulfonyl)-, methyl methylphosphonate
PTS-HB	4708-04-7	2B04	C3H7Cl2OP	Phosphonic dichloride, propyl-
CWCEC	4741-04-2	2B04	C7H17OPS3	Phosphonodithioic acid, methyl-, O-ethyl S-[2-(ethylthio)ethyl] ester Ethanethiol, 2-(ethylthio)-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	4789-37-1	2B04	C4H10ClOPS	Phosphonochloridothioic acid, ethyl-, O-ethyl ester, (R)- (-)-Ethyl ethylphosphonochloridothioate
CWCEC	4789-38-2	2B04	C8H20O4P2S	Phosphonic acid, ethyl-, ethyl ester, anhydride with O-ethyl ethylphosphonothioate, (+)- Phosphonothioic acid, ethyl-, O-ethyl ester, anhydride with ethyl ethylphosphonate, (+)-
CWCEC	4796-90-1	2B04	C5H11F3NO3P	Phosphonamidic acid, N-hydroxy-P-methyl-N-(trifluoromethyl)-, isopropyl ester
CWCEC	4844-37-5	2B04	C14H31O3P	Phosphonic acid, methyl-, dodecyl methyl ester
CWCEC	4851-65-4	2B04	C7H15O3P	Phosphonic acid, methyl-, butyl ethenyl ester Phosphonic acid, methyl-, butyl vinyl ester
CWCEC	4851-66-5	2B04	C7H15O3P	Phosphonic acid, methyl-, isobutyl vinyl ester
CWCEC	4885-75-0	2B04	C11H14NO2PS2	Phosphonothioic acid, ethyl-, O-2-benzothiazolyl O-ethyl ester
CWCEC	4885-76-1	2B04	C10H12NO2PS2	Phosphonothioic acid, methyl-, O-2-benzothiazolyl O-ethyl ester
CWCEC	4932-33-6	2B04	C12H16NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with mercapto(phenylthio)acetonitrile
CWCEC	4938-90-3	2B04	C10H14NO5P	Phosphonic acid, ethyl-, ethyl m-nitrophenyl ester
CWCEC	4950-88-3	2B04	C9H12NO5P	Phosphonic acid, methyl-, methyl (4-nitrophenyl)methyl ester Phosphonic acid, methyl-, methyl p-nitrobenzyl ester Benzyl alcohol, p-nitro-, methyl methylphosphonate
CWCEC	5010-07-1	2B04	C12H15ClNOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with [(p-chlorophenyl)thio]mercaptoacetonitrile
CWCEC	5152-73-8	2B04	C5H13O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-methyl ester, (S)- Phosphonothioic acid, ethyl-, O-ethyl O-methyl ester, (+)- Phosphonothioic acid, ethyl-, O-ethyl O-methyl ester, (S)-(+)-
CWCEC	5166-29-0	2B04	C9H15N2O2PS2	Phosphonothioic acid, methyl-, O-[4-(ethylthio)-6-methyl-2-pyrimidinyl] O-methyl ester 2-Pyrimidinol, 4-(ethylthio)-6-methyl-, O-ester with O-methyl methylphosphonothioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5191-50-4	2B04	C6H11Cl2O3P	Phosphonic acid, ethyl-, 2,2-dichloroethenyl ethyl ester Phosphonic acid, ethyl-, 2,2-dichlorovinyl ethyl ester
CWCEC	5263-13-8	2B04	C14H22NO2PS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[1-methyl-2-oxo-2-[[(phenylthio)methyl]amino]ethyl] ester Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 2-mercapto-N-[(phenylthio)methyl]propionamide
CWCEC	5284-04-8	2B04	C10H24O6P2	Phosphonic acid, methyl-, ethyl ester, diester with 1,4-butanediol
CWCEC	5284-05-9	2B04	C12H28O6P2	Phosphonic acid, ethyl-, ethyl ester, diester with 1,4-butanediol
CWCEC	5284-09-3	2B04	C3H8ClO2P	Phosphonochloridic acid, methyl-, ethyl ester Ethyl methylphosphonochloridate Ethyl methanephosphonochloridate Chloroethoxymethylphosphine oxide O-Ethyl chloromethylphosphonate
CWCEC	5284-10-6	2B04	C4H10ClO2P	Phosphonochloridic acid, ethyl-, ethyl ester Ethyl ethylphosphonochloridate
CWCEC	5290-52-8	2B04	C16H20O6P2	Phosphonic acid, methyl-, ethylene diphenyl ester Phosphonic acid, methyl-, phenyl ester, diester with ethylene glycol Ethylene glycol, bis(phenyl methylphosphonate)
PTS-HB	5301-65-5	2B04	C5H13O3P	Phosphonic acid, ethyl-, ethyl methyl ester
CWCEC	5307-81-3	2B04	C6H14NO3PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-(hydroxymethyl)-2-mercaptoacetamide Acetamide, N-(hydroxymethyl)-2-mercapto-, S-ester with O-ethyl methylphosphondithioate Acetamide, N-(hydroxy
CWCEC	5307-82-4	2B04	C13H20NO2PS3	Phosphonodithioic acid, methyl-, O-ethyl S-[1-methyl-2-oxo-2-[[(phenylthio)methyl]amino]ethyl] ester Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercapto-N-[(phenylthio)methyl]propionamid
CWCEC	5307-88-0	2B04	C7H14NOPS3	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with 3-(ethylthio)-3-mercaptopropionitrile
CWCEC	5307-89-1	2B04	C9H18NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 3-(ethylthio)-3-mercaptopropionitrile
CWCEC	5307-92-6	2B04	C13H18NOPS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 3-mercapto-3-(phenylthio)propionitrile
CWCEC	5355-56-6	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-butyl ester, S-ester with 3-mercapto-2 oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-butyl methylphosphonodithioate Hexanoic acid, 6-hydroxy-2-mercapto-, .epsilon.
CWCEC	5357-47-1	2B04	C8H15O3PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-propyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-m
CWCEC	5357-48-2	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-butyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-butyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-mer

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5357-49-3	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-sec-butyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-sec-butyl methylphosphonodithioate Butyric acid, 4-hydro
CWCEC	5357-50-6	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-isopentyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-isopentyl methylphosphonodithioate Butyric acid, 4-hydro
CWCEC	5357-51-7	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-(1-methylbutyl) ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O (1-methylbutyl) methylphosphonodithioate Butyric a
CWCEC	5357-52-8	2B04	C7H13O2PS3	Phosphonotrithioic acid, methyl-, ethyl ester, ester with dihydro-3-mercapto 2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, ester with ethyl methylphosphonotrithioate Butyric acid, 4-hydroxy-2-mercapto-
CWCEC	5357-53-9	2B04	C7H13O3PS2	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-methyl ethylphosphonodithioate Butyric acid, 4-hydroxy-2-mer
CWCEC	5357-54-0	2B04	C8H15O3PS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-ethyl ethylphosphonodithioate General Chemical 9879 Butyric a
CWCEC	5357-55-1	2B04	C9H17O3PS2	Phosphonodithioic acid, ethyl-, O-isopropyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-isopropyl ethylphosphonodithioate Butyric acid, 4-hydroxy
CWCEC	5357-56-2	2B04	C10H19O3PS2	Phosphonodithioic acid, ethyl-, O-butyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-butyl ethylphosphonodithioate Butyric acid, 4-hydroxy-2-merca
CWCEC	5357-59-5	2B04	C7H13O3PS2	Phosphonodithioic acid, methyl-, O-methyl S-(tetrahydro-2-oxo-2H-pyran-3-yl) ester Valeric acid, 5-hydroxy-2-mercapto-, .delta.-lactone, S-ester with O-methylmethylphosphonodithioate
CWCEC	5357-60-8	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with tetrahydro-3-mercapto-2H-pyran-2-one 2H-Pyran-2-one, tetrahydro-3-mercapto-, S-ester with O-propyl methylphosphonodithioate Valeric acid, 5-hydro
CWCEC	5381-55-5	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-isobutyl ester, S-ester with tetrahydro-3-mercapto-2H-pyran-2-one 2H-Pyran-2-one, tetrahydro-3-mercapto-, S-ester with O-isobutyl methylphosphonodithioate Valeric acid, 5-h

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5381-56-6	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-sec-butyl ester, S-ester with tetrahydro 3-mercapto-2H-pyran-2-one 2H-Pyran-2-one, tetrahydro-3-mercapto, S-ester with O-sec-butyl methylphosphonodithioate Valeric acid, 5-
CWCEC	5381-57-7	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-isobutyl ester, S-ester with 3-mercapto-2-oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-isobutyl methylphosphonodithioate Hexanoic acid, 6-hydroxy-2-mercapto-, .epsilo
CWCEC	5381-58-8	2B04	C12H23O3PS2	Phosphonodithioic acid, methyl-, O-isopentyl ester, S-ester with 3-mercapto-2-oxepanone Hexanoic acid, 6-hydroxy-2-mercapto-, .epsilon.-lactone, S-ester with O-isopentylmethylphosphonodithioate
CWCEC	5381-59-9	2B04	C13H25O3PS2	Phosphonodithioic acid, methyl-, O-isohexyl ester, S-ester with 3-mercapto 2-oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-isohexyl methylphosphonodithioate
CWCEC	5507-60-8	2B04	C8H15O3PS2	Phosphonodithioic acid, methyl-, O-isopropyl ester S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-isopropyl methylphosphonodithioate Butyric acid, 4-hydrox
CWCEC	5507-61-9	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-pentyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-pentyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-m
CWCEC	5507-62-0	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-neopentyl ester, S-ester with dihydro-3 mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-neopentyl methylphosphonodithioate Butyric acid, 4-hydro
CWCEC	5507-63-1	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-hexyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-hexyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-mer
CWCEC	5530-78-9	2B04	C13H18NOPS3	Phosphonodithioic acid, ethyl-, S-[cyano[(4- methylphenyl)thio]methyl] O-ethyl ester Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with mercapto(p-tolylthio)acetonitrile
CWCEC	5543-41-9	2B04	C9H15N2OPS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[(2- pyrimidinylthio)methyl] ester
CWCEC	5543-43-1	2B04	C10H17N2OPS3	Phosphonodithioic acid, ethyl-, O-ethyl S-[[(4-methyl-2-pyrimidinyl)thio]methyl] ester
CWCEC	5557-35-7	2B04	C9H17O3PS2	Phosphonodithioic acid, methyl-, O-isobutyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, O-isobutyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-mercapto-,

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5557-36-8	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-(1-ethylpropyl) ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O (1-ethylpropyl) methylphosphonodithioate 3-Pentano
CWCEC	5559-39-7	2B04	C5H13O3P	Phosphonic acid, ethyl-, ethyl methyl ester, (.+-.)-
CWCEC	5559-40-0	2B04	C8H20O3P2S	Phosphonothioic acid, ethyl-, anhydride with diethyl phosphinic acid, O-ethyl ester, (+)- Phosphinic acid, diethyl-, anhydride with O-ethyl ethylphosphonothioate, (+)-
CWCEC	5559-42-2	2B04	C6H16NO2P	Phosphonamidic acid, P-ethyl-N,N-dimethyl-, ethyl ester, (+)- (+)-Ethyl P-ethyl-N,N-dimethylphosphonamidate
CWCEC	5565-79-7	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with 3-mercapto-2 oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-propyl methylphosphonodithioate Hexanoic acid, 6-hydroxy-2-mercapto-, .epsilon.-l
CWCEC	5565-80-0	2B04	C10H19O3PS2	Phosphonodithioic acid, methyl-, O-isopropyl ester, S-ester with 3-mercapto-2-oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-isopropyl methylphosphonodithioate Hexanoic acid, 6-hydroxy-2-mercapto-, .epsi
CWCEC	5565-81-1	2B04	C12H21O3PS2	Phosphonodithioic acid, methyl-, O-cyclopentyl ester, S-ester with 3-mercapto-2-oxepanone 2-Oxepanone, 3-mercapto-, S-ester with O-cyclopentyl methylphosphonodithioate Hexanoic acid, 6-hydroxy-2-mercapto-, .
CWCEC	5578-48-3	2B04	C14H31NO3P2S4	Phosphonodithioic acid, ethyl-, O-ethyl ester, S,S-diester with N,N-diethyl-2,2-dimercaptoacetamide Acetamide, N,N-diethyl-2,2-dimercapto-, S,S-diester with O-ethyl ethylphosphonodithioate
CWCEC	5578-58-5	2B04	C12H16NO3PS2	Phosphonothioic acid, ethyl-, O-ethyl O-(3,4-dihydro-3-oxo-2H,1,4-benzothiazin-7-yl) ester Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with 7-hydroxy-2H-1,4-benzothiazin-3-(4H)-one
CWCEC	5578-61-0	2B04	C11H14NO3PS2	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 7-hydroxy-2H-1,4 benzothiazin-3(4H)-one
CWCEC	5585-03-5	2B04	C10H17O3PS2	Phosphonodithioic acid, methyl-, O-cyclopentyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-cyclopentyl methylphosphonodithioate Butyric acid, 4-h
CWCEC	5585-04-6	2B04	C11H19O3PS2	Phosphonodithioic acid, methyl-, O-cyclohexyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-cyclohexyl methylphosphonodithioate Butyric acid, 4-hyd
CWCEC	5585-05-7	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-4-methylpentyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone Butyric acid, 4-hydroxy-2-mercapto-, .gamma.-lactone, S-ester with O-isohexylmethylphosphonodithioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5585-06-8	2B04	C15H29O3PS2	Phosphonodithioic acid, methyl-, O-decyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-decyl methylphosphonodithioate Butyric acid, 4-hydroxy-2-mer
CWCEC	5585-07-9	2B04	C8H15O2PS3	Phosphonotrithioic acid, methyl-, isopropyl ester, ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, ester with isopropyl methylphosphonotrithioate Butyric acid, 4-hydroxy-2
CWCEC	5585-08-0	2B04	C9H17O2PS3	Phosphonotrithioic acid, methyl-, butyl ester, ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, ester with butyl methylphosphonotrithioate Butyric acid, 4-hydroxy-2-mercapt
CWCEC	5585-09-1	2B04	C9H17O2PS3	Phosphonotrithioic acid, ethyl-, isopropyl ester, ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, ester with isopropyl ethylphosphonotrithioate Butyric acid, 4-hydroxy-2-m
CWCEC	5585-10-4	2B04	C9H17O3PS2	Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with dihydro-3-mercapto-2(3H)-furanone 2(3H)-Furanone, dihydro-3-mercapto-, S-ester with O-ethyl isopropylphosphonodithioate Butyric acid, 4-hydroxy
CWCEC	5585-11-5	2B04	C8H15O3PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with tetrahydro-3-mercapto-2H-pyran-2-one Valeric acid, 5-hydroxy-2-mercapto-, .delta.-lactone, S-ester with O-ethylmethylphosphonodithioate
CWCEC	5587-35-9	2B04	C14H20N3O3PS2	Phosphorothioic acid, O,O-diethyl S-[2-[[(4-oxo-1,2,3-benzotriazin-3(4H)-yl)methyl]thio]ethyl] ester 1,2,3-Benzotriazine, phosphorothioic acid deriv.
CWCEC	5587-36-0	2B04	C14H20N3O2PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with 3-[[(2-mercaptoethyl)thio]methyl]-1,2,3-benzotriazin-4(3H)-one
CWCEC	5613-56-9	2B04	C12H28O3P2S4	Phosphonodithioic acid, ethyl-, O-ethyl ester, S,S-diester with 2,2'-oxydiethanethiol Ethanethiol, 2,2'-oxydi-, S,S-diester with O-ethyl ethylphosphorodithioate
CWCEC	5613-57-0	2B04	C10H24O3P2S4	Phosphonodithioic acid, ethyl-, O-ethyl ester, S,S-diester with oxydimethanethiol
CWCEC	5613-58-1	2B04	C8H20O5P2S2	Phosphonothioic acid, ethyl-, O-methyl ester, S,S-diester with oxydimethanethiol
CWCEC	5629-52-7	2B04	C11H21O3PS2	Phosphonodithioic acid, methyl-, O-(1-methylpropyl) S-(2-oxo-3-oxepanyl) ester Oxepane, phosphonodithioic acid deriv. Hexanoic acid, 6-hydroxy-2-mercapto-, .epsilon.-lactone, S-ester with O-sec-butylmethylphosphonodi
CWCEC	5802-95-9	2B04	C7H16NO2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercapto-N-methylpropionamide

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5802-96-0	2B04	C8H18NO2PS2	Phosphonodithioic acid, methyl-, O-propyl ester, S-ester with 2-mercapto-N-methylpropionamide
CWCEC	5802-98-2	2B04	C9H20NO2PS2	Phosphonodithioic acid, isopropyl-, O-ethyl ester, S-ester with 2-mercapto-N-methylpropionamide
CWCEC	5802-99-3	2B04	C8H18NO2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 3-mercapto-N-methylbutyramide Butyramide, 2-mercapto-N-methyl-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	5803-00-9	2B04	C8H18NO2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 2-mercapto-N,N-dimethylpropionamide Propionamide, 2-mercapto-N,N-dimethyl-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	5803-01-0	2B04	C10H22NO2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N,N-diethyl-2-mercaptopropionamide Propionamide, N,N-diethyl-2-mercapto-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	5803-02-1	2B04	C11H22NO2PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 1-(2-mercaptopropionyl)piperidine Piperidine, 1-(2-mercaptopropionyl)-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	5803-03-2	2B04	C10H20NO3PS2	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with 4-(2-mercaptopropionyl)morpholine Morpholine, 4-(2-mercaptopropionyl)-, S-ester with O-ethyl methylphosphonodithioate
CWCEC	5827-24-7	2B04	CH3Br2PS	Phosphonothioic dibromide, methyl- Methylphosphonothioic dibromide Methylphosphonothionodibromidic acid Dibromomethylphosphine sulfide Methyl phosphorodibromidothioite
CWCEC	5828-67-1	2B04	C11H25O3P	Phosphonic acid, methyl-, bis(1-ethylpropyl) ester
PTS-HB	5842-06-8	2B12	C8H19NS	Ethanethiol, 2-(dipropylamino)-
PTS-HB	5842-07-9	2B12	C8H19NS	Ethanethiol, 2-[bis(1-methylethyl)amino]-
CWCEC	5849-76-3	2B04	C7H15O5P	Lactic acid, ethyl ester, methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, ester with ethyl lactate
CWCEC	5849-81-0	2B04	C9H11Cl2O3P	Phosphonic acid, methyl-, 2,4-dichlorobenzyl methyl ester Benzyl alcohol, 2,4-dichloro-, monomethyl
PTS-HB	5853-68-9	2B04	C9H11O3P	4H-1,3,2-Benzodioxaphosphorin, 2-ethyl-, 2-oxide
CWCEC	5856-45-1	2B04	C7H17O2PS2.C2H6O4S	Phosphonothioic acid, methyl-, O-ethyl S-[2-(ethylthio)ethyl] ester, compd. with dimethyl sulfate (1:1) Methyl sulfate (Me2SO4), compd. with O-ethyl S-[2-(ethylthio) ethyl]methylphosphonothicate (1:1)
PTS-HB	5902-78-3	2B04	C9H13O4PS2	Phosphonothioic acid, methyl-, O-methyl O-[4-(methylsulfonyl)phenyl] ester
CWCEC	5903-11-7	2B04	C9H13O2PS	Phosphonothioic acid, methyl-, O-methyl O-p-tolyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5937-92-8	2B04	C14H11ClNO2PS	Phosphonothioic acid, methyl-, O-phenyl ester, O-ester with 2-chloro-4-hydroxybenzonitrile
CWCEC	5952-50-1	2B04	C11H17O3PS	Phosphonothioic acid, methyl-, O-ethyl S-(2-phenoxyethyl) ester Ethanethiol, 2-phenoxy-, S-ester with O-ethyl methylphosphonothioate O-Ethyl S-(.beta.-phenoxyethyl) methylthiophosphonate
CWCEC	5952-51-2	2B04	C12H19O3PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-(3-methylphenoxy)ethyl] ester Phosphonothioic acid, methyl-, O-ethyl S-[2-(m-tolyloxy)ethyl] ester Ethanethiol, 2-(m-tolyloxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-52-3	2B04	C12H19O3PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-(4-methylphenoxy)ethyl] ester Phosphonothioic acid, methyl-, O-ethyl S-[2-(p-tolyloxy)ethyl] ester Ethanethiol, 2-(p-tolyloxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-53-4	2B04	C12H19O4PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-(3-methoxyphenoxy)ethyl] ester Phosphonothioic acid, methyl-, O-ethyl S-[2-(m-methoxyphenoxy)ethyl] ester Ethanethiol, 2-(m-methoxyphenoxy)-, S-ester with O-ethyl methylphosphonothioate Eth
CWCEC	5952-54-5	2B04	C12H19O4PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-(4-methoxyphenoxy)ethyl] ester Phosphonothioic acid, methyl-, O-ethyl S-[2-(p-methoxyphenoxy)ethyl] ester Ethanethiol, 2-(p-methoxyphenoxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-55-6	2B04	C11H16ClO3PS	Phosphonothioic acid, methyl-, S-[2-(3-chlorophenoxy)ethyl] O-ethyl ester Phosphonothioic acid, methyl-, S-[2-(m-chlorophenoxy)ethyl] O-ethyl ester Ethanethiol, 2-(m-chlorophenoxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-56-7	2B04	C11H16ClO3PS	Phosphonothioic acid, methyl-, S-[2-(4-chlorophenoxy)ethyl] O-ethyl ester Phosphonothioic acid, methyl-, S-[2-(p-chlorophenoxy)ethyl] O-ethyl ester Ethanethiol, 2-(p-chlorophenoxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-57-8	2B04	C11H16BrO3PS	Phosphonothioic acid, methyl-, S-[2-(4-bromophenoxy)ethyl] O-ethyl ester Phosphonothioic acid, methyl-, S-[2-(p-bromophenoxy)ethyl] O-ethyl ester Ethanethiol, 2-(p-bromophenoxy)-, S-ester with O-ethyl methylphosphonothioate
CWCEC	5952-58-9	2B04	C15H25O3PS	Phosphonothioic acid, methyl-, S-[2-[4-(1,1-dimethylethyl)phenoxy]ethyl] O-ethyl ester Phosphonothioic acid, methyl-, S-[2-(p-tert-butylphenoxy)ethyl] O-ethyl ester Ethanethiol, 2-(p-tert-butylphenoxy)-, S-ester with O-ethyl
PTS-HB	5954-90-5	2B04	C14H12NO2PS	Phosphonothioic acid, methyl-, O-(4-cyanophenyl) O-phenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	5954-91-6	2B04	C10H11ClNO2PS	Phosphonothioic acid, methyl-, O-(2-chloroethyl) ester, O-ester with p-hydroxybenzonitrile Benzonitrile, p-hydroxy-, O-ester with O-(2-chloroethyl) methylphosphonothioate Ethanol, 2-chloro-, hydrogen methylphosp
CWCEC	5954-92-7	2B04	C11H13ClNO2PS	Phosphonothioic acid, methyl-, O-(3-chloro-4-cyanophenyl) O-propyl ester Phosphonothioic acid, methyl-, O-propyl ester, O-ester with 2-chloro-4-hydroxybenzonitrile Benzonitrile, 2-chloro-4-hydroxy-, O-ester with O-propyl
CWCEC	5955-35-1	2B04	C11H18NO5P	Crotonic acid, 2-cyano-3-hydroxy-, ethyl ester, ethyl ethylphosphonate Phosphonic acid, ethyl-, ethyl ester, ester with ethyl 2-cyano-3-hydroxycrotonate
PTS-HB	5994-73-0	2B04	CH5O2PS	Phosphonothioic acid, methyl-
CWCEC	6069-07-4	2B04	C9H21O5P	Phosphonic acid, methyl-, bis(2-ethoxyethyl) ester
CWCEC	6069-09-6	2B04	C7H17O5P	Phosphonic acid, methyl-, bis(2-methoxyethyl) ester
CWCEC	6069-12-1	2B04	C9H21O4P	Phosphonic acid, methyl-, 2-methoxyethyl pentyl ester
CWCEC	6129-86-8	2B04	C10H23O4P	Phosphonic acid, methyl-, 2-ethoxyethyl pentyl ester
CWCEC	6138-32-5	1A06	C6H12Cl3N.C6H3N3O7	Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-, compd. with 2,4,6-trinitrophenol (1:1) Triethylamine, 2,2',2''-trichloro-, monopicrate 2,2',2''-Trichlorotriethylamine picrate Triethylamine, 2,2',2''-trichloro-, picrate
CWCEC	6151-92-4	2B04	C14H31O3P	Phosphonic acid, ethyl-, dihexyl ester
CWCEC	6154-51-4	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, 1,2-dimethylpropyl ester 2-Butanol, 3-methyl-, methylphosphonofluoridate 1,2-Dimethylpropyl methylphosphonofluoridate
CWCEC	6156-13-4	2B04	C18H39O3P	Phosphonic acid, ethyl-, dioctyl ester
CWCEC	6163-75-3	2B04	C4H11O3P	Dimethyl ethanephosphonate Dimethyl ethylphosphonate Ethylphosphonic acid dimethyl ester Phosphonic acid, ethyl-, dimethyl ester
CWCEC	6163-76-4	2B04	C8H19O3P	Phosphonic acid, ethyl-, dipropyl ester Dipropyl ethylphosphonate
CWCEC	6163-81-1	2B04	C16H35O3P	Phosphonic acid, ethyl-, diheptyl ester Diheptyl ethylphosphonate
CWCEC	6163-82-2	2B04	C12H27O3P	Phosphonic acid, ethyl-, dipentyl ester
CWCEC	6171-69-3	2B04	C11H17ClNO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, m-chlorophenyl ester
CWCEC	6171-93-3	1A01	C4H10FO2P	Phosphonofluoridic acid, methyl-, 1-methylethyl ester, (S)- Phosphonofluoridic acid, methyl-, isopropyl ester, (S)-(+)- S-GB (+)-Sarin
CWCEC	6171-94-4	1A01	C4H10FO2P	Phosphonofluoridic acid, methyl-, 1-methylethyl ester, (R)- Phosphonofluoridic acid, methyl-, isopropyl ester, (R)-(-)- (-)-Sarin R-GB
CWCEC	6173-08-6	2B04	C9H13ClNO2P	Phosphonamidic acid, trimethyl-, p-chlorophenyl ester
CWCEC	6173-19-9	2B04	C11H14BrCl2O2PS	Phosphonothioic acid, ethyl-, O-(4-bromo-2,5-dichlorophenyl) O-isopropyl ester
PTS-HB	6173-20-2	2B04	C10H12BrCl2O2PS	Phosphonothioic acid, methyl-, O-(4-bromo-2,5-dichlorophenyl) O-propyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	6180-98-9	2B04	C3H9AsFO2P	Phosphonofluoridic acid, methyl-, anhydride with dimethylarsinous acid Phosphonofluoridic acid, methyl-, O-dimethylarsino deriv.
PTS-HB	6203-26-5	2B04	C15H14NO6P	Phosphonic acid, methyl-, 4-nitrophenyl 2-oxo-2-phenylethyl ester
CWCEC	6395-55-7	2B04	C11H13Cl5NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, pentachlorophenyl ester Phenol, pentachloro-, N,N-diethyl-P-methylphosphonamidate
CWCEC	6395-56-8	2B04	C11H17ClNOPS	Phosphonamidothioic acid, N,N-diethyl-P-methyl-, S-(p-chlorophenyl) ester
CWCEC	6395-57-9	2B04	C13H11N2O7P	Phosphonic acid, methyl-, bis(4-nitrophenyl) ester Phosphonic acid, methyl-, bis(p-nitrophenyl) ester Bis(p-nitrophenyl) methylphosphonate
CWCEC	6395-59-1	2B04	C13H11Cl2O3P	Phosphonic acid, methyl-, bis(4-chlorophenyl) ester Phosphonic acid, methyl-, bis(p-chlorophenyl) ester
CWCEC	6395-61-5	2B04	C9H11Cl3NO2P	Phosphonamidic acid, trimethyl-, 2,4,5-trichlorophenyl ester Phenol, 2,4,5-trichloro-, trimethylphosphonamidate
CWCEC	6395-62-6	2B04	C9H9Cl5NO2P	Phosphonamidic acid, trimethyl-, pentachlorophenyl ester Phenol, pentachloro-, trimethylphosphonamidate
CWCEC	6395-63-7	2B04	C11H16Cl2NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, 2,4-dichlorophenyl ester Phenol, 2,4-dichloro-, N,N-diethyl-p-methylphosphonamidate
CWCEC	6395-64-8	2B04	C11H15Cl3NO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, 2,4,5-trichlorophenyl ester Phenol, 2,4,5-trichloro-, N,N-diethyl-P-methylphosphonamidate
CWCEC	6395-65-9	2B04	C11H17N2O4P	Phosphonamidic acid, N,N-diethyl-P-methyl-, 4-nitrophenyl ester Phosphonamidic acid, N,N-diethyl-P-methyl-, p-nitrophenyl ester
CWCEC	6410-56-6	2B04	C7H17O3P	Phosphonic acid, methyl-, dipropyl ester Dipropyl methylphosphonate
CWCEC	6412-70-0	2B04	C10H12NO2PS	Phosphonothioic acid, methyl-, O-(4-cyanophenyl) O-ethyl ester Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with p-hydroxybenzonitrile Stauffer B 10341 B 10341
CWCEC	6412-71-1	2B04	C10H14NO4PS	Phosphonothioic acid, ethyl-, O-ethyl O-(4-nitrophenyl) ester Phosphonothioic acid, ethyl-, O-ethyl O-(p-nitrophenyl) ester Phosphonothioic acid, ethyl-, ethyl p-nitrophenyl ester
CWCEC	6432-85-5	2B04	C7H7Cl2O2P	Phosphonochloridic acid, methyl-, 3-chlorophenyl ester Phosphonochloridic acid, methyl-, m-chlorophenyl ester
CWCEC	6432-86-6	2B04	C11H17ClNO2P	Phosphonamidic acid, N,N-diethyl-P-methyl-, p-chlorophenyl ester
CWCEC	6432-89-9	2B04	C11H14BrCl2O2PS	Phosphonothioic acid, methyl-, O-(4-bromo-2,5-dichlorophenyl) O-butyl ester
CWCEC	6481-15-8	2B04	C15H33O7P	Phosphonic acid, isopropyl-, diester with 2-ethyl-2-(hydroxymethyl)- 1,3-propanediol
CWCEC	6492-18-8	2B04	C10H12Cl3O3P	Phosphonic acid, ethyl-, ethyl 2,4,5-trichlorophenyl ester Phenol, 2,4,5-trichloro-, ethyl ethylphosphonate Trichloronatoxon Trichloronate oxon

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	6552-16-5	2B04	C10H15O3PS	Phosphonic acid, methyl-, methyl 4-(methylthio)-m-tolyl ester
CWCEC	6552-17-6	2B04	C10H15O4PS	Phosphonic acid, methyl-, methyl 4-(methylsulfinyl)-m-tolyl ester
CWCEC	6552-18-7	2B04	C10H15O2PS2	Phosphonothioic acid, methyl-, O-methyl O-[3-methyl-4- (methylthio)phenyl] ester Phosphonothioic acid, methyl-, O-methyl O-[4-(methylthio)-m-tolyl] ester
PTS-HB	6552-19-8	2B04	C10H15O3PS2	Phosphonothioic acid, methyl-, O-methyl O-[3-methyl-4-(methylsulfinyl)phenyl] ester
PTS-HB	6581-06-2	2A03	C21H23NO3	Benzeneacetic acid, .alpha.-hydroxy-.alpha.-phenyl-, 1-azabicyclo[2.2.2]oct-3-yl ester
PTS-HB	6587-45-7	2B04	C11H17O3PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-(methylsulfinyl)phenyl] ester
CWCEC	6587-94-6	2B04	C8H19PS3	Phosphonotrithioic acid, ethyl-, dipropyl ester
CWCEC	6588-38-1	2B04	C10H23PS3	Phosphonotrithioic acid, ethyl-, diisobutyl ester
CWCEC	6588-39-2	2B04	C10H23PS3	Phosphonotrithioic acid, ethyl-, dibutyl ester Preparation 1106
CWCEC	6588-40-5	2B04	C8H19PS3	Phosphonotrithioic acid, ethyl-, diisopropyl ester
CWCEC	6610-92-0	2B04	C11H17O3PS	Phosphonic acid, ethyl-, ethyl p-(methylthio)phenyl ester Chemagro S 9225
CWCEC	6610-93-1	2B04	C11H17O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[p-(methylthio)phenyl] ester
CWCEC	6610-94-2	2B04	C12H19O3PS	Phosphonic acid, ethyl-, ethyl 4-(methylthio)-m-tolyl ester
CWCEC	6610-95-3	2B04	C12H19O4PS	Phosphonic acid, ethyl-, ethyl 4-(methylsulfinyl)-m-tolyl ester
CWCEC	6610-96-4	2B04	C12H19O2PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-(methylthio)-m-tolyl] ester
CWCEC	6610-97-5	2B04	C12H19O3PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[4-(methylsulfinyl)-m-tolyl] ester
CWCEC	6615-80-1	2B04	C10H17O5P	Crotonic acid, 3-hydroxy-2-(2-hydroxyethyl)-, .gamma.-lactone, ethyl ethylphosphonate
CWCEC	6615-84-5	2B04	C9H15O5P	Crotonic acid, 3-hydroxy-2-(2-hydroxyethyl)-, .gamma.-lactone, methyl ethylphosphonate
CWCEC	6619-50-7	2B04	C7H7Cl2O2P	Phosphonochloridic acid, methyl-, 4-chlorophenyl ester p-Chlorophenyl methanephosphonochloridate Phosphonochloridic acid, methyl-, p-chlorophenyl ester
CWCEC	6650-78-8	2B04	C6H14Cl2NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, methyl ester
CWCEC	6650-81-3	2B04	C7H16Cl2NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, ethyl ester
CWCEC	6650-85-7	2B04	C12H18Cl2NOPS	Phosphonamidothioic acid, N,N-bis(2-chloroethyl)-P-methyl-, S-p-tolyl ester
CWCEC	6650-87-9	2B04	C11H16Cl2NOPS	Phosphonamidothioic acid, N,N-bis(2-chloroethyl)-P-methyl-, S-phenyl ester
CWCEC	6650-90-4	2B04	C11H15Cl2N2O4P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, p-nitrophenyl ester
CWCEC	6650-93-7	2B04	C8H14Cl4NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 3,3-dichloroallyl ester
CWCEC	6650-95-9	2B04	C8H16Cl2NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-; allyl ester
CWCEC	6650-97-1	2B04	C8H15Cl3NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 3-chloroallyl ester
CWCEC	6650-99-3	2B04	C7H13Cl5NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2,2,2-trichloroethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	6651-01-0	2B04	C8H17Cl3NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 3-chloropropyl ester
CWCEC	6651-03-2	2B04	C8H16Cl4NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2,3-dichloropropyl ester
CWCEC	6651-05-4	2B04	C8H17Cl3NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2-chloropropyl ester
CWCEC	6651-07-6	2B04	C8H18Cl2NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, propyl ester
CWCEC	6651-09-8	2B04	C8H14Cl2NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2-propynyl ester
CWCEC	6672-78-2	2B04	C11H17O4PS	Phosphonic acid, ethyl-, ethyl p-(methylsulfinyl)phenyl ester
CWCEC	6716-86-5	2B04	C11H15Cl3NOPS	Phosphonamidothioic acid, N,N-bis(2-chloroethyl)-P-methyl-, S-p-chlorophenyl ester
CWCEC	6748-29-4	2B04	C8H15Cl3NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2-chloroallyl ester
PTS-HB	6779-09-5	2B04	C2H7O3P	Phosphonic acid, ethyl-
CWCEC	6795-01-3	2B04	C6H15O4P	Phosphonoperoxoic acid, methyl-, OO-tert-butyl O-methyl ester
CWCEC	6795-02-4	2B04	C7H17O4P	Phosphonoperoxoic acid, ethyl-, OO-(1,1-dimethylethyl) O-methyl ester Phosphonoperoxoic acid, ethyl-, OO-tert-butyl O-methyl ester
CWCEC	6795-03-5	2B04	C8H19O4P	Phosphonoperoxoic acid, propyl-, OO-tert-butyl O-methyl ester
CWCEC	6795-04-6	2B04	C8H19O4P	Phosphonoperoxoic acid, isopropyl-, OO-tert-butyl O-methyl ester
CWCEC	6795-05-7	2B04	C9H21O5P	Phosphonodiperoxoic acid, methyl-, di-tert-butyl ester
CWCEC	6795-06-8	2B04	C11H25O5P	Phosphonodiperoxoic acid, propyl-, di-tert-butyl ester
CWCEC	6795-07-9	2B04	C11H25O5P	Phosphonodiperoxoic acid, isopropyl-, di-tert-butyl ester
CWCEC	6803-94-7	2B04	C7H15Cl3NO2P	Phosphonamidic acid, N,N-bis(2-chloroethyl)-P-methyl-, 2-chloroethyl ester
PTS-HB	6838-93-3	2B04	C4H11O3P.Na	Phosphonic acid, methyl-; mono(1-methylethyl) ester, sodium salt
CWCEC	6885-99-0	2B04	C10H23O5P	Phosphonodiperoxoic acid, ethyl-, bis(1,1-dimethylethyl) ester Phosphonodiperoxoic acid, ethyl-, di-tert-butyl ester
CWCEC	6996-81-2	2B04	C5H13O2PS	Phosphonothioic acid, methyl-, O,O-diethyl ester O,O-Diethyl methylphosphonothioate Diethy methylphosphonothionate
CWCEC	7010-00-6	2B04	C8H20O2P2S2Se	Phosphonoselenothioic acid, ethyl-, O-ethyl ester, anhydroselenide
CWCEC	7010-15-3	2B04	C5H14NO3P	Phosphonic acid, methyl-, 2-aminoethyl ethyl ester Ethanol, 2-amino-, ethyl methylphosphonate (ester)
CWCEC	7010-22-2	2B04	C4H10ClO2PS	Thiohypochlorous acid, anhydrosulfide with O-ethyl hydrogen ethylphosphonothioate Phosphinic acid, (chlorothio)ethyl-, ethyl ester Sulfenyl chloride, (ethoxyethylphosphinyl)-
CWCEC	7010-34-6	2B04	C6H15OPSSe	Phosphonoselenothioic acid, ethyl-, O,Se-diethyl ester
CWCEC	7010-35-7	2B04	C16H32NOPS	Phosphonamidothioic acid, N,N-dicyclohexyl-P-ethyl-, O-ethyl ester
CWCEC	7030-93-5	2B04	C11H13ClNO2PS2	Phosphonothioic acid, methyl-, O-(2-chloro-5-methyl-4-thiocyanatophenyl) O-ethyl ester
CWCEC	7040-52-0	2B04	C8H17O3P	Phosphonic acid, methyl-, cyclohexyl methyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	7040-53-1	2B04	C13H25O3P	Phosphonic acid, methyl-, dicyclohexyl ester
CWCEC	7040-55-3	2B04	C9H19O3P	Phosphonic acid, methyl-, cyclohexyl ethyl ester
CWCEC	7040-56-4	2B04	C9H21O3P	Phosphonic acid, methyl-, ethyl 1,2,2-trimethylpropyl ester Ethyl pinacolyl methylphosphonate
PTS-HB	7040-57-5	1B12	C7H16ClO2P	Phosphonochloridic acid, methyl-, 1,2,2-trimethylpropyl ester
CWCEC	7040-58-6	2B04	C13H29O3P	Phosphonic acid, methyl-, bis(1,2,2-trimethylpropyl) ester 2-Butanol, 3,3-dimethyl-, methylphosphonate (2:1) 1-Propanol, 1,2,2-trimethyl-, methylphosphonate (2:1) Dipinacolyl methylphosphonate
CWCEC	7040-59-7	2B04	C8H19O3P	Phosphonic acid, methyl-, methyl 1,2,2-trimethylpropyl ester 2-Butanol, 3,3-dimethyl-, methyl methylphosphonate
CWCEC	7040-92-8	2B04	C7H14ClO2P	Phosphonochloridic acid, methyl-, cyclohexyl ester Cyclohexyl methylphosphonochloridate
CWCEC	7061-50-9	2B04	C5H14NO3P.ClH	Phosphonic acid, methyl-, 2-aminoethyl ethyl ester, hydrochloride Ethanol, 2-amino-, ethyl methylphosphonate (ester), hydrochloride
CWCEC	7103-31-3	2B04	C14H20N3O3PS2	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with 3-[[(2-hydroxyethyl)thio]methyl]-1,2,3-benzotriazin-4(3H)-one 1,2,3-Benzotriazin-4(3H)-one, 3-[[(2-hydroxyethyl)thio]methyl]-, O-ester with O-ethyl ethylphosphonothioate
CWCEC	7205-20-1	2B04	C12H16NOPS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with .alpha.-mercapto-m-tolunitrile
CWCEC	7242-55-9	2B04	C10H23O3P	Phosphonic acid, ethyl-, bis(2-methylpropyl) ester Phosphonic acid, ethyl-, diisobutyl ester
CWCEC	7242-56-0	2B04	C9H21O3P	Phosphonic acid, methyl-, bis(2-methylpropyl) ester Phosphonic acid, methyl-, diisobutyl ester Diisobutyl methanephosphonate
PTS-HB	7260-35-7	2B04	C10H13Cl2O2PS	Phosphonothioic acid, ethyl-, O-(2,5-dichlorophenyl) O-ethyl ester
CWCEC	7284-49-3	2B04	C8H10NO5P	Phosphonic acid, methyl-, methyl 4-nitrophenyl ester Phosphonic acid, methyl-, methyl p-nitrophenyl ester O-Methyl-p-nitrophenyl methylphosphonate
CWCEC	7284-51-7	2B04	C10H14NO5P	Phosphonic acid, methyl-, 4-nitrophenyl propyl ester Phosphonic acid, methyl-, p-nitrophenyl propyl ester
CWCEC	7284-53-9	2B04	C11H16NO5P	Phosphonic acid, methyl-, butyl 4-nitrophenyl ester Phosphonic acid, methyl-, butyl p-nitrophenyl ester
CWCEC	7284-54-0	2B04	C11H16NO5P	Phosphonic acid, methyl-, sec-butyl p-nitrophenyl ester
CWCEC	7284-55-1	2B04	C12H18NO5P	Phosphonic acid, methyl-, 4-nitrophenyl pentyl ester Phosphonic acid, methyl-, p-nitrophenyl pentyl ester O-Pentyl-p-nitrophenyl methylphosphonate
CWCEC	7284-56-2	2B04	C13H18NO5P	Phosphonic acid, methyl-, cyclohexyl p-nitrophenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	7284-57-3	2B04	C13H20NO5P	Phosphonic acid, methyl-, 4-nitrophenyl 1,2,2-trimethylpropyl ester Phosphonic acid, methy -, p-nitrophenyl 1,2,2-trimethylpropyl ester 2-Butanol, 3,3-dimethyl-, p-nitrophenyl methy phosphonate
PTS-HB	7284-58-4	2B04	C11H16NO5P	Phosphonic acid, ethyl-, isopropyl p-nitrophenyl ester
CWCEC	7284-59-5	2B04	C12H18NO5P	Phosphonic acid, propyl-, isopropyl p-nitrophenyl ester
PTS-HB	7284-60-8	2B04	C12H18NO5P	Phosphonic acid, isopropyl-, isopropyl p-nitrophenyl ester
CWCEC	7284-82-4	1A01	C6H12FO2P	Phosphonofluoridic acid, methyl-, cyclopentyl ester Cyclopentanol, methylphosphonofluoridate
CWCEC	7284-83-5	1A01	C8H16FO2P	Phosphonofluoridic acid, methyl-, cycloheptyl ester Cycloheptanol, methylphosphonofluoridate
CWCEC	7284-84-6	1A01	C8H16FO2P	Phosphonofluoridic acid, ethyl-, cyclohexyl ester
PTS-HB	7305-61-5	2B04	C4H11O3P	Phosphonic acid, ethyl-, monoethyl ester
CWCEC	7307-29-1	2B04	C11H25O3P	Phosphonic acid, propyl-, diisobutyl ester
CWCEC	7317-56-8	2B04	C11H14Cl3O3P	Phosphonic acid, methyl-, phenyl 2,2,2-trichloro-1,1-dimethylethyl ester
CWCEC	7324-27-8	2B04	C8H10NO4PS	Phosphonothioic acid, methyl-, S-methyl O-(4-nitrophenyl) ester, (-)- Phosphonothioic acid, methyl-, S-methyl O-(p-nitrophenyl) ester, (-)- S-Methyl-p-nitrophenyl methylphosphonothiolate, (-)-
CWCEC	7324-28-9	2B04	C8H10NO4PS	Phosphonothioic acid, methyl-, S-methyl O-(4-nitrophenyl) ester, (+)- Phosphonothioic acid, methyl-, S-methyl O-(p-nitrophenyl) ester, (+)- S-Methyl-p-nitrophenyl methylphosphonothiolate, (+)-
CWCEC	7324-30-3	2B04	C9H12NO4PS	Phosphonothioic acid, methyl-, S-ethyl O-(4-nitrophenyl) ester, (+)- Phosphonothioic acid, methyl-, S-ethyl O-(p-nitrophenyl) ester, (+)- S-Ethyl-p-nitrophenyl methylphosphonothiolate, (+)-
CWCEC	7324-31-4	2B04	C9H12NO4PS	Phosphonothioic acid, methyl-, S-ethyl O-(4-nitrophenyl) ester, (-)- Phosphonothioic acid, methyl-, S-ethyl O-(p-nitrophenyl) ester, (-)- S-Ethyl-p-nitrophenyl methylphosphonothiolate, (-)-
CWCEC	7324-33-6	2B04	C10H14NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) S-propyl ester, (+)- Phosphonothioic acid, methyl-, O-(p-nitrophenyl) S-propyl ester, (+)- S-Propyl-p-nitrophenyl methylphosphonothiolate, (+)-
CWCEC	7324-34-7	2B04	C10H14NO4PS	Phosphonothioic acid, methyl-, O-(4-nitrophenyl) S-propyl ester, (-)- Phosphonothioic acid, methyl-, O-(p-nitrophenyl) S-propyl ester, (-)- S-Propyl-p-nitrophenyl methylphosphonothiolate, (-)-
CWCEC	7324-36-9	2B04	C11H16NO4PS	Phosphonothioic acid, methyl-, S-butyl O-(4-nitrophenyl) ester, (+)- Phosphonothioic acid, methyl-, S-butyl O-(p-nitrophenyl) ester, (+)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	7324-37-0	2B04	C11H16NO4PS	Phosphonothioic acid, methyl-, S-butyl O-(4-nitrophenyl) ester, (-)- Phosphonothioic acid, methyl-, S-butyl O-(p-nitrophenyl) ester, (-)-
CWCEC	7331-88-6	2B04	C4H10ClO2P	Phosphonochloridic acid, ethyl-, ethyl ester, (.+-.)-
CWCEC	7348-83-6	2B04	C8H20O4P2S	Phosphonic acid, ethyl-, anhydride with O-ethyl hydrogen ethylphosphonothioate, ethyl ester Phosphonic acid, ethyl-, monoethyl ester, anhydride with O-ethyl ethylphosphonothioate Phosphonothioic acid, ethyl-, O-ethyl este
CWCEC	7348-85-8	2B04	C6H15O2PS	Phosphonothioic acid, ethyl-, O,S-diethyl ester, (R)- Phosphonothioic acid, ethyl-, O,S-diethyl ester, (-)- (-)-O,S-Diethyl ethylphosphonothioate
CWCEC	7351-19-1	2B04	C13H11Cl2O7PS2	Phosphonic acid, methyl-, diester with p-hydroxybenzenesulfonyl chloride Bis[p-(chlorosulfonyl)phenyl] methylphosphonate Benzenesulfonyl chloride, p-hydroxy-, methylphosphonate (2:1)
CWCEC	7351-34-0	2B04	C4H12NO2P	Phosphonamidic acid, trimethyl-, methyl ester
CWCEC	7364-83-2	2B04	C11H16NO5P	Phosphonic acid, methyl-, 2-methylpropyl 4-nitrophenyl ester Phosphonic acid, methyl-, isobutyl p-nitrophenyl ester Isobutyl p-nitrophenyl methylphosphonate
CWCEC	7369-42-8	2B04	C8H20O6P2	Isohypophosphoric acid, ethyl-, triethyl ester Phosphonic acid, ethyl-, ethyl ester, anhydride with diethyl phosphate Ethyl phosphate, (EtO)2(HO)PO, anhydride with ethyl ethylphosphonate Phosphonic acid, ethyl-, monoethyl ester, anhydride with diethyl pho
CWCEC	7369-43-9	2B04	C8H20O5P2	Diphosphonic acid, diethyl-, diethyl ester Phosphonic acid, ethyl-, anhydride, diethyl ester Phosphonic acid, ethyl-, monoethyl ester, anhydride
CWCEC	7452-34-8	2B04	C13H19O4PS	Benzoic acid, p-hydroxy-, ethyl ester, O-ester with O-ethyl ethylphosphonothioate Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with ethyl p-hydroxybenzoate
CWCEC	7452-35-9	2B04	C12H19O3PS2	Phosphonothioic acid, ethyl-, O-ethyl O-[p-(ethylsulfinyl)phenyl] ester Phenol, p-(ethylsulfinyl)-, O-ester with O-ethyl ethylphosphonothioate
CWCEC	7452-36-0	2B04	C12H17O4PS	Benzoic acid, p-hydroxy-, ethyl ester, O-ester with O-ethyl methylphosphonothioate Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with ethyl p-hydroxybenzoate
CWCEC	7452-41-7	2B04	C11H15O3PS	Phosphonothioic acid, methyl-, O-ethyl ester, O-ester with 4'-hydroxyacetophenone
CWCEC	7452-42-8	2B04	C12H17O3PS	Phosphonothioic acid, ethyl-, O-ethyl ester, O-ester with 4'-hydroxyacetophenone
CWCEC	7526-25-2	2B04	C8H11O3P	Phosphonic acid, methyl-, methyl phenyl ester Methyl phenyl methylphosphonate
PTS-HB	7526-26-3	2B04	C13H13O3P	Phosphonic acid, methyl-, diphenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	7526-28-5	2B04	C10H15O3P	Phosphonic acid, ethyl-, ethyl phenyl ester Dyfoxon
CWCEC	7526-29-6	2B04	C14H15O3P	Phosphonic acid, ethyl-, diphenyl ester Diphenyl ethylphosphonate
CWCEC	7533-75-7	2B04	C8H8Cl2IO2PS	Phosphonothioic acid, methyl-, O-(2,5-dichloro-4-iodophenyl) O-methyl ester Phenol, 2,5-dichloro-4-iodo-, O-ester with O-methyl methylphosphonothioate CIBA C 11046,C 11046
CWCEC	7587-16-8	2B04	C10H12Cl2IO2PS	Phosphonothioic acid, isopropyl-, O-(2,5-dichloro-4-iodophenyl) O-methyl ester
CWCEC	7608-38-0	2B04	C4H10BrOPS	Phosphonobromidothioic acid, ethyl-, O-ethyl ester
CWCEC	7610-97-1	2B04	C5H14NO.CH3FO2P	Choline, methylphosphonofluoridate
CWCEC	7692-20-8	2B04	C12H17BrN3O2PS	Phosphonothioic acid, ethyl-, O-(3-bromo-5,7-dimethylpyrazolo[1,5-a]pyrimidin-2-yl) O-ethyl ester
PTS-HB	7719-09-7	3B14	SHCl	Thionyl chloride
PTS-HB	7719-12-2	3B06	Cl3P	Phosphorus trichloride
CWCEC	7727-44-8	2B04	C6H13O3P	Phosphonic acid, ethyl-, ethyl vinyl ester
CWCEC	7727-45-9	2B04	C7H13O3P	Phosphonic acid, ethyl-, ethenyl 2-propenyl ester
CWCEC	7727-46-0	2B04	C8H17O3P	Phosphonic acid, ethyl-, butyl vinyl ester
CWCEC	7757-44-0	2B04	C7H15O3P	Phosphonic acid, ethyl-, ethenyl propyl ester
CWCEC	7761-77-5	1A01	C4H8FO2P	Phosphonofluoridic acid, methyl-, cyclopropyl ester Cyclopropanol, methylphosphonofluoridate
PTS-HB	7776-66-1	2B04	C4H11O2PS	Phosphonothioic acid, ethyl-, O-ethyl ester
PTS-HB	7784-34-1	2B07	AsCl3	Arsenous trichloride
CWCEC	8071-56-5	2B04	C10H13ClN2.C10H12BrCl2O2PS	Phosphonothioic acid, ethyl-, O-(4-bromo-2,5-dichlorophenyl) O-ethyl ester, mixt. with N'-(4-chloro-2-methylphenyl)-N,N- dimethylmethanimidamide Methanimidamide, N'-(4-chloro-2-methylphenyl)-N,N-dimethyl-, mixt.
PTS-HB	9009-86-3	1A08	W99	Ricins
PTS-HB	10025-67-9	3B12	Cl2S2	Sulfur monochloride
PTS-HB	10025-87-3	3B05	Cl3OP	Phosphorus oxychloride
PTS-HB	10026-13-8	3B07	Cl5P	Phosphorus pentachloride
PTS-HB	10161-84-9	2B04	C10H24NO2PSe	Phosphonoselenoic acid, ethyl-, Se-[2-(diethylamino)ethyl] O-ethyl ester
CWCEC	10177-81-8	2B04	C8H20NO3PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-(2-mercaptopropyl)methanesulfonamide
CWCEC	10177-82-9	2B04	C7H18NO3PS3	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-(2-mercaptoethyl)methanesulfonamide
CWCEC	10177-83-0	2B04	C6H16NO3PS3	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-(2-mercaptoethyl)methanesulfonamide

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	10177-86-3	2B04	$C_7H_{18}NO_3PS_3$	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-(2-mercaptopropyl)methanesulfonamide
CWCEC	10177-87-4	2B04	$C_6H_{16}NO_3PS_3$	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with N-(2-mercaptopropyl)methanesulfonamide
CWCEC	10177-88-5	2B04	$C_7H_{18}NO_3PS_3$	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)ethanesulfonamide
CWCEC	10177-89-6	2B04	$C_7H_{18}NO_3PS_3$	Phosphonodithioic acid, methyl-, O-ethyl ester, S-ester with N-(2-mercaptoethyl)ethanesulfonamide
CWCEC	10177-90-9	2B04	$C_6H_{16}NO_3PS_3$	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)methanesulfonamide
CWCEC	10177-91-0	2B04	$C_6H_{16}NO_3PS_3$	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)ethanesulfonamide
CWCEC	10177-97-6	2B04	$C_5H_{14}NO_3PS_3$	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with N-(2-mercaptoethyl)methanesulfonamide
CWCEC	10221-94-0	2B04	$C_8H_{14}NO_2PS_2$	Phosphonodithioic acid, methyl-, O-methyl ester, S-ester with 2-mercapto-N-methyl-N-2-propynylacetamide
CWCEC	10221-95-1	2B04	$C_9H_{16}NO_2PS_2$	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with 2-mercapto-N-methyl-N-2-propynylacetamide
CWCEC	10262-44-9	2B04	$C_{31}H_{57}O_3P$	5.alpha.-Cholestan-3.beta.-ol, 4,4-dimethyl-, methyl methylphosphonate
CWCEC	10358-95-9	2B04	$C_8H_{11}N_2O_3P$	Picolinaldehyde, oxime methyl methylphosphonate Phosphonic acid, methyl-, methyl ester, (2-pyridylmethylene)amino deriv. Picolinaldehyde, O-(methoxymethylphosphinyl)oxime
CWCEC	10358-96-0	2B04	$C_9H_{13}N_2O_3P$	Picolinaldehyde, oxime ethyl methylphosphonate Picolinaldehyde, O-(ethoxymethylphosphinyl)oxime Phosphonic acid, methyl-, ethyl ester, (2-pyridylmethylene)amino deriv.
CWCEC	10358-97-1	2B04	$C_{10}H_{15}N_2O_3P$	Picolinaldehyde, oxime propyl methylphosphonate Picolinaldehyde, O-(methylpropoxyphosphinyl)oxime Phosphonic acid, methyl-, propyl ester, (2-pyridylmethylene)amino deriv.
CWCEC	10358-98-2	2B04	$C_{10}H_{15}N_2O_3P$	Picolinaldehyde, oxime isopropyl methylphosphonate Picolinaldehyde, O-(isopropoxymethylphosphinyl)oxime Phosphonic acid, methyl-, isopropyl ester, (2-pyridylmethylene)amino deriv.
CWCEC	10368-23-7	2B04	$C_6H_{10}Cl_3O_3P$	Phosphonic acid, ethyl-, 2-chloroethyl 2,2-dichloroethenyl ester Phosphonic acid, ethyl-, 2 chloroethyl 2,2-dichlorovinyl ester Ethanol, 2,2-dichloro-, 2-chloroethyl ethylphosphonate 2-Chloroethyl-2,2-dichlorovinylethylphosphonate
CWCEC	10491-30-2	2B04	$C_6H_{13}Cl_2O_2PS$	Phosphonothioic acid, ethyl-, O,O-bis(2-chloroethyl) ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	10545-71-8	2B04	C15H24NO5P	Phosphonic acid, methyl-, 4-nitrophenyl octyl ester Phosphonic acid, methyl-, p-nitrophenyl octyl ester
PTS-HB	10545-99-0	3B13	Cl2S	Sulfur dichloride
CWCEC	10548-27-3	2B04	C19H37O7P	Phosphonic acid, methyl-, bis[3-(2-ethyl-2-methyl-1,3-dioxolan-4- yl)propyl] ester
CWCEC	10552-86-0	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, O-(1-methylethyl) S-propyl ester Phosphonothioic acid, methyl-, O-isopropyl S-propyl ester
CWCEC	10552-88-2	2B04	C5H13O2PS	Phosphonothioic acid, methyl-, O-methyl S-propyl ester
CWCEC	10552-90-6	2B04	C6H15OPS2	Phosphonodithioic acid, methyl-, O-ethyl S-propyl ester
CWCEC	10552-91-7	2B04	C16H35OPS2	Phosphonodithioic acid, methyl-, O-dodecyl S-propyl ester
CWCEC	10552-92-8	2B04	C7H13OPS2	Phosphonodithioic acid, methyl-, S-propyl O-2-propynyl ester 2-Propyn-1-ol, O-ester with S-propyl methylphosphonodithioite
CWCEC	10552-93-9	2B04	C6H14ClOPS2	Phosphonodithioic acid, methyl-, O-(2-chloroethyl) S-propyl ester Ethanol, 2-chloro-, O-ester with S-propyl methylphosphonodithioate
CWCEC	10566-19-5	2B04	C25H41O12PS	Glucofuranose, 1,2:5,6-di-O-isopropylidene-, methylphosphonothioate, alpha.-D-
CWCEC	10566-20-8	2B04	C25H41O12PS	Galactopyranose, 1,2:3,4-di-O-isopropylidene-, methylphosphonothioate, .alpha.-D-
CWCEC	12327-88-7	1A06	C6H12Cl3N.1/4H.1/16O40 SiW12	Tungstate(4-), [orthosilicato(4-)]hexatriacontaoxododeca-, tetrahydrogen, compd. with 2-chloro-N,N-bis (2-chloroethyl)ethanamine (1:4) Silicic acid (H4SiO4), tungsten complex Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-, [ort
CWCEC	13014-47-6	2B04	C13H20NO5P	Phosphonic acid, methyl-, hexyl 4-nitrophenyl ester Phosphonic acid, methyl-, hexyl p-nitrophenyl ester O-Hexyl p-nitrophenyl methylphosphonate
CWCEC	13019-62-0	2B04	C17H32NO6PS	Glucofuranose, 1,2:5,6-di-O-isopropylidene-, N,N-diethyl-P-methylphosphonamidothioate,.alpha.-D- Phosphonamidothioic acid, N,N-diethyl-P-methyl-, O-ester with 1,2:5,6-di-O-isopropylidene-.alpha.-D-glucofuranose
CWCEC	13062-08-3	2B04	C9H11Cl2O3P	Phosphonic acid, ethyl-, 2,4-dichlorophenyl methyl ester
CWCEC	13062-09-4	2B04	C9H10Cl3O3P	Phosphonic acid, methyl-, ethyl 2,4,5-trichlorophenyl ester Phenol, 2,4,5-trichloro-, ethyl methylphosphonate
CWCEC	13062-16-3	2B04	C10H13Cl2O3P	Phosphonic acid, ethyl-, 2,4-dichlorophenyl ethyl ester
CWCEC	13062-39-0	2B04	C10H12Cl3O2PS	Phosphonothioic acid, isopropyl-, O-methyl O-(2,4,5-trichlorophenyl) ester
CWCEC	13062-50-5	2B04	C10H12Cl3O2PS2	Phosphonothioic acid, methyl-, O-ethyl O-[2,4,6-trichloro-3- (methylthio)phenyl] ester
CWCEC	13063-71-3	2B04	C17H21O2PS	Phosphonothioic acid, ethyl-, O-ethyl O-.alpha.-phenyl-p-tolyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	13063-77-9	2B04	C19H25O2PS	Phosphonothioic acid, ethyl-, O-[p-(.alpha.,.alpha.- dimethylbenzyl)phenyl] O-ethyl ester Phosphonothioic acid, ethyl-, O-ethyl O-.alpha.-phenyl-p-cumenyl ester
CWCEC	13063-81-5	2B04	C17H20NO4PS	Phosphonothioic acid, ethyl-, O-ethyl O-(2-nitro-.alpha.-phenyl-p- tolyl) ester
CWCEC	13063-82-6	2B04	C18H22NO5P	Phosphonic acid, isopropyl-, ethyl 2-nitro-.alpha.-phenyl-p-tolyl ester
PTS-HB	13074-12-9	2B04	C8H10NO4PS	Phosphonothioic acid, methyl-, O-methyl O-(4-nitrophenyl) ester
PTS-HB	13074-13-0	2B04	C9H12NO4PS	Phosphonothioic acid, methyl-, O-methyl O-(3-methyl-4-nitrophenyl) ester
CWCEC	13074-17-4	2B04	C9H12NO5P	Phosphonic acid, methyl-, methyl 3-methyl-4-nitrophenyl ester Phosphonic acid, methyl-, methyl 4-nitro-m-tolyl ester m-Cresol, 4-nitro-, methyl methylphosphonate
CWCEC	13088-83-0	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-propyl ester O-Ethyl S-propyl methylthiophosphonate O-Ethyl S-propyl methylphosphonothioate
CWCEC	13088-84-1	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, S-butyl O-ethyl ester S-Butyl O-ethyl methylphosphonothioate LG 58
CWCEC	13088-89-6	2B04	C12H27O2PS	Phosphonothioic acid, methyl-, O-ethyl S-nonyl ester O-Ethyl S-nonyl methylthiophosphonate
CWCEC	13089-62-8	2B04	C15H28NO8P	Galactopyranose, 1,2:3,4-di-O-isopropylidene-, 2-aminoethyl methylphosphonate, .alpha.-D- Galactopyranose, 1,2:3,4-di-O-isopropylidene-, 2-aminoethyl methylphosphonate
CWCEC	13089-63-9	2B04	C15H28NO8P	Glucofuranose, 1,2:5,6-di-O-isopropylidene-, 2-aminoethyl methylphosphonate, .alpha.-D- Glucofuranose, 1,2:5,6-di-O-isopropylidene-, 2-aminoethyl methylphosphonate
CWCEC	13089-64-0	2B04	C16H30NO8P	Galactopyranose, 1,2:3,4-di-O-isopropylidene-, 2-(methylamino)ethyl methylphosphonate, .alpha.-D-
CWCEC	13089-69-5	2B04	C16H29INO7P	Glucofuranose, 1,2:5,6-di-O-isopropylidene-, N-(2-iodoethyl)-N,P-dimethylphosphonamidate, .alpha.-D- Glucofuranose, 1,2:5,6-di-O-isopropylidene-, N-(2-iodoethyl)-N,P- dimethylphosphonamidate
CWCEC	13104-13-7	2B04	C9H11Cl2O2PS	Phosphonothioic acid, methyl-, O-(2,4-dichlorophenyl) O-ethyl ester Phenol, 2,4-dichloro-, O-ester with O-ethyl methylphosphonothioate BAY 38333
CWCEC	13105-79-8	2B11	C10H8N4O5.C7H17NO	Ethanol, 2-(ethylpropylamino)-, picrolonate
PTS-HB	13105-93-6	2B10	C7H16ClN.ClH	Propylamine, N-(2-chloroethyl)-N-ethyl-, hydrochloride
CWCEC	13106-45-1	2B04	C15H28NO8P.C10H8N4O5	Galactopyranose, 1,2:3,4-di-O-isopropylidene-, 2-aminoethylmethyl-phosphonate,compd. with 3-methyl-4-nitro-1-(p-nitrophenyl)- pyrazol-5-ol (1:1) Galactopyranose, 1,2:3,4-di-O-isopropylidene-, 2-aminoethyl methylphosphonate, picrolonate,
CWCEC	13113-89-8	2B04	C2H6ClOPS	Phosphonochloridothioic acid, methyl-, S-methyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	13113-90-1	2B04	C3H8ClOPS	Phosphonochloridothioic acid, methyl-, S-ethyl ester (Ethylthio)methylphosphinic chloride
CWCEC	13113-91-2	2B04	C4H10ClOPS	Phosphonochloridothioic acid, methyl-, S-propyl ester
CWCEC	13113-92-3	2B04	C3H8ClOPS	Phosphonochloridothioic acid, ethyl-, S-methyl ester
CWCEC	13113-93-4	2B04	C4H10ClOPS	Phosphonochloridothioic acid, ethyl-, S-ethyl ester S-Ethyl ethylchlorophosphonate
CWCEC	13113-94-5	2B04	C5H12ClOPS	Phosphonochloridothioic acid, ethyl-, S-propyl ester
CWCEC	13113-98-9	2B04	C4H10ClOPS	Phosphonochloridothioic acid, methyl-, S-isopropyl ester
CWCEC	13113-99-0	2B04	C5H12ClOPS	Phosphonochloridothioic acid, ethyl-, S-(1-methylethyl) ester Phosphonochloridothioic acid, ethyl-, S-isopropyl ester
CWCEC	13126-64-2	2B04	C5H13OPS2	Phosphonodithioic acid, methyl-, O-methyl S-propyl ester
CWCEC	13172-12-8	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1-methylpentyl ester 2-Hexanol, methylphosphonofluoridate
CWCEC	13172-14-0	1A01	C7H12FO2P	Phosphonofluoridic acid, methyl-, bicyclo[2.2.0]hex-2-yl ester Bicyclo[2.2.0]hexan-2-ol, methylphosphonofluoridate
CWCEC	13200-61-8	1A06	C7H4N2O7.1/2C6H12Cl3N	Salicylic acid, 3,5-dinitro-, compd. with 2,2',2"- trichlorotriethylamine (2:1) Triethylamine, 2,2',2"-trichloro-, bis(3,5-dinitrosalicylate) Salicylic acid, 3,5-dinitro-, compd. with 2,2',2"-trichlorotriethylamine
PTS-HB	13242-44-9	2B12	C4H11NS.ClH	Ethanethiol, 2-(dimethylamino)-, hydrochloride
CWCEC	13254-46-1	1A06	C10H6N2O8S.C6H12Cl3N	2-Naphthalenesulfonic acid, 8-hydroxy-5,7-dinitro-, compd. with 2,2',2"-trichlorotriethylamine (1:1) Triethylamine, 2,2',2"-trichloro-, 8-hydroxy-5,7-dinitro-2-naphthalenesulfonate acid (1:1) 2-Naphthalenesulfonic acid, 8-
CWCEC	13273-12-6	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, 1,1-dimethylethyl ester Phosphonofluoridic acid, methyl-, tert-butyl ester
PTS-HB	13361-94-9	2B04	C11H16NO4PS	Phosphonothioic acid, ethyl-, O-isopropyl O-(p-nitrophenyl) ester
PTS-HB	13413-40-6	2B04	C8H20OP2S4	Phosphonodithioic acid, methyl-, bimol. monoanhydride, S,S-dipropyl ester
CWCEC	13454-59-6	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, pentyl ester
PTS-HB	13538-10-8	2B04	C11H16NO5P	Phosphonic acid, (1-methylethyl)-, ethyl 4-nitrophenyl ester
CWCEC	13915-98-5	1A03	C8H20NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1-methylethyl) ester, (S)- Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-isopropyl ester, (+)-
CWCEC	13915-99-6	1A03	C8H20NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1-methylethyl) ester, (R)- Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-isopropyl ester, (-)-
CWCEC	14618-04-3	1A01	C5H10FO2P	Phosphonofluoridic acid, methyl-, cyclobutyl ester Cyclobutanol, methylphosphonofluoridate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	14618-06-5	2B04	C9H12FO2P	Phosphonofluoridic acid, methyl-, p-methylbenzyl ester Benzyl alcohol, p-methyl-, methylphosphonofluoridate
CWCEC	14618-07-6	2B04	C8H10FO2P	Phosphonofluoridic acid, methyl-, benzyl ester
CWCEC	14618-08-7	2B04	C8H9F2O2P	Phosphonofluoridic acid, methyl-, m-fluorobenzyl ester Benzyl alcohol, m-fluoro-, methylphosphonofluoridate
CWCEC	14618-09-8	2B04	C8H9FNO4P	Phosphonofluoridic acid, methyl-, p-nitrobenzyl ester Benzyl alcohol, p-nitro-, methylphosphonofluoridate
PTS-HB	14655-69-7	2B04	C6H17N2OP	Phosphonic diamide, P-ethyl-N,N,N',N'-tetramethyl-
PTS-HB	14667-53-9	2B04	C10H11ClNO4PS	Phosphonothioic acid, methyl-, O-(2-chloro-2-propenyl) O-(4-nitrophenyl) ester
CWCEC	14719-38-1	1A01	C9H18FO2P	Phosphonofluoridic acid, methyl-, cyclooctyl ester Cyclooctanol, methylphosphonofluoridate
CWCEC	15512-81-9	2B10	C6H14ClN.ClH	2-Propanamine, N-(2-chloroethyl)-N-methyl-, hydrochloride Diethylamine, 2'-chloro-N,1-dimethyl-, hydrochloride
CWCEC	15512-82-0	2B10	C7H16ClN.ClH	*Propylamine, N-(2-chloroethyl)-N,2-dimethyl-, hydrochloride*
PTS-HB	15536-01-3	2B04	C9H12NO5P	Phosphonic acid, ethyl-, methyl 4-nitrophenyl ester
PTS-HB	15715-41-0	2B04	C5H13O2P	Phosphonous acid, methyl-, diethyl ester
PTS-HB	16537-51-2	2B04	C14H18NO3PS2	Phosphonodithioic acid, ethyl-, S-[(1,3-dihydro-1,3-dioxo-2H-isoindol-2-yl)methyl] O-(1-methylethyl) ester
PTS-HB	16537-52-3	2B04	C15H20NO3PS2	Phosphonodithioic acid, ethyl-, S-[(1,3-dihydro-1,3-dioxo-2H-isoindol-2-yl)methyl] O-(2-methylpropyl) ester
CWCEC	17123-07-8	2B06	C11H26NO3P	Phosphoramidic acid, dipropyl-, ethyl propyl ester
CWCEC	17123-10-3	2B06	C12H28NO3P	Phosphoramidic acid, dipropyl-, dipropyl ester
PTS-HB	17579-99-6	2B04	C19H18O3P.I	Phosphorus(1+), methyltriphenoxy-, iodide, (T-4)-
PTS-HB	17581-48-5	2B04	C12H23O4PS3	Butanedioic acid, [[methyl(propylthio)phosphinothioyl]thio]-, diethyl ester
CWCEC	17961-19-2	2B04	C8H20NO2P	Phosphonous acid, methyl-, isobutyl 2-(methylamino)ethyl ester Ethanol, 2-(methylamino), isobutyl methylphosphonate (ester)
CWCEC	17961-20-5	2B04	C8H20NO2P	Phosphonous acid, methyl-, tert-butyl 2-(methylamino)ethyl ester Ethanol, 2-(methylamino)-, tert-butyl methylphosphonate (ester)
CWCEC	17982-54-6	2B04	C14H17N2O2P	Phosphonous acid, ethyl-, bis(m-aminophenyl) ester Phenol, m-amino-, ethylphosphonite (2:1) (ester)
PTS-HB	18005-38-4	2B04	C5H12ClOPS	Phosphonochloridothioic acid, methyl-, O-butyl ester
PTS-HB	18032-95-6	2B04	C6H15OPS2	Phosphonodithioic acid, ethyl-, S,S-diethyl ester
CWCEC	18191-24-7	1A03	C14H33NO2PS.1/2O4S	Ethanaminium, N,N-diethyl-N-methyl-2-[[methyl-(1,2,2-trimethylpropoxy) phosphino]thio]-, sulfate (2:1) Ammonium, diethyl(2-mercaptoethyl)methyl-, sulfate (2:1), S,S-diester with O-(1,2,2-trimethylpropyl) methylphosphonothioate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	18191-25-8	1A03	C14H33NO2PS	Ammonium, diethyl(2-mercaptoethyl)methyl-, S-ester with O-(1,2,2-trimethylpropyl) methyl phosphonothioate
PTS-HB	18278-44-9	2B04	C5H12NO2PS2	Phosphonodithioic acid, methyl-, O-methyl S-[2-(methylamino)-2-oxoethyl] ester
PTS-HB	18300-07-7	2B04	C8H20O2P2S5	Phosphonodithioic acid, ethyl-, S,S'-[thiobis(methylene)] O,O'-dimethyl ester
PTS-HB	18300-10-2	2B04	C10H24O2P2S5	Phosphonodithioic acid, ethyl-, S,S'-[thiobis(methylene)] O,O'-diethyl ester
PTS-HB	18313-91-2	2B04	C11H16NO4PS	Phosphonothioic acid, ethyl-, O-ethyl O-(3-methyl-4-nitrophenyl) ester
CWCEC	18350-57-7	2B04	C3H7ClFOPS	Phosphonofluoridothioic acid, methyl-, S-(2-chloroethyl) ester Ethanethiol, 2-chloro-, methylphosphonofluoridate
CWCEC	18358-34-4	1A01	C6H14FO2P	Phosphonofluoridic acid, ethyl-, butyl ester
CWCEC	18358-36-6	1A01	C6H14FO2P	Phosphonofluoridic acid, propyl-, propyl ester
CWCEC	18358-37-7	1A01	C6H14FO2P	Phosphonofluoridic acid, propyl-, 1-methylethyl ester Phosphonofluoridic acid, propyl-, isopropyl ester
PTS-HB	18425-48-4	2B04	C12H15N2O2PS	Glyoxylonitrile, phenyl-, oxime, O-ethyl ethylphosphonothioate
PTS-HB	18425-49-5	2B04	C12H15N2O3P	Glyoxylonitrile, phenyl-, oxime, ethyl ethylphosphonate
PTS-HB	18466-11-0	2B04	C9H12ClOPS3	Phosphonodithioic acid, methyl-, S-[[(4-chlorophenyl)thio]methyl] O-methyl ester
PTS-HB	18596-51-5	2B04	C11H15Cl2O2PS2	Phosphonodithioic acid, ethyl-, S-[(2,4-dichlorophenoxy)methyl] O-ethyl ester
PTS-HB	18596-67-3	2B04	C12H17Cl2O2PS2	Phosphonodithioic acid, ethyl-, S-[(2,4-dichlorophenoxy)methyl] O-propyl ester
PTS-HB	18729-79-8	2B04	C12H15OPS3	Phosphonodithioic acid, methyl-, O-benzo[b]thien-4-yl S-propyl ester
CWCEC	18755-36-7	2B04	C4H11O3P	Phosphonic acid, methyl-, ethyl methyl ester Ethyl methyl methylphosphonate
PTS-HB	18755-43-6	2B04	C5H13O3P	Phosphonic acid, propyl-, dimethyl ester
CWCEC	18931-89-0	2B06	C10H24NO3P	Phosphoramidic acid, isopropylpropyl-, diethyl ester
PTS-HB	19133-28-9	2B04	C11H13ClNO2PS	Phosphonothioic acid, ethyl-, O-(2-chloroethyl) O-(4-cyanophenyl) ester
CWCEC	19447-69-9	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 2,2-dimethylhexyl ester 1-Hexanol, 2,2-dimethyl-, methylphosphonofluoridate
CWCEC	19447-70-2	2B04	C10H15FNO2P	Phosphonofluoridic acid, methyl-, 2-(N-methylanilino)ethyl ester Ethanol, 2-(N-methylanilino)-, methylphosphonofluoridate (ester)
PTS-HB	19447-71-3	2B04	C11H18FNO2P CH3O4S	Ammonium, (2-hydroxyethyl)dimethylphenyl-, methyl sulfate, methylphosphonofluoridate
CWCEC	19447-72-4	2B04	C6H16FNO2P CH3O4S	Choline, methyl sulfate, methylphosphonofluoridate Phosphonofluoridic acid, ester with choline methyl sulfate
PTS-HB	20395-17-9	2B04	C10H24O4P2S3	Phosphonothioic acid, ethyl-, S,S'-[thiobis(methylene)] O,O'-diethyl ester
CWCEC	20442-53-9	2B04	C5H13O3P	Phosphonic acid, ethyl-, monopropyl ester Phosphonic acid, ethyl-, propyl ester O-Propyl hydrogen ethylphosphonate
PTS-HB	20820-80-8	1A03	C7H18NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-ethyl ester
PTS-HB	20978-45-4	2B04	C11H16NO4PS	Phosphonothioic acid, (1-methylethyl)-, O-ethyl O-(4-nitrophenyl) ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	21068-51-9	1A03	C7H18NO2PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] ester S 27 (pesticide) S-(2-Diethylaminoethyl) hydrogen methylphosphonothiolate
CWCEC	21068-52-0	1A03	C8H20NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1-methylethyl) ester Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-isopropyl ester S-(2-Dimethylaminoethyl) isopropyl methylphosphonothi
PTS-HB	21070-22-4	2B04	C16H16NO7P	Phosphonic acid, methyl-, 2-(4-methoxyphenyl)-2-oxoethyl 4-nitrophenyl ester
PTS-HB	21070-23-5	2B04	C15H13ClNO6P	Phosphonic acid, methyl-, 2-(4-chlorophenyl)-2-oxoethyl 4-nitrophenyl ester
PTS-HB	21161-62-6	2B04	C15H13N2O8P	Phosphonic acid, methyl-, 4-nitrophenyl 2-(4-nitrophenyl)-2-oxoethyl ester
CWCEC	21641-86-1	2B04	C14H33NO2PS.HO4S	Ammonium, diethyl(2-mercaptoethyl)methyl-, hydrogen sulfate, S-ester with O-(1,2,2-trimethylpropyl) methylphosphonothioate Phosphonothioic acid, methyl-, O-(1,2,2-trimethylpropyl) ester, S-ester with diethyl(2-mercaptoethyl)methylammonium hydrog
CWCEC	21738-25-0	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(diethylamino)ethyl] O-ethyl ester O-Ethyl S-diethylaminoethyl ethylphosphonothiolate S-(Diethylamino)ethyl O-ethyl ethylphosphonothioate O-Ethyl S-diethylaminoethyl ethylphosphonothioate VE
PTS-HB	21770-86-5	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] O-ethyl ester
CWCEC	21852-16-4	2B04	C3H10NO2PS	Phosphonothioic acid, methyl-, S-(2-aminoethyl) ester Ethanethiol, 2-amino-, hydrogen methylphosphonate (ester)
PTS-HB	21921-96-0	2B04	C5H13O3P	Phosphonic acid, propyl-, monoethyl ester
PTS-HB	21988-53-4	2B04	C10H25NO5P2S	Phosphoramidic acid, [2-[(methoxymethylphosphinyl)thio]ethyl]-, bis(1-methylethyl) ester
PTS-HB	22068-06-0	2B04	C7H18NOPS	Phosphinothioic acid, methyl-, S-[2-(diethylamino)ethyl] ester
CWCEC	22107-46-6	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, isopentyl ester
PTS-HB	22243-91-0	2B04	C11H12NO3PS2	Phosphonodithioic acid, methyl-, S-[(1,3-dihydro-1,3-dioxo-2H-isoindol-2-yl)methyl] O-methyl ester
CWCEC	22250-42-6	2B06	C10H24NO3P	Phosphoramidic acid, diethyl-, dipropyl ester
PTS-HB	22371-94-4	2B04	C12H18NO4PS	Phosphonothioic acid, isopropyl-, O-isopropyl O-(p-nitrophenyl) ester
CWCEC	22925-94-6	1A03	C10H22NO2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-[2-(dimethylamino)ethyl] ester, (R)- Cyclopentanol, O-ester with S-[2-(dimethylamino)ethyl] methylphosphonothioate, (R)-(-)- Phosphonothioic acid, methyl-, O-cyclopentyl
CWCEC	22925-95-7	1A03	C10H22NO2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-[2-(dimethylamino)ethyl] ester, (S)- Cyclopentanol, O-ester with S-[2-(dimethylamino)ethyl] methylphosphonothioate, S-(+)- Phosphonothioic acid, methyl-, O-cyclopentyl S-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	22925-96-8	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, [R-(R,R)]- Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, (R,R)- 2-Octanol, methylphosphonofluoridate, (R,R)-
CWCEC	22925-97-9	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1-methylheptyl ester
CWCEC	22925-98-0	1A03	C10H22NO2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-[2- (dimethylamino)ethyl] ester
PTS-HB	22956-47-4	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, [R-(R*,R*)]-
PTS-HB	22956-48-5	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, [S-(R*,S*)]-
CWCEC	22974-27-2	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, stereoisomer 2-Octanol, methylphosphonofluoridate, stereoisomer
CWCEC	23306-80-1	2B05	C6H14Cl2NOP	Phosphoramidic dichloride, bis(1-methylethyl)- Phosphoramidic dichloride, diisopropyl-
PTS-HB	24017-17-2	2B04	C14H18NO3PS2	Phosphonodithioic acid, ethyl-, O-propyl ester, S-ester with N-(mercaptomethyl)phthalimide
PTS-HB	24017-18-3	2B04	C14H18NO3PS2	Phosphonodithioic acid, methyl-, O-isobutyl ester, S-ester with N-(mercaptomethyl)phthalimide
PTS-HB	24017-20-7	2B04	C12H14NO3PS2	Phosphonodithioic acid, ethyl-, O-methyl ester, S-ester with N-(mercaptomethyl)phthalimide
PTS-HB	24017-24-1	2B04	C13H16NO3PS2	Phosphonodithioic acid, ethyl-, O-ethyl ester, S-ester with N-(mercaptomethyl)phthalimide
CWCEC	24578-82-3	1A03	C12H29NO2PS.I	Ethanaminium, 2-[(ethoxyethylphosphinyl)thio]-N,N,N-triethyl-, iodide Ammonium, triethyl(2-mercaptoethyl)-, iodide, S-ester with O-ethyl ethylphosphonothioate Phosphonothioic acid, ethyl-, O-ethyl ester, S-ester with trieth
CWCEC	24578-95-8	1A03	C12H29NO2PS	Ammonium, triethyl(2-mercaptoethyl)-, S-ester with O-ethyl ethylphosphonothioate
CWCEC	24590-44-1	2B06	C8H20NO3P	Phosphoramidic acid, diethyl-, methyl propyl ester
CWCEC	24753-11-5	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, [R-(R,S)]- Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, stereoisomer 2-Octanol, methylphosphonofluoridate, stereoisomer
CWCEC	24753-12-6	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, [S-(R,R)]- Phosphonofluoridic acid, methyl-, 1-methylheptyl ester, (S,S)- 2-Octanol, methylphosphonofluoridate, (S,S)-
PTS-HB	24753-15-9	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, [R-(R*,S*)]-
PTS-HB	24753-16-0	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, [S-(R*,R*)]-
PTS-HB	24838-84-4	2B04	C12H18ClOPS2	Phosphonodithioic acid, ethyl-, S-(4-chlorophenyl) O-(2-methylpropyl) ester
PTS-HB	25296-66-6	2B04	C5H13O2P	Phosphinic acid, methyl-, 2-methylpropyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	25537-46-6	2B04	C11H19N2O3PS	Phosphonic acid, ethyl-, ethyl 2-(ethylthio)-6-methyl-4-pyrimidinyl ester
PTS-HB	25918-54-1	2B04	C9H10Cl3O2PS	Phosphonothioic acid, ethyl-, O-methyl O-(2,4,5-trichlorophenyl) ester
CWCEC	26348-64-1	1A03	C9H23NO2PS.I	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy) phosphinyl]thio]-, iodide, (S)- Ammonium, (2-mercaptoethyl)trimethyl-, iodide, S-ester with O-isopropyl methylphosphonothioate, (+)- Phosphonothioic acid, methyl-, O-isopropy
CWCEC	26348-71-0	1A03	C9H23NO2PS.I	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy) phosphinyl]thio]-, iodide, (R)- Phosphonothioic acid, methyl-, O-isopropyl S-ester with (2-mercaptoethyl) trimethylammonium iodide, (R)-(-)- Phosphonothioic acid, methyl-
PTS-HB	26350-28-7	2B04	C4H12NOPS	Phosphonamidothioic acid, P-ethyl-, S-ethyl ester
PTS-HB	26350-29-8	2B04	C3H10NOPS	Phosphonamidothioic acid, P-ethyl-, S-methyl ester
PTS-HB	26350-31-2	2B04	C3H10NPS2	Phosphonamidodithioic acid, P-ethyl-, methyl ester
PTS-HB	26594-06-9	2B04	C10H17N4O4P	Phosphonamidic acid, P-ethyl-N-[[(5-methoxy-2-pyrimidinyl)amino]carbonyl]-, ethyl ester
CWCEC	28364-21-8	1A01	C9H18FO2P	Phosphonofluoridic acid, propyl-, cyclohexyl ester
CWCEC	28464-30-4	2B04	C4H9BrFO2P	Phosphonofluoridic acid, ethyl-, 2-bromoethyl ester Ethanol, 2-bromo-, ethylphosphonofluoridate
CWCEC	28464-31-5	2B04	C5H11BrFO2P	Phosphonofluoridic acid, ethyl-, 2-bromo-1-methylethyl ester 2-Propanol, 1-bromo-, ethylphosphonofluoridate
PTS-HB	29173-31-7	2B04	C7H14NO4PS2	2-Oxa-4-thia-7-aza-3-phosphaoctan-8-oic acid, 3,7-dimethyl-6-oxo-, methyl ester, 3-sulfide
CWCEC	30102-97-7	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, S-[2-(dipropylamino)ethyl] ester Hydrogen S-2-di-n-propylaminoethyl methylphosphonothioate
CWCEC	30496-18-5	2B11	C8H19NO	Ethanol, [bis(1-methylethyl)amino]-
CWCEC	30593-65-8	1A01	C8H18FO2P	Phosphonofluoridic acid, methyl-, 1,3,3-trimethylbutyl ester
CWCEC	30593-70-5	2B04	C5H10FO2P	Phosphonofluoridic acid, methyl-, 1-methylallyl ester
CWCEC	30593-71-6	2B04	C5H8FO2P	Phosphonofluoridic acid, methyl-, 1-methyl-2-propynyl ester
CWCEC	30596-19-1	2B04	C6H10FO2P	Phosphonofluoridic acid, methyl-, 1-methyl-2-butynyl ester
CWCEC	30596-20-4	2B04	C6H15FNO2P	Phosphonofluoridic acid, methyl-, 2-(dimethylamino)-1-methylethyl ester
PTS-HB	32997-23-2	2B04	C3H9Cl3N3P3	1,3,5,2,4,6-Triazatriphosphorine, 2,4,6-trichloro-2,2,4,4,6,6-hexahydro-2,4,6-trimethyl-
PTS-HB	33232-85-8	2B04	C10H15O3P	Phosphonic acid, ethyl-, methyl p-tolyl ester
PTS-HB	33232-87-0	2B04	C9H12ClO3P	Phosphonic acid, ethyl-, p-chlorophenyl methyl ester
PTS-HB	33232-88-1	2B04	C10H12NO3P	Phosphonic acid, ethyl-, methyl ester, ester with p-hydroxybenzonitrile
PTS-HB	33267-37-7	2B04	C10H15O5PS	Phosphonic acid, ethyl-, methyl p-(methylsulfonyl)phenyl ester
PTS-HB	33910-75-7	2B04	C6H15O2PS2	Phosphonothioic acid, methyl-, O-ethyl S-[(ethylthio)methyl] ester
PTS-HB	34255-87-3	2B04	CH5O3P.H3N	Phosphonic acid, methyl-, monoammonium salt

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	34256-71-8	1A03	C5H14NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] ester S-(2-Dimethylaminoethyl) hydrogen methylphosphonthiolate
PTS-HB	34256-72-9	2B04	C12H20NO2PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-(methylphenylamino)ethyl] ester
CWCEC	34388-36-8	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1,2,2-trimethylpropyl) ester Pinacolyl S-(2-dimethylaminoethyl)methylphosphonothioate Pinacolyl S-(2-dimethylaminoethyl)methylphosphonotioate
PTS-HB	35335-60-5	2B04	C10H16NOPS2	Phosphonamidothioic acid, P-ethyl-, O-[3-methyl-4-(methylthio)phenyl] ester
PTS-HB	35523-89-8	1A07	C10H17N7O4	1H,10H-Pyrrolo[1,2-c]purine-10,10-diol, 2,6-diamino-4-[[(aminocarbonyl)oxy]methyl]-3a,4,8,9-tetrahydro-, [3aS-(3a.alpha.,4.alpha.,10aR*)]-
PTS-HB	35575-81-6	2B04	C10H12ClN2O3PS2	Phosphonodithioic acid, methyl-, S-[(6-chloro-2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] O-ethyl ester
PTS-HB	35575-92-9	2B04	C10H12ClN2O3PS2	Phosphonodithioic acid, ethyl-, S-[(6-chloro-2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] O methyl ester
PTS-HB	35614-25-6	2B04	C9H11N2O3PS2	Phosphonodithioic acid, methyl-, O-methyl S-[(2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] ester
PTS-HB	35851-62-8	2B04	C2H7O3P.1/3Al	Phosphonic acid, methyl-, monomethyl ester, aluminum salt
CWCEC	36598-84-2	2B05	C2H6ClFNOP	Phosphoramidic chloride fluoride, dimethyl-
CWCEC	36716-60-6	2B10	C8H18ClN	1-Propanamine, N-(2-chloroethyl)-N-propyl- 2-(Dipropylamino)ethyl chloride 2-(N,N-Dipropylamino)ethyl chloride (2-Chloroethyl)dipropylamine Dipropylamine, N-(2-chloroethyl)- N,N-Dipropyl-2-chloroethylamine
CWCEC	36759-66-7	2B12	C6H15NS	Ethanethiol, 2-[methyl(1-methylethyl)amino]- .beta.-Methylisopropylaminoethane thiol 2-(Isopropylmethylamino)ethanethiol
CWCEC	36759-67-8	2B12	C7H17NS	Ethanethiol, 2-[ethyl(1-methylethyl)amino]- .beta.-Ethylisopropylaminoethane thiol 2-(Ethylisopropylamino)ethanethiol
CWCEC	36759-68-9	2B12	C8H19NS	Ethanethiol, 2-[(1-methylethyl)propylamino]- .beta.-Propyl-isopropylaminoethanethiol
PTS-HB	37419-16-2	2B04	C9H10ClN2O3PS2	Phosphonodithioic acid, methyl-, S-[(6-chloro-2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] O-methyl ester
PTS-HB	37429-95-1	2B04	C11H14ClN2O3PS2	Phosphonodithioic acid, ethyl-, S-[(6-chloro-2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] O ethyl ester
PTS-HB	37840-66-7	2B04	C10H17N2O4PS	Phosphonothioic acid, ethyl-, O-(1,6-dihydro-5-methoxy-1-methyl-6-oxo-4-pyridazinyl) O-ethyl ester
CWCEC	38184-38-2	1A01	C5H10FO2P	Phosphonofluoridic acid, methyl-, cyclobutyl ester, (.+-.)-
CWCEC	38184-39-3	1A01	C6H12FO2P	Phosphonofluoridic acid, methyl-, cyclopentyl ester, (.+-.)-
CWCEC	38184-40-6	1A01	C7H14FO2P	Phosphonofluoridic acid, methyl-, cyclohexyl ester, (.+-.)-
CWCEC	38184-41-7	1A01	C8H16FO2P	Phosphonofluoridic acid, methyl-, cycloheptyl ester, (.+-.)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	38184-42-8	1A01	C9H18FO2P	Phosphonofluoridic acid, methyl-, cyclooctyl ester, (.+-.)-
PTS-HB	38672-36-5	2B04	C8H16Cl3O3P	Phosphonic acid, methyl-, ethyl 5,5,5-trichloropentyl ester
CWCEC	38770-03-5	1A03	C12H29NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1,2,2-trimethylpropoxy)phosphinyl]thio]-
PTS-HB	39928-05-7	1A03	C13H22ClNO2PS.CH3O4S	Benzenaminium, 3-chloro-N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-N,N-dimethyl-, methyl sulfate
PTS-HB	40334-69-8	1A05	C4H4AsCl3	Arsinous chloride, bis(2-chloroethenyl)-
PTS-HB	40334-70-1	1A05	C6H6AsCl3	Arsine, tris(2-chloroethenyl)-
PTS-HB	40618-52-8	2B04	C7H17O2PS	Phosphonothioic acid, ethyl-, S-butyl O-methyl ester
CWCEC	40881-98-9	2B05	C6H14Cl2NOP	Phosphoramidic dichloride, dipropyl- Dipropylphosphoramidoyl dichloride
CWCEC	40882-01-7	2B05	C6H14F2NOP	Phosphoramidic difluoride, dipropyl- Dipropylphosphoramidoyl difluoride
CWCEC	40921-41-3	2B10	C4H10ClN.H	Ethanamine, 2-chloro-N,N-dimethyl-, conjugate acid
PTS-HB	41203-81-0	2B04	C9H20O6P2	Phosphonic acid, methyl-, (5-ethyl-2-methyl-1,3,2-dioxaphosphorinan-5-yl)methyl methyl ester, P-oxide
PTS-HB	41222-33-7	2B04	(C6H11Cl2O3P.C3H9O3P)x	Phosphonic acid, ethenyl-, bis(2-chloroethyl) ester, polymer with dimethyl methylphosphonate
PTS-HB	41294-01-3	2B04	C13H22NO2PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-[methyl(3-methylphenyl)amino]ethyl] ester
PTS-HB	41294-02-4	2B04	C13H22NO3PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-[(3-methoxyphenyl)methylamino]ethyl] ester
PTS-HB	41294-03-5	2B04	C12H19ClNO2PS	Phosphonothioic acid, methyl-, S-[2-[(3-chlorophenyl)methylamino]ethyl] O-ethyl ester
PTS-HB	41294-04-6	2B04	C13H22NO2PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-[methyl(4-methylphenyl)amino]ethyl] ester
PTS-HB	41294-05-7	2B04	C13H22NO3PS	Phosphonothioic acid, methyl-, O-ethyl S-[2-[(4-methoxyphenyl)methylamino]ethyl] ester
PTS-HB	41294-06-8	2B04	C12H19ClNO2PS	Phosphonothioic acid, methyl-, S-[2-[(4-chlorophenyl)methylamino]ethyl] O-ethyl ester
PTS-HB	41294-07-9	1A03	C13H23NO2PS.CH3O4S	Benzenaminium, N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-N,N-dimethyl-, methyl sulfate
PTS-HB	41294-08-0	1A03	C14H25NO2PS.CH3O4S	Benzenaminium, N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-N,N,3-trimethyl-, methyl sulfate
PTS-HB	41294-09-1	1A03	C14H25NO3PS.CH3O4S	Benzenaminium, N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-3-methoxy-N,N-dimethyl-, methyl sulfate
PTS-HB	41294-11-5	1A03	C14H25NO2PS.CH3O4S	Benzenaminium, N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-N,N,4-trimethyl-, methyl sulfate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	41294-12-6	1A03	C14H25NO3PS.CH3O4S	Benzenaminium, N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-4-methoxy-N,N-dimethyl-, methy sulfate
PTS-HB	41294-13-7	1A03	C13H22ClNO2PS.CH3O4S	Benzenaminium, 4-chloro-N-[2-[(ethoxymethylphosphinyl)thio]ethyl]-N,N-dimethyl-, methyl sulfate
CWCEC	41391-21-3	2B04	C9H21PS4	Phosphonotrithioic acid, ethyl-, 1,1-dimethylethyl (ethylthio)methyl ester
CWCEC	41391-36-0	2B04	C6H15PS4	Phosphonotrithioic acid, ethyl-, ethyl (methylthio)methyl ester
CWCEC	41391-37-1	2B04	C6H15PS4	Phosphonotrithioic acid, ethyl-, (ethylthio)methyl methyl ester
CWCEC	41391-44-0	2B04	C9H21PS4	Phosphonotrithioic acid, ethyl-, (ethylthio)methyl 2-methylpropyl ester
PTS-HB	41480-75-5	2B12	C8H19NS.ClH	Ethanethiol, 2-[bis(1-methylethyl)amino]-, hydrochloride
CWCEC	41906-52-9	2B12	C4H11NS.H	Ethanethiol, 2-(dimethylamino)-, conjugate monoacid
PTS-HB	42595-45-9	2B04	C15H31O9P3	Phosphonic acid, methyl-, bis[(5-ethyl-2-methyl-2-oxido-1,3,2-dioxaphosphorinan-5-yl)methyl] ester
CWCEC	44027-79-4	2B04	CH3FO2P	Phosphonofluoridic acid, methyl-, ion(1-)
PTS-HB	44991-89-1	2B04	C6H16FNO2P	Ethanaminium, 2-[(fluoromethylphosphinyl)oxy]-N,N,N-trimethyl-
PTS-HB	50335-09-6	2B04	C13H20Cl2NO2PS	Phosphonothioic acid, ethyl-, O-[2,4-dichloro-6-[(diethylamino)methyl]phenyl] ester
CWCEC	50636-78-7	2B04	C10H15NO.C4H11O2PS	Phosphonothioic acid, (1-methylethyl)-, O-methyl ester, (R)-, compd. with [R-(R,S)]-.alpha.-[1-(methylamino)ethyl]benzenemethanol (1:1) Benzenemethanol, .alpha.-[1-(methylamino)ethyl]-, [R-(R,S)]-, (R)-O-methyl (1-methylethyl)phosphonothioate (
PTS-HB	50782-69-9	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester
PTS-HB	50824-96-9	2B04	C10H23O2PS2	Phosphonothioic acid, ethyl-, S-[2-(ethylthio)ethyl] O-(1-methylpropyl) ester
PTS-HB	50869-34-6	2B04	C11H15Cl2O2PS2	Phosphonodithioic acid, methyl-, O-(2,4-dichlorophenyl) S-(2-ethoxyethyl) ester
CWCEC	50929-96-9	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl]-O-(1- methylpropyl) ester
PTS-HB	50929-97-0	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpropyl) ester, ethanedioate (1:1)
CWCEC	51375-12-3	2B10	C11H12I3NO2.C6H14ClN	Benzenepropanoic acid, 3-amino-.alpha.-ethyl-2,4,6-triiodo-, compd. with 2-chloro-N,N diethylethanamine (1:1) Ethanamine, 2-chloro-N,N-diethyl-, 3-amino-.alpha.-ethyl-2,4,6-triiodobenzenepropanoate Iodopanoic acid 2-diethylaminoethylchloride sa
CWCEC	51446-23-2	1A03	C12H28NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-(1-methylethyl) ester O-Isopropyl S-[2-(diisopropylamino)ethyl] methylthiophosphonate O-Isopropyl S-(2-diisopropylaminoethyl)methylphosphonothioate
CWCEC	51825-50-4	2B04	C13H22NO2PS	Phosphonothioic acid, methyl-, S-[2-(methylphenylamino)ethyl] O-propyl ester
CWCEC	51825-51-5	2B04	C14H24NO2PS	Phosphonothioic acid, methyl-, O-butyl S-[2- (methylphenylamino)ethyl] ester
CWCEC	51825-55-9	2B04	C13H21ClNO2PS	Phosphonothioic acid, methyl-, S-[2-[(4- chlorophenyl)methylamino]ethyl] O-propyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	51825-59-3	2B04	C14H24NO2PS	Phosphonothioic acid, methyl-, S-[2-[methyl(4- methylphenyl)amino]ethyl] O-propyl ester
CWCEC	51825-63-9	2B04	C14H24NO3PS	Phosphonothioic acid, methyl-, S-[2-[(4- methoxyphenyl)methylamino]ethyl] O-propyl ester
CWCEC	51825-64-0	2B04	C15H26NO3PS	Phosphonothioic acid, methyl-, O-butyl S-[2-[(4- methoxyphenyl)methylamino]ethyl] ester
CWCEC	51865-09-9	2B04	C4H11O2PS	Phosphonothioic acid, methyl-, O-ethyl S-methyl ester O-Ethyl S-methyl methylphosphonothioate S-Methyl O-ethyl methylphosphonothionate
CWCEC	52364-45-1	1A03	C12H28NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-propyl ester
CWCEC	52364-46-2	1A03	C13H30NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-butyl ester
CWCEC	52755-18-7	2B04	C13H18FN2O9P	Phosphonofluoridic acid, methyl-, 2-[2-[2-(2,4- dinitrophenoxy)ethoxy]ethoxy]ethyl ester [3,6-Dioxa-(8-(2,4-dinitrophenoxy)octyl]methylphosphonofluoridate
CWCEC	53128-18-0	2B04	C13H21ClNO2PS	Phosphonothioic acid, methyl-, S-[2-[(3- chlorophenyl)methylamino]ethyl] O-propyl ester
CWCEC	53128-19-1	2B04	C14H23ClNO2PS	Phosphonothioic acid, methyl-, O-butyl S-[2-[(3- chlorophenyl)methylamino]ethyl] ester
CWCEC	53128-23-7	2B04	C14H24NO2PS	Phosphonothioic acid, methyl-, S-[2-[methyl(3- methylphenyl)amino]ethyl] O-propyl ester
CWCEC	53128-27-1	2B04	C14H24NO3PS	Phosphonothioic acid, methyl-, S-[2-[(3- methoxyphenyl)methylamino]ethyl] O-propyl ester
CWCEC	53279-98-4	2B06	C7H18NO3P	Phosphoramidic acid, ethylmethyl-, diethyl ester
CWCEC	53438-15-6	2B04	C10H20FO7P	.alpha.-D-Glucopyranoside, methyl 2,3-di-O-methyl-, 6-(methylphosphonofluoridate)
CWCEC	53612-56-9	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpropyl) ester, [S-(R,R)]-
CWCEC	53612-57-0	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl], O-(1-methylpropyl) ester, [S-(R,R)]-, ethanedioate (1:1)
CWCEC	53612-58-1	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpropyl) ester, [R-(R,S)]-
CWCEC	53612-59-2	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl], O-(1-methylpropyl) ester, [R-(R,S)]-, ethanedioate (1:1)
CWCEC	53612-60-5	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpropyl) ester, [S-(R,S)]-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	53612-61-6	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl], O-(1-methylpropyl) ester, [S-(R,S)]-, ethanedioate (1:1)
PTS-HB	53621-79-7	2B04	C9H13O3P	Phosphonic acid. propyl-, monophenyl ester
PTS-HB	53621-95-7	2B04	C4H11O3P	Phosphonic acid propyl-, monomethyl ester
CWCEC	53678-79-8	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpropyl) ester, [R-(R,R)]-
CWCEC	53678-80-1	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl], O-(1-methylpropyl) ester, [R-(R,R)]-, ethanedioate (1:1)
CWCEC	54153-16-1	2B10	C5H12ClN	Ethanamine, 2-chloro-N-ethyl-N-methyl- Diethylamine, 2-chloro-N-methyl-
PTS-HB	54253-87-1	2B04	C10H13N2O3PS2	Phosphonodithioic acid, ethyl-, O-methyl S-[(2-oxooxazolo[4,5-b]pyridin-3(2H)-yl)methyl] ester
CWCEC	55523-55-2	1B10	C9H22NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl ethyl ester
CWCEC	55523-56-3	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, O-[2-(diethylamino)ethyl] O-ethyl ester
CWCEC	55523-57-4	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, O-[2-(diethylamino)ethyl] O-ethyl ester
CWCEC	55785-72-3	1B10	C10H24NO2P	Phosphinic acid, ethyl-, 2-(diethylamino)ethyl ethyl ester
PTS-HB	55931-94-7	2B12	C4H11NS.Na	Ethanethiol, 2-(dimethylamino)-, sodium salt
CWCEC	56217-62-0	1A03	C8H20NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-propyl ester
CWCEC	56217-63-1	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, O-butyl S-[2-(dimethylamino)ethyl] ester
CWCEC	56217-64-2	1A03	C10H24NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-pentyl ester
PTS-HB	56217-65-3	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(2-methylpropyl) ester
CWCEC	56217-66-4	1A03	C10H24NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(2,2-dimethylpropyl) ester
PTS-HB	56217-67-5	1A03	C8H21NO2PS	Ethanaminium, 2-[(ethoxymethylphosphinyl)thio]-N,N,N-trimethyl-
CWCEC	56217-68-6	1A03	C9H23NO2PS	Ethanaminium, N,N,N-trimethyl-2-[(methylpropoxyphosphinyl)thio]-
CWCEC	56217-69-7	1A03	C9H23NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy)phosphinyl]thio]-
CWCEC	56217-70-0	1A03	C10H25NO2PS	Ethanaminium, 2-[(butoxymethylphosphinyl)thio]-N,N,N-trimethyl-
CWCEC	56217-71-1	1A03	C10H25NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(2-methyl-2-propoxy) phosphinyl]thio]-
CWCEC	56217-72-2	1A03	C11H27NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(pentyloxy)phosphinyl]thio]-
CWCEC	56217-73-3	1A03	C11H27NO2PS	Ethanaminium, 2-[[(2,2-dimethylpropoxy)methylphosphinyl]thio]-N,N,N- trimethyl-
CWCEC	57508-11-9	1A06	C6H12Cl3N	Ethanamine, N,N-diethyl-, trichloro deriv. Trichlorotriethylamine TTA
PTS-HB	57856-11-8	1B10	C11H26NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl ethyl ester
CWCEC	57856-12-9	2B04	C17H39N2O2P	Phosphonous acid, methyl-, bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	58109-29-8	2B04	C4H8FO2P	Phosphonofluoridic acid, methyl-, 2-propenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	58259-58-8	1A03	C8H20NO2PS.H	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1-methylethyl) ester, conjugate monoacid
PTS-HB	58259-60-2	2B04	C3H9O2PS	Phosphonothioic acid, methyl-, O,S-dimethyl ester
PTS-HB	58373-29-8	2B04	C20H18F3O6PS	Phosphorane, methyltriphenoxy[[(trifluoromethyl)sulfonyl]oxy]-
PTS-HB	58995-43-0	2B04	C12H14NO2PS	Phosphonothioic acid, methyl-, O-ethyl O-6-quinolinyl ester
CWCEC	60347-38-8	2B04	C14H24NO2PS	Phosphonothioic acid, methyl-, O-butyl S-[2-[(phenylmethyl)amino]ethyl] ester
CWCEC	60347-39-9	2B04	C13H22NO2PS	Phosphonothioic acid, methyl-, S-[2-[(phenylmethyl)amino]ethyl] O-propyl ester
PTS-HB	60671-03-6	2B04	C7H15N2OP	Aziridine, 1,1'-(methylphosphinylidene)bis[2-methyl-
CWCEC	61278-88-4	2B06	C9H22NO3P	Phosphoramidic acid, ethylpropyl-, diethyl ester
CWCEC	61502-63-4	2B11	C8H19NO.C2H4O2	Ethanol, 2-[bis(1-methylethyl)amino]-, acetate (salt) Diisopropylethanolamine acetate
PTS-HB	62246-71-3	2B04	C16H19O2PS	Phosphonothioic acid, methyl-, O-(diphenylmethyl) O-ethyl ester
PTS-HB	62421-46-9	2B04	C10H14ClO2PS	Phosphonothioic acid, ethyl-, S-(4-chlorophenyl) O-ethyl ester
CWCEC	62512-68-9	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-(dipropylamino)ethyl] O-ethyl ester
PTS-HB	62680-05-1	2B04	C10H15O2PS	Phosphonothioic acid, ethyl-, O-ethyl S-phenyl ester, (.+-.)-
PTS-HB	62697-92-1	2B04	C10H15O2PS	Phosphonothioic acid, ethyl-, O-ethyl S-phenyl ester, (R)-
PTS-HB	62742-85-2	2B04	C10H15O2PS	Phosphonothioic acid, ethyl-, O-ethyl S-phenyl ester, (S)-
CWCEC	63051-68-3	2B11	C8H19NO.ClH	Ethanol, 2-[bis(1-methylethyl)amino]-, hydrochloride 2-(Diisopropylamino)ethanol hydrochloride
CWCEC	63210-55-9	2B12	C5H13NS	Ethanethiol, 2-(ethylmethylamino)-
PTS-HB	63815-52-1	2B04	C8H20O4P2S2	Thioisohypophosphoric acid ((HO)2P(S)OP(S)H(OH)), ethyl-, triethyl ester
PTS-HB	63815-53-2	2B04	C13H16NO2PS	Phosphonamidothioic acid, P-methyl-N-(1-naphthalenyloxy)-, O-ethyl ester
PTS-HB	63815-54-3	2B04	C9H15N2O2PS2	Phosphonothioic acid, methyl-, O-[2-(ethylthio)-6-methyl-4-pyrimidinyl] O-methyl ester
PTS-HB	63815-55-4	1A02	C6H13N2O2P	Phosphoramidocyanidic acid, dimethyl-, 1-methylethyl ester
PTS-HB	63815-56-5	1A02	C4H9N2O2P	Phosphoramidocyanidic acid, dimethyl-, methyl ester
PTS-HB	63815-60-1	1A02	C7H15N2O2P	Phosphoramidocyanidic acid, diethyl-, ethyl ester
PTS-HB	63869-13-6	1A04	C5H10Cl2S2	Ethane, 1,1'-[methylenebis(thio)]bis[2-chloro-
PTS-HB	63869-31-8	2B04	C11H16ClOPS3	Phosphonodithioic acid, ethyl-, S-[[(4-chlorophenyl)thio]methyl] O-ethyl ester
PTS-HB	63869-33-0	2B04	C10H13Cl2OPS2	Phosphonodithioic acid, methyl-, O-(2,4-dichlorophenyl) S-propyl ester
PTS-HB	63905-10-2	1A04	C7H14Cl2S2	Propane, 1,3-bis[(2-chloroethyl)thio]-
PTS-HB	63906-39-8	2B04	C8H17O2PS3	Acetic acid, [[methyl(propylthio)phosphinothioyl]thio]-, ethyl ester
PTS-HB	63917-40-8	2B04	C6H18B3P3	1,3,5,2,4,6-Triphosphatriborin, 1,2,3,4,5,6-hexahydro-1,2,3,4,5,6-hexamethyl-
PTS-HB	63918-89-8	1A04	C8H16Cl2OS2	Ethane, 1,1'-oxybis[2-[(2-chloroethyl)thio]-
PTS-HB	63918-90-1	1A04	C6H12Cl2OS2	Ethane, 1,1'-[oxybis(methylenethio)]bis[2-chloro-
PTS-HB	65142-99-6	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-propyl ester, (.+-.)-
PTS-HB	65143-01-3	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, S-butyl O-ethyl ester, (.+-.)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	65143-02-4	2B04	C8H19O2PS	Phosphonothioic acid, methyl-, O-ethyl S-pentyl ester, (.+-.)-
PTS-HB	65143-04-6	2B04	C9H19O2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-propyl ester, (.+-.)-
PTS-HB	65143-05-7	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester, (.+-.)-
PTS-HB	65167-51-3	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-propyl ester, (R)-
PTS-HB	65167-52-4	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-propyl ester, (S)-
PTS-HB	65167-53-5	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-(1-methylethyl) ester, (R)-
PTS-HB	65167-54-6	2B04	C6H15O2PS	Phosphonothioic acid, methyl-, O-ethyl S-(1-methylethyl) ester, (S)-
PTS-HB	65167-55-7	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, S-butyl O-ethyl ester, (R)-
PTS-HB	65167-56-8	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, S-butyl O-ethyl ester, (S)-
PTS-HB	65167-57-9	2B04	C8H19O2PS	Phosphonothioic acid, methyl-, O-ethyl S-pentyl ester, (R)-
PTS-HB	65167-58-0	2B04	C8H19O2PS	Phosphonothioic acid, methyl-, O-ethyl S-pentyl ester, (S)-
PTS-HB	65167-59-1	2B04	C7H15O2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-methyl ester, (R)-
PTS-HB	65167-60-4	2B04	C7H15O2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-methyl ester, (S)-
PTS-HB	65167-61-5	2B04	C9H19O2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-propyl ester, (R)-
PTS-HB	65167-62-6	2B04	C9H19O2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-propyl ester, (S)-
PTS-HB	65167-63-7	2B04	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester, (R)-
PTS-HB	65167-64-8	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester, (S)-
PTS-HB	65331-54-6	2B04	C4H12NOPS	Phosphonamidothioic acid, P-propyl-, S-methyl ester
PTS-HB	65331-56-8	2B04	C7H16NO2PS	Phosphonamidothioic acid, P-ethyl-N-(1-oxopropyl)-, S-ethyl ester
PTS-HB	65659-19-0	2B06	C6H16NO3P	Phosphoramidic acid, diethyl-, dimethyl ester
PTS-HB	66295-44-1	2B04	C7H17O2P	Phosphonous acid, methyl-, bis(1-methylethyl) ester
CWCEC	66348-71-8	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, 1-ethylpropyl ester Alpha
CWCEC	66348-72-9	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, 1-methylpropyl ester, (R,R)-
CWCEC	66348-74-1	1A01	C5H12FO2P	Phosphonofluoridic acid, methyl-, 1-methylpropyl ester, (R,S)-
CWCEC	66429-59-2	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (R,R)-
CWCEC	66429-60-5	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (R,S)-
PTS-HB	67000-88-8	2B04	C21H20FO2P	Phosphonofluoridic acid, methyl-, 4-(1-pyrenyl)butyl ester
PTS-HB	67242-36-8	2B04	C4H12NOPS	Phosphonamidothioic acid, trimethyl-, S-methyl ester
PTS-HB	67242-37-9	2B04	C4H12NOPS	Phosphonamidothioic acid, P-(1-methylethyl)-, S-methyl ester
PTS-HB	67242-39-1	2B04	C5H12NO2PS	Phosphonamidothioic acid, N-acetyl-P-ethyl-, S-methyl ester
PTS-HB	67242-40-4	2B04	C6H14NO2PS	Phosphonamidothioic acid, N-acetyl-P-ethyl-, S-ethyl ester
PTS-HB	67242-41-5	2B04	C6H14NO2PS	Phosphonamidothioic acid, P-ethyl-N-(1-oxopropyl)-, S-methyl ester
PTS-HB	67242-42-6	2B04	C8H18NO2PS	Phosphonamidothioic acid, P-ethyl-N-(1-oxobutyl)-, S-ethyl ester
PTS-HB	67242-43-7	2B04	C7H16NO2PS	Phosphonamidothioic acid, P-ethyl-N-(2-methyl-1-oxopropyl)-, S-methyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	67242-45-9	2B04	C8H18NO2PS	Phosphonamidothioic acid, P-ethyl-N-(1-oxopentyl)-, S-methyl ester
PTS-HB	67242-47-1	2B04	C8H16NO2PS	Phosphonamidothioic acid, P-ethyl-N-(3-methyl-1-oxo-2-butenyl)-, S-methyl ester
PTS-HB	67242-48-2	2B04	C6H14NO2PS	Phosphonamidothioic acid, P-methyl-N-(tetrahydro-2-furanyl)-, S-methyl ester
PTS-HB	67242-50-6	2B04	C4H12NPS2	Phosphonamidodithioic acid, P-ethyl-N-methyl-, methyl ester
PTS-HB	67242-51-7	2B04	C5H14NPS2	Phosphonamidodithioic acid, P-ethyl-N,N-dimethyl-, methyl ester
PTS-HB	67242-52-8	2B04	C2H8NOPS	Phosphonamidothioic acid, P-methyl-, S-methyl ester
PTS-HB	67293-69-0	2B04	C8H11OPS2	Phosphonodithioic acid, ethyl-, S-phenyl ester
PTS-HB	67325-77-3	2B04	(C6H12Cl3O4P.C3H9O3P)	Phosphonic acid, methyl-, dimethyl ester, polymer with tris(2-chloroethyl) phosphate
PTS-HB	67538-57-2	2B04	C4H11O2P	Phosphonous acid, methyl-, mono(1-methylethyl) ester
PTS-HB	67812-17-3	2B04	C8H21O6PSi	Phosphonic acid, methyl-, methyl 3-(trimethoxysilyl)propyl ester
PTS-HB	67845-39-0	2B10	C6H14ClN.H2O4S	Ethanamine, 2-chloro-N,N-diethyl-, sulfate (1:1)
PTS-HB	68391-41-3	2B10	C6H14ClN.1/2H2O4S	Ethanamine, 2-chloro-N,N-diethyl-, sulfate (2:1)
PTS-HB	68640-55-1	2B04	C22H31OPS2	Phosphonodithioic acid, methyl-, S-(diphenylmethyl) O-octyl ester
PTS-HB	68640-57-3	2B04	C16H19OPS2	Phosphonodithioic acid, methyl-, S-(diphenylmethyl) O-ethyl ester
PTS-HB	68957-94-8	2B04	C9H21O6P3	1,3,5,2,4,6-Trioxatriphosphorinane, 2,4,6-tripropyl-, 2,4,6-trioxide
PTS-HB	68957-95-9	2B04	(C9H21O6P3.C2H4O)x	1,3,5,2,4,6-Trioxatriphosphorinane, 2,4,6-tripropyl-, 2,4,6-trioxide, polymer with oxirane
CWCEC	69153-76-0	2B10	C4H10ClN.1/2H2O4S	Ethanamine, 2-chloro-N,N-dimethyl-, sulfate (2:1)
CWCEC	69777-00-0	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-hexyl ester
CWCEC	69777-01-1	2B04	C8H21NO2PS.CH3O4S	Ethanaminium, 2-[(ethoxymethylphosphinyl)thio]-N,N,N-trimethyl-, methyl sulfate
CWCEC	69777-02-2	2B04	C9H23NO2PS.CH3O4S	Ethanaminium, N,N,N-trimethyl-2-[(methylpropoxyphosphinyl)thio]-, methyl sulfate
CWCEC	69777-03-3	2B04	C10H25NO2PS.CH3O4S	Ethanaminium, 2-[(butoxymethylphosphinyl)thio]-N,N,N-trimethyl-, methyl sulfate
CWCEC	69777-04-4	2B04	C11H27NO2PS.CH3O4S	Ethanaminium, N,N,N-trimethyl-2-[[methyl(pentyloxy)phosphinyl]thio]-, methyl sulfate
CWCEC	69777-05-5	2B04	C9H23NO2PS.CH3O4S	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1- methylethoxy)phosphinyl]thio]-, methyl sulfate
CWCEC	69777-06-6	2B04	C10H25NO2PS.CH3O4S	Ethanaminium, N,N,N-trimethyl-2-[[methyl(2- methylpropoxy)phosphinyl]thio]-, methyl sulfate
CWCEC	69777-07-7	2B04	C11H27NO2PS.CH3O4S	Ethanaminium, 2-[[(2,2-dimethylpropoxy)methylphosphinyl]thio]-N,N,N- trimethyl-, methyl sulfate
CWCEC	69777-08-8	2B04	C12H29NO2PS	Ethanaminium, 2-[[(hexyloxy)methylphosphinyl]thio]-N,N,N-trimethyl-
CWCEC	69777-09-9	2B04	C12H29NO2PS.CH3O4S	Ethanaminium, 2-[[(hexyloxy)methylphosphinyl]thio]-N,N,N-trimethyl-, methyl sulfate

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	69777-10-2	2B04	C12H27NO2PS	Ethanaminium, 2-[[(cyclohexyloxy)methylphosphinyl]thio]-N,N,N-trimethyl-
CWCEC	69777-11-3	2B04	C12H27NO2PS.CH3O4S	Ethanaminium, 2-[[(cyclohexyloxy)methylphosphinyl]thio]-N,N,N- trimethyl-, methyl sulfate
CWCEC	69795-06-8	1A03	C11H24NO2PS	Phosphonothioic acid, methyl-, O-cyclohexyl S-[2-(dimethylamino)ethyl] ester
PTS-HB	70055-71-9	2B04	C24H49N2O.C2H6O3P	1-Propanaminium, N,N,N-trimethyl-3-[(1-oxo-9-octadecenyl)amino]-, (Z)-, methyl methylphosphonate
PTS-HB	70715-06-9	2B04	(C3H9O3P.C2H4O.O5P2)x	Phosphonic acid, methyl-, dimethyl ester, polymer with oxirane and phosphorus oxide (P2O5)
PTS-HB	71002-67-0	2B04	C12H18NO5P	Phosphonic acid, ethyl-, butyl 4-nitrophenyl ester
CWCEC	71171-49-8	2B11	C8H19NO.H	Ethanol, 2-[bis(1-methylethyl)amino]-, conjugate monoacid
PTS-HB	71293-83-9	2B04	C11H24NO3P	Phosphonic acid, methyl-, 1-methylethyl 2-(1-piperidinyl)ethyl ester
PTS-HB	71293-85-1	1B10	C13H28NO3P	Phosphonic acid, methyl-, cyclohexyl 2-(diethylamino)ethyl ester
PTS-HB	71293-86-2	1B10	C15H32NO3P	Phosphonic acid, methyl-, cyclohexyl 2-(dipropylamino)ethyl ester
PTS-HB	71293-89-5	1A03	C13H28NO2PS	Phosphonothioic acid, methyl-, O-cyclohexyl S-[2-(diethylamino)ethyl] ester
PTS-HB	71293-92-0	2B04	C11H25N2O2PS	Phosphinothioic acid, methyl-4-morpholinyl-, S-[2-(diethylamino)ethyl] ester
PTS-HB	71410-68-9	2B04	C11H25N2O3P	Phosphinic acid, methyl-4-morpholinyl-, 2-(diethylamino)ethyl ester
PTS-HB	71760-04-8	2B04	C6H16O5P2	Diphosphonic acid, dipropyl-
CWCEC	71802-25-0	2B04	C18H26FN2O4PS	Phosphonofluoridic acid, methyl-, 5-[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]pentyl ester
CWCEC	71840-25-0	2B04	C11H26NO2PS	Phosphonothioic acid, methyl-, O-[2-[bis(1- methylethyl)amino]ethyl] O-ethyl ester
PTS-HB	71840-26-1	1B10	C11H26NO3P	Phosphonic acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl ethyl ester
CWCEC	71877-78-6	2B06	C5H14NO3P	Phosphoramidic acid, dimethyl-, ethyl methyl ester, (S)-
CWCEC	71877-79-7	2B06	C5H14NO3P	Phosphoramidic acid, dimethyl-, ethyl methyl ester, (R)-
CWCEC	72361-27-4	1A06	C6H12Cl3N.C2H4ClNO	Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-, compd. with chloroaziridine monohydroxy deriv. (1:1) Aziridine, chloro-, monohydroxy deriv., compd. with 2-chloro-N,N-bis(2-chloroethyl)ethanamine (1:1)
PTS-HB	72720-11-7	2B04	C12H25O4PS2	7-Oxa-3,5-dithia-6-phosphatetradecanoic acid, 6-methyl-, methyl ester, 6-oxide
PTS-HB	72720-12-8	2B04	C10H21O4PS2	7-Oxa-3,5-dithia-6-phosphadodecanoic acid, 6-methyl-, methyl ester, 6-oxide
PTS-HB	72720-13-9	2B04	C11H23O4PS2	7-Oxa-3,5-dithia-6-phosphatridecanoic acid, 6-methyl-, methyl ester, 6-oxide
PTS-HB	72720-14-0	2B04	C13H27O4PS2	7-Oxa-3,5-dithia-6-phosphapentadecanoic acid, 6-methyl-, methyl ester, 6-oxide
CWCEC	73207-98-4	1A03	C9H22NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] ester
CWCEC	73376-22-4	2B04	C17H24FN2O4PS	Phosphonofluoridic acid, methyl-, 4-[[[5-(dimethylamino)-1-naphthalenyl]sulfonyl]amino]butyl ester
CWCEC	73447-93-5	2B04	C7H16FO4P	Phosphonofluoridic acid, methyl-, 2,3-dihydroxy-2,3-dimethylbutyl ester
PTS-HB	73790-31-5	2B04	C9H17O3P	Phosphonic acid, propyl-, di-2-propenyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

PTS-HB	73790-34-8	2B04	C8H10ClN2OP	1H-1,3,2-Benzodiazaphosphole, 5-chloro-2-ethyl-2,3-dihydro-, 2-oxide
PTS-HB	73790-46-2	2B04	C25H57N3P.Br	Phosphorus(1+), tris(N-butyl-1-butanaminato)methyl-, bromide, (T-4)-
PTS-HB	73790-51-9	2B04	C12H23N.C3H9O2PS	Phosphonothioic acid, methyl-, O-ethyl ester, compd. with N-cyclohexylcyclohexanamine (1:1)
CWCEC	73835-17-3	1A03	C12H28NO2PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester VS
PTS-HB	74038-41-8	2B04	C11H16NO4P	Phosphonic acid, ethyl-, 4-(aminocarbonyl)phenyl ethyl ester
CWCEC	74124-48-4	2B06	C10H24NO3P	Phosphoramidic acid, diethyl-, bis(1-methylethyl) ester Phosphoramidic acid, diethyl-, diisopropyl ester
CWCEC	74195-74-7	1A06	C6H12Cl3N.C3H7ClO2	1,2-Propanediol, 3-chloro-, compd. with 2-chloro-N,N-bis(2-chloroethyl)ethanamine (1:1) Ethanamine, 2-chloro-N,N-bis(2-chloroethyl)-, compd. with 3-chloro-1,2-propanediol (1:1)
PTS-HB	74789-22-3	2B04	C6H13O4PS2	2-Oxa-4,6-dithia-3-phosphaoctan-8-oic acid, 3-methyl-, methyl ester, 3-oxide
PTS-HB	74789-24-5	2B04	C7H15O4PS2	3-Oxa-5,7-dithia-4-phosphanonan-9-oic acid, 4-methyl-, methyl ester, 4-oxide
PTS-HB	74789-25-6	2B04	C8H17O4PS2	3-Oxa-5,7-dithia-4-phosphanonan-9-oic acid, 4-methyl-, ethyl ester, 4-oxide
PTS-HB	74789-26-7	2B04	C10H21O4PS2	3-Oxa-5,7-dithia-4-phosphanonan-9-oic acid, 4-methyl-, 2-methylpropyl ester, 4-oxide
PTS-HB	74789-27-8	2B04	C8H17O4PS2	7-Oxa-3,5-dithia-6-phosphadecanoic acid, 6-methyl-, methyl ester, 6-oxide
PTS-HB	74789-28-9	2B04	C9H19O4PS2	7-Oxa-3,5-dithia-6-phosphaundecanoic acid, 6-methyl-, methyl ester, 6-oxide
PTS-HB	74789-29-0	2B04	C9H19O4PS2	7-Oxa-3,5-dithia-6-phosphadecanoic acid, 6,9-dimethyl-, methyl ester, 6-oxide
PTS-HB	74789-30-3	2B04	C12H25O4PS2	7-Oxa-3,5-dithia-6-phosphadecanoic acid, 6,9-dimethyl-, 2-methylpropyl ester, 6-oxide
CWCEC	75310-28-0	2B04	C7H17O5P	Phosphonic acid, propyl-, bis(2-hydroxyethyl) ester
CWCEC	75354-69-7	2B04	C3H9O2PSe	Phosphonoselenoic acid, methyl-, O,Se-dimethyl ester, (-)-
CWCEC	75354-70-0	2B04	C6H15O2PSe	Phosphonoselenoic acid, ethyl-, O,Se-diethyl ester, (+)-
CWCEC	75390-67-9	2B04	C3H9ClNOPS2	Phosphonamidothioic acid, N-(chlorothio)-N,P-dimethyl-, O-methyl ester
CWCEC	75390-70-4	2B04	C7H17ClNOPS2	Phosphonamidothioic acid, N-(chlorothio)-P-methyl-N-(1-methylethyl)-, O-(1-methylethyl) ester
CWCEC	75425-95-5	2B04	C6H11Cl2O3P	Phosphonic acid, ethyl-, 2,2-dichloroethenyl ethyl ester, (+)-
CWCEC	75425-96-6	2B04	C6H11Cl2O3P	Phosphonic acid, ethyl-, 2,2-dichloroethenyl ethyl ester, (-)-
CWCEC	75897-37-9	2B04	C19H32N5O5PS2	Phosphonothioic acid, methyl-, O-ethyl S-[2-[[2-[[1-oxo-6- (1,2,6,7-tetrahydro-1-methyl-2,6-dioxo-3H-purin-3- yl)hexyl]amino]ethyl]thio]ethyl] ester
CWCEC	75937-39-2	2B04	C29H39N4O6PS2	Phosphonothioic acid, methyl-, S-[2-[[2-[[3-[[4-(2,5-dioxo-4,4- diphenyl-1-imidazolidinyl) 1-oxobutyl]amino]-1- oxopropyl]amino]ethyl]thio]ethyl] O-ethyl ester
CWCEC	76062-13-0	2B04	C6H11O2PS	Phosphonothioic acid, methyl-, O-ethyl S-2-propynyl ester
PTS-HB	76203-96-8	2B04	C9H10Cl3O2PS	Phosphonothioic acid, methyl-, O-ethyl O-(2,4,6-trichlorophenyl) ester
CWCEC	76300-66-8	2B04	C4H6ClOPS	Phosphonochloridothioic acid, methyl-, O-2-propynyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	76300-67-9	2B04	C5H8ClOPS	Phosphonochloridothioic acid, ethyl-, O-2-propynyl ester
CWCEC	76300-68-0	2B04	C5H8ClOPS	Phosphonochloridothioic acid, methyl-, O-(1-methyl-2-propynyl) ester
CWCEC	76341-63-4	2B04	C17H37O3P	Phosphonic acid, methyl-, bis(1-methylheptyl) ester P 350 (extractant) Bis(1-methylheptyl) methylphosphonate
CWCEC	76395-46-5	2B06	C10H24NO3P	Phosphoramidic acid, bis(1-methylethyl)-, diethyl ester
CWCEC	76538-14-2	2B04	C6H11Cl2O2PS	Phosphonothioic acid, methyl-, O-(3,3-dichloro-2-propenyl) O-ethyl ester
CWCEC	76538-18-6	2B04	C7H13PS3	Phosphonotrithioic acid, methyl-, di-2-propenyl ester
CWCEC	76538-24-4	2B04	C6H11OPS2	Phosphonodithioic acid, methyl-, O-ethyl S-2-propynyl ester
CWCEC	76706-96-2	2B04	C7H12ClO2PS	Phosphonothioic acid, methyl-, S-(4-chloro-2-butynyl) O-ethyl ester
CWCEC	76707-02-3	2B04	C8H14ClO2PS	Phosphonothioic acid, methyl-, S-(4-chloro-2-butynyl) O-propyl ester
CWCEC	76707-17-0	2B04	C9H17O2PS2	Phosphonothioic acid, methyl-, O-ethyl S-[4-(ethylthio)-2-butynyl] ester
CWCEC	76707-18-1	2B04	C10H19O2PS2	Phosphonothioic acid, methyl-, S-[4-(ethylthio)-2-butynyl] O-propyl ester
CWCEC	76707-19-2	2B04	C11H21O2PS2	Phosphonothioic acid, methyl-, O-butyl S-[4-(ethylthio)-2-butynyl] ester
CWCEC	76943-34-5	2B04	C15H34O4P2	Diphosphine, tributoxy(1-methylethyl)-, 2-oxide
CWCEC	76949-01-4	2B04	C6H15O4P	Phosphonic acid, propyl-, 2-hydroxyethyl methyl ester
CWCEC	76949-02-5	2B04	C10H24O6P2	Phosphonic acid, propyl-, 1,2-ethanediyl dimethyl ester
CWCEC	77304-63-3	2B04	C13H29O3P	Phosphonic acid, methyl-, dihexyl ester
CWCEC	77304-64-4	2B04	C15H33O3P	Phosphonic acid, methyl-, diheptyl ester Diheptyl methylphosphonate
CWCEC	77375-34-9	2B04	C7H13O5P	Phosphonic acid, methyl-, bis(oxiranylmethyl) ester Phosphonic acid, methyl-, bis(2,3-epoxypropyl) ester Diglycidyl methylphosphonate
CWCEC	77529-46-5	2B04	C6H14ClOPS	Phosphonochloridothioic acid, propyl-, O-(1-methylethyl) ester
CWCEC	77529-50-1	2B04	C6H16O2P2S4	Thioperoxydiphosphonic acid, diethyl-, dimethyl ester
CWCEC	77529-51-2	2B04	C8H20O2P2S4	Thioperoxydiphosphonic acid, diethyl-, diethyl ester
CWCEC	77529-52-3	2B04	C10H24O2P2S4	Thioperoxydiphosphonic acid, diethyl-, dipropyl ester
CWCEC	77529-53-4	2B04	C12H28O2P2S4	Thioperoxydiphosphonic acid, dipropyl-, bis(1-methylethyl) ester
CWCEC	78570-13-5	2B04	C6H14ClPS2	Phosphonochloridodithioic acid, ethyl-, 1,1-dimethylethyl ester S-tert-Butyl ethylphosphonodithioic chloride
CWCEC	78570-14-6	2B04	C8H19OPS2	Phosphonodithioic acid, ethyl-, S-(1,1-dimethylethyl) O-ethyl ester
CWCEC	78570-15-7	2B04	C7H17OPS2	Phosphonodithioic acid, ethyl-, S-(1,1-dimethylethyl) O-methyl ester
CWCEC	78570-16-8	2B04	C6H15OPS2	Phosphonodithioic acid, methyl-, S-(1,1-dimethylethyl) O-methyl ester
CWCEC	78570-17-9	2B04	C7H17OPS2	Phosphonodithioic acid, methyl-, S-(1,1-dimethylethyl) O-ethyl ester
CWCEC	78570-18-0	2B04	C8H19OPS2	Phosphonodithioic acid, methyl-, S-(1,1-dimethylethyl) O-propyl ester
CWCEC	78570-19-1	2B04	C9H21OPS2	Phosphonodithioic acid, ethyl-, S-(1,1-dimethylethyl) O-propyl ester
CWCEC	78570-20-4	2B04	C8H19OPS2	Phosphonodithioic acid, methyl-, S-(1,1-dimethylethyl) O-(1-methylethyl) ester
CWCEC	78570-21-5	2B04	C9H21OPS2	Phosphonodithioic acid, ethyl-, S-(1,1-dimethylethyl) O-(1-methylethyl) ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	78570-22-6	2B04	C7H17OPS2	Phosphonodithioic acid, ethyl-, O-methyl S-(1-methylpropyl) ester
CWCEC	78570-23-7	2B04	C7H17OPS2	Phosphonodithioic acid, ethyl-, O-methyl S-(2-methylpropyl) ester
CWCEC	78570-24-8	2B04	C7H17OPS2	Phosphonodithioic acid, ethyl-, O-ethyl S-(1-methylethyl) ester
CWCEC	78570-25-9	2B04	C8H19OPS2	Phosphonodithioic acid, ethyl-, O-ethyl S-(1-methylpropyl) ester
CWCEC	78570-26-0	2B04	C9H21OPS2	Phosphonodithioic acid, ethyl-, S-(1-methylpropyl) O-propyl ester
CWCEC	78570-27-1	2B04	C10H23OPS2	Phosphonodithioic acid, ethyl-, O,S-bis(1-methylpropyl) ester
CWCEC	79081-03-1	2B04	C4H5N2OPS2	Phosphonic diisothiocyanate, ethyl-
CWCEC	79100-72-4	2B04	C9H21PS3	Phosphonotrithioic acid, ethyl-, 1,1-dimethylethyl propyl ester
CWCEC	79100-73-5	2B04	C8H19PS3	Phosphonotrithioic acid, ethyl-, 1-methylethyl propyl ester
CWCEC	79100-74-6	2B04	C9H21PS3	Phosphonotrithioic acid, ethyl-, butyl propyl ester
CWCEC	79100-75-7	2B04	C9H21PS3	Phosphonotrithioic acid, ethyl-, 1-methylpropyl propyl ester
CWCEC	79106-86-8	2B04	C6H15PS3	Phosphonotrithioic acid, ethyl-, methyl propyl ester
CWCEC	79106-87-9	2B04	C7H17PS3	Phosphonotrithioic acid, ethyl-, ethyl propyl ester
CWCEC	79106-88-0	2B04	C7H17PS3	Phosphonotrithioic acid, ethyl-, ethyl 1-methylethyl ester
CWCEC	79106-89-1	2B04	C9H21PS3	Phosphonotrithioic acid, ethyl-, 1-methylethyl 2-methylpropyl ester
CWCEC	79106-90-4	2B04	C9H21PS3	Phosphonotrithioic acid, ethyl-, 2-methylpropyl propyl ester
CWCEC	79220-12-5	2B04	C5H12ClPS2	Phosphonochloridodithioic acid, methyl-, 1,1-dimethylethyl ester S-tert-Butyl methylphosphonodithioic chloride
CWCEC	79236-71-8	2B04	C3H9O2PS	Phosphonothioic acid, methyl-, O,S-dimethyl ester, (R)-
CWCEC	79236-72-9	2B04	C3H9O2PS	Phosphonothioic acid, methyl-, O,S-dimethyl ester, (S)-
CWCEC	79288-98-5	2B04	C7H9O3P	Phosphonic acid, methyl-, di-2-propynyl ester
CWCEC	79288-99-6	2B04	C5H9O3P	Phosphonic acid, methyl-, methyl 2-propynyl ester Methyl propargyl methanephosphonate
CWCEC	79289-00-2	2B04	C7H9O2PS	Phosphonothioic acid, methyl-, O,O-di-2-propynyl ester
PTS-HB	79351-07-8	2B04	C7H18FNO2P	1-Propanaminium, 3-[(fluoromethylphosphinyl)oxy]-N,N,N-trimethyl-
PTS-HB	79351-08-9	2B04	C7H18FNO2P	1-Propanaminium, 2-[(fluoromethylphosphinyl)oxy]-N,N,N-trimethyl-
CWCEC	79351-18-1	1A03	C12H29NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl[(1- methylpentyl)oxy]phosphinyl]thio]-
CWCEC	79351-19-2	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-(1-methylpentyl) ester
PTS-HB	79494-63-6	2B04	C9H18NO5PS	Glycine, N-[[(ethoxymethylphosphinyl)thio]acetyl]-, ethyl ester, (.+-.)-
PTS-HB	79548-50-8	2B04	C9H18NO5PS	Glycine, N-[[(ethoxymethylphosphinyl)thio]acetyl]-, ethyl ester, (S)-
PTS-HB	79548-51-9	2B04	C9H18NO5PS	Glycine, N-[[(ethoxymethylphosphinyl)thio]acetyl]-, ethyl ester, (R)-
CWCEC	82564-90-7	2B04	C12H20NO2P	Phosphonous acid, ethyl-, ethyl 2-(phenylamino)ethyl ester
CWCEC	82564-91-8	2B04	C16H20NO2P	Phosphonous acid, ethyl-, phenyl 2-(phenylamino)ethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	82721-31-1	1A03	C15H34NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-hexyl ester
CWCEC	82721-32-2	2B04	C11H24NO2PS	Phosphonothioic acid, methyl-, S-[2- (cyclopentylmethylamino)ethyl] O-ethyl ester
CWCEC	82721-33-3	2B04	C12H26NO2PS	Phosphonothioic acid, methyl-, S-[2- (cyclohexylmethylamino)ethyl] O-ethyl ester
CWCEC	82906-79-4	2B04	C20H29N2O2P	Phosphonous acid, ethyl-, bis[2-(methylphenylamino)ethyl] ester
CWCEC	82906-80-7	2B04	C22H33N2O2P	Phosphonous acid, ethyl-, bis[2-(ethylphenylamino)ethyl] ester
PTS-HB	82980-43-6	2B04	C9H13O2PS	Phosphonothioic acid, methyl-, O-methyl O-(3-methylphenyl) ester
PTS-HB	82980-44-7	2B04	C12H19O3PS2	Phosphonothioic acid, (1-methylethyl)-, O-methyl O-[3-methyl-4-(methylsulfinyl)phenyl] ester
CWCEC	83563-66-0	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 2,3-dimethylbutyl ester
PTS-HB	84044-17-7	2B04	C4H11O2PS	Phosphonothioic acid, ethyl-, O,S-dimethyl ester
PTS-HB	84402-58-4	2B04	C2H6N4O.CH5O3P	Phosphonic acid, methyl-, compd. with (aminoiminomethyl)urea (1:1)
PTS-HB	84962-98-1	2B04	C4H13O6PSi.Na	Phosphonic acid, methyl-, mono[3-(trihydroxysilyl)propyl] ester, monosodium salt
PTS-HB	85187-13-9	2B04	C7H17O2P	Phosphinic acid, methyl-, hexyl ester
CWCEC	85473-32-1	1A01	C8H16FO2P	Phosphonofluoridic acid, methyl-, 2-methylcyclohexyl ester
CWCEC	85473-33-2	1A03	C14H30NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-cyclopentyl ester
PTS-HB	87025-52-3	2B04	C6H15O2P	Phosphinic acid, methyl-, pentyl ester
CWCEC	89166-63-2	2B04	C3H10NO2P	Phosphonous acid, methyl-, 2-aminoethyl ester
PTS-HB	89254-45-5	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (1S)-
PTS-HB	89254-46-6	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (1R)-
CWCEC	89280-63-7	2B04	C6H16NO2PS	Phosphonothioic acid, methyl-, O-[2-(dimethylamino)ethyl] S-methyl ester
CWCEC	89893-76-5	2B04	C7H18NO2PS	Phosphonothioic acid, methyl-, O-[2-(dimethylamino)ethyl] S-ethyl ester
PTS-HB	89893-77-6	2B06	C7H18NO3P	Phosphoramidic acid, diethyl-, ethyl methyl ester
PTS-HB	90220-14-7	2B04	C7H17O2PS	Phosphonothioic acid, methyl-, O,S-dipropyl ester
PTS-HB	90220-15-8	2B04	C8H19O2PS	Phosphonothioic acid, ethyl-, O,S-dipropyl ester
PTS-HB	90220-16-9	2B04	C6H15O2PS	Phosphonothioic acid, ethyl-, O-methyl S-propyl ester
PTS-HB	90220-17-0	2B04	C6H15O2PS	Phosphonothioic acid, ethyl-, S-methyl O-propyl ester
PTS-HB	90220-18-1	2B04	C7H17O2PS	Phosphonothioic acid, ethyl-, O-butyl S-methyl ester
PTS-HB	90220-19-2	2B04	C5H13O2PS	Phosphonothioic acid, propyl-, O,S-dimethyl ester
PTS-HB	90245-33-3	2B04	C5H13O2PS	Phosphonothioic acid, ethyl-, S-ethyl O-methyl ester
CWCEC	90272-58-5	2B04	C8H20NO2PS	Phosphonothioic acid, methyl-, O-[2-(diethylamino)ethyl] S-methyl ester
CWCEC	90272-62-1	2B06	C8H20NO3P	Phosphoramidic acid, dipropyl-, dimethyl ester
CWCEC	90644-17-0	2B04	C6H3N3O7.C3H10NO2P	Phosphonous acid, methyl-, 2-aminoethyl ester, picrate
CWCEC	90723-09-4	2B04	C9H22NO2PS	Phosphonothioic acid, methyl-, O-[2-(diethylamino)ethyl] S-ethyl ester
CWCEC	90865-84-2	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (R,R)-(.+-.)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	90865-85-3	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 1,2,2-trimethylpropyl ester, (R,S)-(.+-.)-
CWCEC	90889-18-2	1A03	C4H12NO2PS	Phosphonothioic acid, ethyl-, S-2-aminoethyl ester
CWCEC	91043-34-4	2B06	C10H24NO3P	Phosphoramidic acid, dipropyl-, diethyl ester
CWCEC	91134-95-1	1A03	C10H24NO2PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] O-isopropyl ester
CWCEC	91343-06-5	2B12	C8H19NS.C2H4O2	Ethanethiol, 2-(diisopropylamino)-, acetate
PTS-HB	91772-41-7	2B04	C7H18O4P2S2	Phosphonothioic acid, [[(ethoxyethylphosphinothioyl)oxy]methyl]-, O,O-dimethyl ester
CWCEC	92457-51-7	2B04	C12H15FN3O5P	Phosphonofluoridic acid, methyl-, 5-(7-nitro-2,1,3-benzoxadiazol-4-yl) pentyl ester 2,1,3-Benzoxadiazole, phosphonofluoridic acid deriv. Phosphonofluoridic acid, methyl-, 5-(7-nitro-4-benzofurazanyl)pentyl ester
CWCEC	92460-63-4	2B11	C8H19NO.H	Ethanol, 2-(dipropylamino)-, conjugate monoacid
CWCEC	92813-09-7	2B04	C17H23FNO4PS	Phosphonofluoridic acid, methyl-, 4-[[5-(dimethylamino)-1- naphthalenyl]sulfonyl]butyl ester
CWCEC	92813-45-1	2B04	C16H15FNO2P.ClH	Phosphonofluoridic acid, methyl-, 2-(9-acridinyl)ethyl ester, hydrochloride
CWCEC	92813-46-2	2B04	C16H15FNO2P	Phosphonofluoridic acid, methyl-, 2-(9-acridinyl)ethyl ester
CWCEC	92813-47-3	2B04	C17H17FNO2P.ClH	Phosphonofluoridic acid, methyl-, 3-(9-acridinyl)propyl ester, hydrochloride
CWCEC	92813-48-4	2B04	C18H19FNO2P.ClH	Phosphonofluoridic acid, methyl-, 4-(9-acridinyl)butyl ester, hydrochloride
CWCEC	92813-49-5	2B04	C18H19FNO2P	Phosphonofluoridic acid, methyl-, 4-(9-acridinyl)butyl ester
CWCEC	92813-50-8	2B04	C20H23FNO2P.ClH	Phosphonofluoridic acid, methyl-, 6-(9-acridinyl)hexyl ester, hydrochloride
CWCEC	93240-66-5	1A03	C12H26NO2PS	Phosphonothioic acid, methyl-, O-cyclopentyl S-[2-(diethylamino)ethyl] ester
CWCEC	93957-08-5	1A02	C5H11N2O2P	Phosphoramidocyanidic acid, dimethyl-, ethyl ester, (+)- (+)-Tabun
CWCEC	93957-09-6	1A02	C5H11N2O2P	Phosphoramidocyanidic acid, dimethyl-, ethyl ester, (-)- (-)-Tabun
CWCEC	94854-57-6	2B04	C17H17FNO2P	Phosphonofluoridic acid, methyl-, 3-(9-acridinyl)propyl ester
CWCEC	94854-58-7	2B04	C20H23FNO2P	Phosphonofluoridic acid, methyl-, 6-(9-acridinyl)hexyl ester
PTS-HB	95230-44-7	2B04	C13H17NO3P.I	Quinolinium, 7-[(ethoxymethylphosphinyl)oxy]-1-methyl-, iodide
CWCEC	96142-60-8	2B10	C6H14ClN.ClH	1-Propanamine, N-(2-chloroethyl)-N-methyl-, hydrochloride
CWCEC	96304-84-6	2B04	C9H10FN4O5P	Phosphonofluoridic acid, methyl-, 2-[(7-nitro-2,1,3-benzoxadiazol-4- yl)amino]ethyl ester 2,1,3-Benzoxadiazole, phosphonofluoridic acid deriv. Phosphonofluoridic acid, methyl-, 2-[(7-nitro-4- benzofurazanyl)amino]ethyl ester
CWCEC	96304-85-7	2B04	C12H16FN4O5P	Phosphonofluoridic acid, methyl-, 5-[(7-nitro-2,1,3-benzoxadiazol-4- yl)amino]pentyl ester 2,1,3-Benzoxadiazole, phosphonofluoridic acid deriv. Phosphonofluoridic acid, methyl-, 5-[(7-nitro-4- benzofurazanyl)amino]pentyl ester
CWCEC	97505-35-6	1B09	CH3Cl2OP.CH3F2OP	Phosphonic difluoride, methyl-, mixt. with methylphosphonic dichloride Phosphonic dichloride, methyl-, mixt. contg. methylphosphonic difluoride DIDI
CWCEC	97931-19-6	1A01	C10H22FO2P	Phosphonofluoridic acid, methyl-, 2,2-diethyl-1-methylbutyl ester
CWCEC	97931-20-9	1A01	C8H18FO2P	Phosphonofluoridic acid, ethyl-, 1,2,2-trimethylpropyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	98021-11-5	2B12	C4H11NS.H2O4S	Ethanethiol, 2-dimethylamino-, sulfate
CWCEC	98543-25-0	1A03	C8H20NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-ethyl ester
CWCEC	98543-28-3	2B06	C8H20NO3P	Phosphoramidic acid, dimethyl-, dipropyl ester
CWCEC	99091-66-4	2B04	C17H23FNO4PS.ClH	Phosphonofluoridic acid, methyl-, 4-[[5-(dimethylamino)-1- naphthalenyl]sulfonyl]butyl ester, hydrochloride
CWCEC	99520-56-6	2B06	C7H18NO3P	Phosphoramidic acid, dimethyl-, ethyl 1-methylethyl ester
CWCEC	99858-98-7	2B12	C7H6O2.C4H11NS	Ethanethiol, 2-dimethylamino-, benzoate
CWCEC	99858-99-8	2B12	C7H6O2.C4H11NS ClH	Ethanethiol, 2-dimethylamino-, benzoate, hydrochloride
CWCEC	99991-06-7	1A03	C11H26NO2PS	Phosphonothioic acid, isopropyl-, S-(2-diethylaminoethyl) O-ethyl ester
CWCEC	99991-07-8	1A03	C11H26NO2PS	Phosphonothioic acid, propyl-, S-(2-diethylaminoethyl) O-ethyl ester
CWCEC	101078-31-3	1B10	C11H26NO2P.HI	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl ethyl ester, monohydriodide
CWCEC	101591-77-9	1A03	C10H24NO2PS.C7H8O3S	Phosphonothioic acid, ethyl-, S-(2-diethylaminoethyl) O-ethyl ester, p-toluenesulfonate
CWCEC	101884-85-9	1A03	C11H26NO2PS.C7H8O3S	Phosphonothioic acid, isopropyl-, S-(2-diethylaminoethyl) O-ethyl ester, p-toluenesulfonate
CWCEC	101884-86-0	1A03	C11H26NO2PS.C7H8O3S	Phosphonothioic acid, propyl-, S-(2-diethylaminoethyl) O-ethyl ester, p-toluenesulfonate
CWCEC	102388-57-8	1A01	C3H8FO2P	Phosphonofluoridic acid, methyl-, ethyl ester, (.+-.)-
CWCEC	102388-60-3	1A03	C14H30NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-cyclopentyl ester, (.+-.)-
CWCEC	102490-54-0	1A01	C4H10FO2P	Phosphonofluoridic acid, methyl-, 1-methylethyl ester, (.+-.)-
CWCEC	102490-55-1	1A02	C5H11N2O2P	Phosphoramidocyanidic acid, dimethyl-, ethyl ester, (.+-.)-
CWCEC	102490-57-3	1A03	C14H30NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-cyclopentyl ester, (R)-
CWCEC	102490-59-5	1A03	C14H30NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-cyclopentyl ester, (S)-
PTS-HB	102585-58-0	2B04	C9H19O4PS2	2-Oxa-4,6-dithia-3-phosphaoctan-8-oic acid, 3-methyl-, butyl ester, 3-oxide
CWCEC	102608-93-5	1A06	C6H14O6.xC6H12Cl3N	D-Mannitol, compd. with 2-chloro-N,N-bis(2-chloroethyl)ethanamine Ethanamine, 2-chloro N,N-bis(2-chloroethyl)-, compd. with D-mannitol
PTS-HB	104685-21-4	2B04	C4H11O2PS2	Phosphonothioic acid, methyl-, O-methyl S-[(methylthio)methyl] ester
PTS-HB	104685-22-5	2B04	C6H15O2PS2	Phosphonothioic acid, methyl-, O-methyl S-[[(1-methylethyl)thio]methyl] ester
PTS-HB	104685-23-6	2B04	C7H17O2PS2	Phosphonothioic acid, methyl-, S-[[(1,1-dimethylethyl)thio]methyl] O-methyl ester
PTS-HB	104685-24-7	2B04	C7H17O2PS2	Phosphonothioic acid, methyl-, O-ethyl S-[[(1-methylethyl)thio]methyl] ester
CWCEC	105069-01-0	1A06	C12H24Cl4N2	Piperazinium, 1,1,4,4-tetrakis(2-chloroethyl)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	105069-02-1	1A06	C12H24Cl4N2.2C6H2N3O	1,1,4,4-Tetrakis(2-chloroethyl)piperazinium dipicrate
CWCEC	105143-44-0	2B12	C6H15NS.C6H3N3O7	Ethanethiol, 2-diethylamino-, picrate
CWCEC	106178-29-4	2B04	C4H4F7O2P	Phosphonofluoridic acid, methyl-, 2,2,2-trifluoro-1-(trifluoromethyl)ethyl ester
CWCEC	107059-49-4	1A03	C9H22NO2PS.C7H8O3S	Phosphonothioic acid, methyl-, S-(2-diethylaminoethyl) O-ethyl ester, p-toluenesulfonate
CWCEC	108302-04-1	1A03	C10H24NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-(2-diethylaminoethyl) O-ethyl ester, oxalate
CWCEC	108490-92-2	1A03	C6H16NO2PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-methyl ester
CWCEC	108776-13-2	1A03	C9H22NO2PS.C2H2O4	Phosphonothioic acid, methyl-, S-(2-diethylaminoethyl) O-ethyl ester, oxalate
PTS-HB	109438-26-8	2B04	C14H32O4P2S	Phosphonothioic acid, ethyl-, anhydride with ethyl phosphonic acid, dipentyl ester
CWCEC	109513-85-1	2B11	C8H19NO.C4H6CrN6S4.H	Ethanol, 2-dipropylamino-, reineckate
CWCEC	109654-18-4	2A01	C10H24NO3PS.C6H8O7	Phosphorothioic acid, S-(2-diethylaminoethyl) O,O-diethyl ester, citrate
CWCEC	110422-92-9	1A03	C8H20NO2PS.C2H2O4	Phosphonothioic acid, ethyl-, S-(2-dimethylaminoethyl) O-ethyl ester, oxalate
CWCEC	110501-57-0	2B04	C13H30NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2-[bis(1- methylethyl)amino]ethyl]thio]ethyl] O-ethyl ester
CWCEC	110501-60-5	2B04	C15H34NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-[bis(1-methylethyl)amino]ethyl]thio]ethyl]thio]ethyl] O-ethyl ester
CWCEC	111422-20-9	1A01	C7H14FO2P	Phosphonofluoridic acid, methyi-, cyclohexyl ester, (+)-
CWCEC	111422-21-0	1A01	C7H14FO2P	Phosphonofluoridic acid, methyl-, cyclohexyl ester, (-)-
CWCEC	113548-85-9	1A01	C8H18FO2P	Phosphonofluoridic acid, methyl-, 2-methyl-1-(1-methylethyl)propyi ester
CWCEC	113548-86-0	1A01	C8H16FO2P	Phosphonofluoridic acid, methyl-, 3-methylcyclohexyl ester
CWCEC	113548-87-1	1A01	C8H16FO2P	Phosphonofluoridic acid, methyl-, 4-methylcyclohexyl ester
CWCEC	113548-88-2	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 3-methyl-2-(1-methylethyl)butyl ester
CWCEC	113548-89-3	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, hexyl ester
CWCEC	113848-98-9	2B04	C3H7ClFP	Phosphonous chloride fluoride, (1-methylethyl)- Chlorofluoroisopropylphosphine
CWCEC	114400-90-7	1A03	C8H21NO2PS.HO	(2-Mercaptoethyl)trimethylammonium hydroxide, S-ester with ethyl methylphosphonothioate
CWCEC	114942-11-9	2B04	C20H18FO2P	Phosphonofluoridic acid, methyl-, 3-(1-pyrenyl)propyl ester
CWCEC	115172-04-8	2B04	C3H7Br2P	Phosphohous dibromide, (1-methylethyl)- Dibromoisopropylphosphine Isopropylphosphonous dibromide
CWCEC	115792-08-0	2B04	C7H16FO3P	Phosphonofluoridic acid, methyl-, 2-hydroxy-1,1,2-trimethylpropyl ester
CWCEC	120087-83-4	1A03	C9H23NO2PS.HO	(2-Mercaptoethyl)trimethylammonium hydroxide, S-ester with isopropyl methylphosphonothioate
CWCEC	120394-34-5	1A03	C13H29NO2PS	Ethanaminium, 2-[[(cycloheptyloxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (S)-

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	120394-35-6	1A03	C13H29NO2PS.CH3O3S	Ethanaminium, 2-[[(cycloheptyloxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (S)-, methanesulfonate
CWCEC	120394-36-7	1A03	C13H29NO2PS	Ethanaminium, 2-[[(cycloheptyloxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (R)-
CWCEC	120394-37-8	1A03	C13H29NO2PS.CH3O3S	Ethanaminium, 2-[[(cycloheptyloxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (R)-, methanesulfonate
CWCEC	120394-38-9	1A03	C9H23NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy) phosphinyl]thio]-, (S)-
CWCEC	120394-39-0	1A03	C9H23NO2PS.CH3O3S	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1- methylethoxy)phosphinyl]thio]-, (S)-, methanesulfonate
CWCEC	120394-40-3	1A03	C9H23NO2PS	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy) phosphinyl]thio]-, (R)-
CWCEC	120394-41-4	1A03	C9H23NO2PS.CH3O3S	Ethanaminium, N,N,N-trimethyl-2-[[methyl(1-methylethoxy) phosphinyl]thio]-, (R)-, methanesulfonate
CWCEC	120394-42-5	1A03	C12H29NO2PS	Ethanaminium, 2-[[(3,3-dimethylbutoxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (S)-
CWCEC	120394-43-6	1A03	C12H29NO2PS.CH3O3S	Ethanaminium, 2-[[(3,3-dimethylbutoxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (S)-, methanesulfonate
CWCEC	120394-44-7	1A03	C12H29NO2PS	Ethanaminium, 2-[[(3,3-dimethylbutoxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (R)-
CWCEC	120394-45-8	1A03	C12H29NO2PS.CH3O3S	Ethanaminium, 2-[[(3,3-dimethylbutoxy)methylphosphinyl]thio]-N,N,N- trimethyl-, (R)-, methanesulfonate
CWCEC	120526-54-7	2B11	C16H18N2O5S.C8H19NO	Penicillin V, compd. with 2-diisopropylaminoethanol
CWCEC	121530-43-6	2B04	C9H12FN4O5P	Phosphonofluoridic acid, methyl-, 2-[(7-nitro-2,1,3-benzoxadiazol- 1(3H)-yl)amino]ethyl ester 2,1,3-Benzoxadiazole, phosphonofluoridic acid deriv. Phosphonofluoridic acid, methyl-, 2-[(7-nitro-1(3H)- benzofurazanyl)amino]ethyl ester
CWCEC	121530-44-7	2B04	C12H18FN4O5P	Phosphonofluoridic acid, methyl-, 5-[(7-nitro-2,1,3-benzoxadiazol- 1(3H)-yl)amino]pentyl ester 2,1,3-Benzoxadiazole, phosphonofluoridic acid deriv. Phosphonofluoridic acid, methyl-, 5-[(7-nitro-1(3H)- benzofurazanyl)amino]pentyl ester
CWCEC	122081-90-7	2B06	C6H16NO3P	Phosphoramidic acid, methyl(1-methylethyl)-, dimethyl ester
PTS-HB	125229-70-1	2B04	C4H13O6PSi.Na.W99	Phosphonic acid, methyl-, mono[3-(trihydroxysilyl)propyl] ester, monosodium salt, reaction products with sodium silicate
CWCEC	126204-48-6	1A01	C7H16FO2P	Phosphonofluoridic acid, methyl-, 2-ethylbutyl ester Ebu

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	126314-71-4	2B04	C7H9O2PS.C6H9N3O2	1H-Pyrazole-4-carboxylic acid, 3-amino-, ethyl ester, mono(O-phenyl methylphosphonothioate) Phosphonothioic acid, methyl-, O-phenyl ester, compd. with ethyl 3-amino-1H-pyrazole-4-carboxylate (1:1)
CWCEC	128399-00-8	2A01	C25H22ClNO3.C10H24NO3PS	Benzeneacetic acid, 4-chloro-.alpha.-(1-methylethyl)-, cyano(3-phenoxyphenyl)methyl ester, mixt. with S-[2-(diethylamino)ethyl] O,O-diethyl phosphorothioate Phosphorothioic acid, S-[2-(diethylamino)ethyl] O,O-dieth
CWCEC	128869-78-3	2B04	C11H26NO3PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-ethyl ester, N-oxide
CWCEC	128869-80-7	2B04	C7H18NO3PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] O-ethyl ester, N-oxide
CWCEC	129914-38-1	2B04	C9H21PS4	Phosphonotrithioic acid, ethyl-, butyl (ethylthio)methyl ester
PTS-HB	130713-83-6	2B04	C6H15O2P	Phosphinic acid, methyl-, 2-methylbutyl ester
CWCEC	132412-52-3	1A03	C14H31NO2PS.I	Ethanaminium, 2-[[(cyclohexyloxy)methylphosphinyl]thio]-N,N-diethyl-N-methyl-, iodide
CWCEC	133826-40-1	2B04	C7H8FO2P	Phosphonofluoridic acid, methyl-, phenyl ester
CWCEC	134873-49-7	2B06	C12H28NO3P	Phosphoramidic acid, dipropyl-, bis(1-methylethyl) ester
CWCEC	135445-19-1	1A01	C8H18FO2P	Phosphonofluoridic acid, ethyl-, hexyl ester Hexyl ethylfluorophosphinate Hexyl ethylphosphonofluoridate
CWCEC	135806-85-8	2B04	C13H28FO2P	Phosphonofluoridic acid, methyl-, dodecyl ester
CWCEC	135806-86-9	2B04	C13H26FO2P	Phosphonofluoridic acid, methyl-, 8-dodecenyl ester, (Z)-
CWCEC	138780-00-4	2B04	C5H10FO2P	Phosphonofluoridic acid, methyl-, 2-butenyl ester, (E)- trans-Crotylsarin
PTS-HB	139194-01-7	2B04	C22H54N6O4P2.2I	Phosphorus(1+), .mu.-1,4,10,13-tetraoxa-7,16-diazacyclooctadecane-7,16-diyltetrakis(N-methylmethanaminato)dimethyl-, diiodide
PTS-HB	139194-04-0	2B04	C15H35N3O4P.I	Phosphorus(1+), bis(N-methylmethanaminato)methyl(1,4,7,10-tetraoxa-13-azacyclopentadecanato-N)-, iodide, (T-4)-
PTS-HB	139194-05-1	2B04	C18H42F2N4O4P2.2I	Phosphorus(1+), .mu.-1,4,10,13-tetraoxa-7,16-diazacyclooctadecane-7,16-diyldifluorobis(N-methylmethanaminato)dimethyl-, diiodide
CWCEC	141102-73-0	2B05	C6H14F2NOP	Phosphoramidic difluoride, bis(1-methylethyl)-
CWCEC	141968-54-9	2B06	C6H16NO3P	Phosphoramidic acid, dimethyl-, methyl 1-methylethyl ester
PTS-HB	142868-93-7	1A04	C8H16Cl2S2	Butane, 1,4-bis[(2-chloroethyl)thio]-
PTS-HB	142868-94-8	1A04	C9H18Cl2S2	Pentane, 1,5-bis[(2-chloroethyl)thio]-
CWCEC	144313-52-0	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, octyl ester
CWCEC	148461-87-4	1A02	C8H17N2O2P	Phosphoramidocyanidic acid, dimethyl-, pentyl ester
CWCEC	152405-75-9	1A03	C9H21NO2PS	Phosphonothioic acid, methyl-, S-[2-[bis(1-methylethyl)amino]ethyl] ester, ion(1-)
CWCEC	159395-76-3	1A01	C9H20FO2P	Phosphonofluoridic acid, methyl-, 1,5-dimethylhexyl ester
CWCEC	159395-77-4	1A01	C6H14FO2P	Phosphonofluoridic acid, methyl-, 1,1-dimethylpropyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	159395-78-5	1A01	C10H22FO2P	Phosphonofluoridic acid, methyl-, 1,1-diethyl-2,2-dimethylpropyl ester
CWCEC	159395-79-6	1A01	C11H24FO2P	Phosphonofluoridic acid, methyl-, 1-ethyl-1,5-dimethylhexyl ester
CWCEC	159574-69-3	1B10	C12H28NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl ethyl ester
CWCEC	159939-87-4	1A03	C11H26NO2PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] O-(2-methylpropyl) ester
CWCEC	161935-16-6	1A03	C10H24NO2PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	161935-18-8	1A03	C8H20NO2PS	Phosphonothioic acid, ethyl-, S-[2-(diethylamino)ethyl] ester
CWCEC	162085-82-7	1A01	C8H18FO2P	Phosphonofluoridic acid, methyl-, heptyl ester
CWCEC	162085-83-8	1A01	C6H14FO2P	Phosphonofluoridic acid, ethyl-, 1-methylpropyl ester
CWCEC	162085-84-9	1A01	C7H16FO2P	Phosphonofluoridic acid, ethyl-, pentyl ester
CWCEC	162085-85-0	1A01	C9H20FO2P	Phosphonofluoridic acid, ethyl-, heptyl ester
CWCEC	162085-86-1	1A02	C6H13N2O2P	Phosphoramidocyanidic acid, dimethyl-, propyl ester
CWCEC	162085-87-2	1A02	C7H15N2O2P	Phosphoramidocyanidic acid, dimethyl-, butyl ester
CWCEC	162085-88-3	1A02	C7H15N2O2P	Phosphoramidocyanidic acid, dimethyl-, 2-methylpropyl ester
CWCEC	162085-89-4	1A02	C7H15N2O2P	Phosphoramidocyanidic acid, dimethyl-, 1-methylpropyl ester
CWCEC	162085-90-7	1A02	C9H19N2O2P	Phosphoramidocyanidic acid, dimethyl-, hexyl ester
CWCEC	162085-91-8	1A02	C10H21N2O2P	Phosphoramidocyanidic acid, dimethyl-, heptyl ester
CWCEC	162085-92-9	1A03	C9H22NO2PS	Phosphonothioic acid, ethyl-, S-[2-(dimethylamino)ethyl] O-(1-methylethyl) ester
CWCEC	162085-93-0	1A03	C11H26NO2PS	Phosphonothioic acid, ethyl-, S-[2-(diethylamino)ethyl] O-(1-methylethyl) ester
CWCEC	162085-94-1	1A03	C11H26NO2PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-methyl ester
CWCEC	162085-95-2	1A03	C13H30NO2PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1-methylethyl)amino]ethyl] O-(1-methylethyl) ester
CWCEC	166756-34-9	2B04	C12H22FO2P	Phosphonofluoridic acid, methyl-, 1,4,7,7-tetramethylbicyclo[2.2.1] hept-2-yl ester, [1S [1.alpha.,2.beta.(R),4.alpha.]]-
CWCEC	166756-35-0	1A01	C2H6FO2P	Phosphonofluoridic acid, methyl-, methyl ester, (R)-
CWCEC	167026-89-3	2B04	C12H22FO2P	Phosphonofluoridic acid, methyl-, 1,4,7,7-tetramethylbicyclo[2.2.1] hept-2-yl ester, [1S [1.alpha.,2.beta.(S),4.alpha.]]-
CWCEC	167940-00-3	1B10	C7H18NO2P	Phosphonous acid, methyl-, 2-(dimethylamino)ethyl ethyl ester
CWCEC	169662-44-6	1B10	C10H24NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dimethylamino)ethyl propyl ester
CWCEC	169662-45-7	1B10	C10H24NO2P	Phosphonous acid, propyl-, 2-(dimethylamino)ethyl 1-methylethyl ester
CWCEC	169662-46-8	1B10	C10H24NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl propyl ester
CWCEC	169662-47-9	1B10	C10H24NO2P	Phosphonous acid, propyl-, 2-(diethylamino)ethyl methyl ester
CWCEC	169662-48-0	1B10	C10H24NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dimethylamino)ethyl 1-methylethyl ester
CWCEC	169662-49-1	1B10	C10H24NO2P	Phosphonous acid, propyl-, 2-(dimethylamino)ethyl propyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	169662-50-4	1B10	C10H24NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl 1-methylethyl ester
CWCEC	169662-51-5	1B10	C10H24NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl methyl ester
CWCEC	169662-52-6	1B10	C10H24NO2P	Phosphonous acid, methyl-, 2-(dipropylamino)ethyl methyl ester
CWCEC	169662-53-7	1B10	C10H24NO2P	Phosphonous acid, ethyl-, butyl 2-(dimethylamino)ethyl ester
CWCEC	169662-54-8	1B10	C10H24NO2P	Phosphonous acid, (1-methylethyl)-, 2-(diethylamino)ethyl methyl ester
CWCEC	169662-56-0	2B04	C10H24NO3PS	Phosphonothioic acid, ethyl-, S-[2-(diethylamino)ethyl] O-ethyl ester, N-oxide
CWCEC	169662-57-1	2B04	C10H24NO3PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1- methylethyl)amino]ethyl] ester, N-oxide
CWCEC	169662-63-9	2B04	C11H26NO3PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]sulfinyl]ethyl]thio]ethyl] ester
CWCEC	169662-64-0	2B04	C11H26NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl]thio]ethyl] ester
CWCEC	169662-65-1	1B10	C11H26NO2P	Phosphonous acid, propyl-, butyl 2-(dimethylamino)ethyl ester
CWCEC	169662-66-2	1B10	C11H26NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl 2-methylpropyl ester
CWCEC	169662-67-3	1B10	C11H26NO2P	Phosphonous acid, methyl-, 2-(dimethylamino)ethyl, 1,2,2-trimethylpropyl ester
CWCEC	169662-68-4	1B10	C11H26NO2P	Phosphonous acid, methyl-, butyl 2-(diethylamino)ethyl ester
CWCEC	169662-69-5	1B10	C11H26NO2P	Phosphonous acid, (1-methylethyl)-, 2-(diethylamino)ethyl ethyl ester
CWCEC	169662-70-8	1B10	C11H26NO2P	Phosphonous acid, ethyl-, 2-(dipropylamino)ethyl methyl ester
CWCEC	169662-71-9	1B10	C11H26NO2P	Phosphonous acid, propyl-, 2-(diethylamino)ethyl ethyl ester
CWCEC	169662-72-0	1B10	C11H26NO2P	Phosphonous acid, (1-methylethyl)-, butyl 2-(dimethylamino)ethyl ester
CWCEC	169662-73-1	1B10	C11H26NO2P	Phosphonous acid, methyl-, 2-(dipropylamino)ethyl ethyl ester
CWCEC	169662-74-2	1B10	C11H26NO2P	Phosphonous acid, ethyl-, 2-(diethylamino)ethyl propyl ester
CWCEC	169739-12-2	2B04	C12H28NO3PS2	Phosphonothioic acid, ethyl-, S-[2-[[2- (diethylamino)ethyl]sulfinyl]ethyl] O-ethyl ester
CWCEC	169739-14-4	2B04	C12H28NO4PS2	Phosphonothioic acid, ethyl-, S-[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl] O-ethyl ester
CWCEC	169739-17-7	2B04	C13H22NO2PS	Phosphonothioic acid, ethyl-, O-ethyl S-[2-(methylphenylamino)ethyl] ester
CWCEC	169739-19-9	1B10	C13H30NO2P	Phosphonous acid, propyl-, 2-(dipropylamino)ethyl ethyl ester
CWCEC	169739-20-2	1B10	C13H30NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl 1-methylethyl ester
CWCEC	169739-21-3	1B10	C13H30NO2P	Phosphonous acid, propyl-, butyl 2-(diethylamino)ethyl ester
CWCEC	169739-22-4	1B10	C13H30NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl butyl ester
CWCEC	169739-23-5	1B10	C13H30NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl propyl ester
CWCEC	169739-24-6	1B10	C13H30NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl ethyl ester
CWCEC	169739-25-7	1B10	C13H30NO2P	Phosphonous acid, (1-methylethyl)-, butyl 2-(diethylamino)ethyl ester
CWCEC	169739-26-8	1B10	C13H30NO2P	Phosphonous acid, methyl-, butyl 2-(dipropylamino)ethyl ester
CWCEC	169739-27-9	1B10	C13H30NO2P	Phosphonous acid, propyl-, 2-(dimethylamino)ethyl 1,2,2-trimethylpropyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	169739-28-0	1B10	C13H30NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	169739-29-1	1B10	C13H30NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dimethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	169739-30-4	1B10	C13H30NO2P	Phosphonous acid, ethyl-, 2-(dipropylamino)ethyl propyl ester
CWCEC	169739-31-5	1B10	C13H30NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dipropylamino)ethyl ethyl ester
CWCEC	169739-32-6	1B10	C13H30NO2P	Phosphonous acid, ethyl-, 2-(dipropylamino)ethyl 1-methylethyl ester
CWCEC	169739-33-7	1B10	C13H30NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1- methylethyl)amino]ethyl ethyl ester
CWCEC	169739-34-8	2B04	C13H30NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]thio]ethyl] O-(2-methylpropyl) ester
CWCEC	169739-35-9	2B04	C13H30NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]thio]ethyl]thio]ethyl] O-ethyl ester
CWCEC	169739-36-0	2B04	C13H30NO3PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]sulfinyl]ethyl] O-(2-methylpropyl) ester
CWCEC	169739-37-1	2B04	C13H30NO3PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]sulfinyl]ethyl]thio]ethyl] O-ethyl ester
CWCEC	169739-38-2	2B04	C13H30NO4PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl] O-(2-methylpropyl) ester
CWCEC	169739-39-3	2B04	C13H30NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfinyl]ethyl]sulfinyl]ethyl] O-ethyl ester
CWCEC	169739-40-6	2B04	C13H30NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl]thio]ethyl] O-ethyl ester
CWCEC	169739-41-7	2B04	C13H30NO6PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfonyl]ethyl]sulfonyl]ethyl] O-ethyl ester
CWCEC	169739-42-8	2B04	C13H31N2O2P	Phosphonous acid, methyl-, bis[2-(diethylamino)ethyl] ester
CWCEC	169739-43-9	2B04	C13H31N2O2PS	Phosphonothioic acid, methyl-, O,O-bis[2-(diethylamino)ethyl] ester
CWCEC	169739-58-6	1B10	C14H32NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dipropylamino)ethyl propyl ester
CWCEC	169739-59-7	1B10	C14H32NO2P	Phosphonous acid, propyl-, 2-(dipropylamino)ethyl propyl ester
CWCEC	169739-60-0	1B10	C14H32NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dipropylamino)ethyl 1-methylethyl ester
CWCEC	169797-58-4	1B10	C11H26NO2P	Phosphonous acid, ethyl-, 2-(diethylamino)ethyl 1-methylethyl ester
CWCEC	169797-59-5	1B10	C11H26NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl methyl ester
CWCEC	169797-60-8	2B04	C11H26NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]thio]ethyl] O-ethyl ester
CWCEC	169797-61-9	2B04	C11H26NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (dimethylamino)ethyl]thio]ethyl]thio]ethyl] O ethyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	169797-62-0	2B04	C11H26NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]thio]ethyl]thio]ethyl] ester
CWCEC	169797-64-2	2B04	C11H26NO3PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] O-(2-methylpropyl) ester, N-oxide
CWCEC	169797-65-3	2B04	C11H26NO3PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]sulfinyl]ethyl] O-ethyl ester
CWCEC	169797-68-6	2B04	C11H26NO4PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl] O-ethyl ester
CWCEC	169797-69-7	2B04	C11H26NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfinyl]ethyl]sulfinyl]ethyl] ester
CWCEC	169797-70-0	2B04	C11H26NO6PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfonyl]ethyl]sulfonyl]ethyl] ester
CWCEC	169797-84-6	1B10	C12H28NO2P	Phosphonous acid, propyl-, 2-(diethylamino)ethyl propyl ester
CWCEC	169797-85-7	1B10	C12H28NO2P	Phosphonous acid, propyl-, 2-(diethylamino)ethyl 1-methylethyl ester
CWCEC	169797-86-8	1B10	C12H28NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl propyl ester
CWCEC	169797-87-9	1B10	C12H28NO2P	Phosphonous acid, methyl-, 2-(dipropylamino)ethyl propyl ester
CWCEC	169797-88-0	1B10	C12H28NO2P	Phosphonous acid, propyl-, 2-(dipropylamino)ethyl methyl ester
CWCEC	169797-89-1	1B10	C12H28NO2P	Phosphonous acid, ethyl-, 2-(dipropylamino)ethyl ethyl ester
CWCEC	169797-90-4	1B10	C12H28NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl methyl ester
CWCEC	169797-91-5	1B10	C12H28NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1-methylethyl)amino]ethyl methyl ester
CWCEC	169797-92-6	1B10	C12H28NO2P	Phosphonous acid, ethyl-, butyl 2-(diethylamino)ethyl ester
CWCEC	169797-93-7	1B10	C12H28NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dipropylamino)ethyl methyl ester
CWCEC	169797-94-8	1B10	C12H28NO2P	Phosphonous acid, ethyl-, 2-(dimethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	169797-95-9	1B10	C12H28NO2P	Phosphonous acid, methyl-, 2-(dipropylamino)ethyl 1-methylethyl ester
CWCEC	169797-96-0	1B10	C12H28NO2P	Phosphonous acid, (1-methylethyl)-, 2-(diethylamino)ethyl 1-methylethyl ester
CWCEC	169797-97-1	1B10	C12H28NO2P	Phosphonous acid, (1-methylethyl)-, 2-(diethylamino)ethyl propyl ester
CWCEC	169797-98-2	1B10	C12H28NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl 1-methylethyl ester
CWCEC	169797-99-3	2B04	C12H28NO2PS2	Phosphonothioic acid, ethyl-, S-[2-[[2- (diethylamino)ethyl]thio]ethyl] O-ethyl ester
CWCEC	169798-00-9	2B04	C12H28NO2PS2	Phosphonothioic acid, ethyl-, S-[2-[[2-[bis(1- methylethyl)amino]ethyl]thio]ethyl] ester
CWCEC	169798-01-0	2B06	C12H28NO3P	Phosphoramidic acid, bis(1-methylethyl)-, bis(1-methylethyl) ester
CWCEC	169798-02-1	2B06	C12H28NO3P	Phosphoramidic acid, bis(1-methylethyl)-, dipropyl ester
CWCEC	169798-03-2	2B04	C12H28NO3PS	Phosphonothioic acid, ethyl-, S-[2-[bis(1- methylethyl)amino]ethyl] O-ethyl ester, N-oxide

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	170004-71-4	2B04	C16H36NO2PS3	Phosphonothioic acid, ethyl-, S-[2-[[2-[[2-[bis(1-methylethyl)amino]ethyl]thio]ethyl]thio]ethyl] O-ethyl ester
CWCEC	170004-73-6	1B10	C17H38NO2P	Phosphonous acid, propyl-, 2-(dipropylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170004-74-7	1B10	C17H38NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1- methylethyl)amino]ethyl 1,2,2-trimethylpropyl ester
CWCEC	170004-75-8	1B10	C17H38NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dipropylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170004-76-9	1B10	C17H38NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl 1,2,2-trimethylpropyl ester
CWCEC	170004-77-0	2B04	C17H39N2O2PS	Phosphonothioic acid, methyl-, O,S-bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	170004-85-0	2B04	C18H41N2O2P	Phosphonous acid, ethyl-, bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	170004-86-1	2B04	C18H41N2O2PS	Phosphonothioic acid, ethyl-, O,S-bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	170004-87-2	2B04	C18H41N2O2PS	Phosphonothioic acid, ethyl-, O,O-bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	170005-08-0	2B04	C13H31N2O2PS	Phosphonothioic acid, methyl-, O,S-bis[2-(diethylamino)ethyl] ester
CWCEC	170082-63-0	1B10	C6H16NO2P	Phosphonous acid, methyl-, 2-(dimethylamino)ethyl methyl ester
CWCEC	170082-64-1	2B06	C6H16NO3P	Phosphoramidic acid, dimethyl-, methyl propyl ester
CWCEC	170082-83-4	1B10	C7H18NO2P	Phosphonous acid, ethyl-, 2-(dimethylamino)ethyl methyl ester
CWCEC	170082-84-5	1A03	C7H18NO2PS	Phosphonothioic acid, methyl-, O-[2-(dimethylamino)ethyl] O-ethyl ester
CWCEC	170082-85-6	2B04	C7H18NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2-(dimethylamino)ethyl]thio]ethyl] ester
CWCEC	170082-87-8	2B04	C7H18NO3PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] ester, N-oxide
CWCEC	170135-55-4	2B04	C5H14NO3PS	Phosphonothioic acid, methyl-, S-[2-(dimethylamino)ethyl] ester, N-oxide
CWCEC	170135-68-9	1B10	C14H32NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl 1-methylethyl ester
CWCEC	170135-69-0	1B10	C14H32NO2P	Phosphonous acid, ethyl-, 2-(diethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170135-70-3	2B04	C14H32NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl butyl ester
CWCEC	170135-71-4	1B10	C14H32NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl propyl ester
CWCEC	170135-72-5	2B04	C14H32NO2P	Phosphonous acid, ethyl-, butyl 2-(dipropylamino)ethyl ester
CWCEC	170135-73-6	1B10	C14H32NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1- methylethyl)amino]ethyl propyl ester
CWCEC	170135-74-7	1B10	C14H32NO2P	Phosphonous acid, propyl-, 2-(dipropylamino)ethyl 1-methylethyl ester
CWCEC	170135-76-9	1B10	C14H32NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1- methylethyl)amino]ethyl 1-methylethyl ester
CWCEC	170135-78-1	2B04	C14H32NO2PS2	Phosphonothioic acid, ethyl-, S-[2-[[2-[bis(1- methylethyl)amino]ethyl]thio]ethyl] O-ethyl ester
CWCEC	170135-79-2	2B04	C14H32NO2PS3	Phosphonothioic acid, ethyl-, S-[2-[[2-[[2-[bis(1-methylethyl)amino]ethyl]thio]ethyl]thio]ethyl] ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	170135-80-5	2B04	C14H32NO2PS3	Phosphonothioic acid, ethyl-, S-[2-[[2-[[2- (diethylamino)ethyl]thio]ethyl]thio]ethyl] O-ethyl ester
CWCEC	170135-81-6	2B04	C14H32NO3PS2	Phosphonothioic acid, ethyl-, S-[2-[[2-[bis(1- methylethyl)amino]ethyl]sulfinyl]ethyl] O-ethyl ester
CWCEC	170135-82-7	2B04	C14H32NO4PS2	Phosphonothioic acid, ethyl-, S-[2-[[2-[bis(1- methylethyl)amino]ethyl]sulfonyl]ethyl] O-ethyl ester
CWCEC	170135-83-8	2B04	C14H33N2O2PS	Phosphonothioic acid, ethyl-, O,S-bis[2-(diethylamino)ethyl] ester
CWCEC	170135-84-9	2B04	C14H33N2O2PS	Phosphonothioic acid, ethyl-, O,O-bis[2-(diethylamino)ethyl] ester
CWCEC	170135-88-3	1B10	C15H34NO2P	Phosphonous acid, (1-methylethyl)-, 2-[bis(1- methylethyl)amino]ethyl butyl ester
CWCEC	170135-89-4	1B10	C15H34NO2P	Phosphonous acid, (1-methylethyl)-, 2-(diethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170135-91-8	1B10	C15H34NO2P	Phosphonous acid, propyl-, 2-[bis(1-methylethyl)amino]ethyl butyl ester
CWCEC	170135-92-9	1B10	C15H34NO2P	Phosphonous acid, (1-methylethyl)-, butyl 2-(dipropylamino)ethyl ester
CWCEC	170135-93-0	1B10	C15H34NO2P	Phosphonous acid, propyl-, butyl 2-(dipropylamino)ethyl ester
CWCEC	170135-94-1	1B10	C15H34NO2P	Phosphonous acid, methyl-, 2-[bis(1-methylethyl)amino]ethyl 1,2,2-trimethylpropyl ester
CWCEC	170135-95-2	1B10	C15H34NO2P	Phosphonous acid, methyl-, 2-(dipropylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170135-96-3	2B04	C15H34NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (diethylamino)ethyl]thio]ethyl]thio]ethyl] O-(2-methylpropyl) ester
CWCEC	170135-97-4	2B04	C15H34NO3PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfinyl] ethyl]thio]ethyl] O-(2-methylpropyl) ester
CWCEC	170135-98-5	2B04	C15H34NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfinyl] ethyl]sulfinyl]ethyl] O-(2-methylpropyl) ester
CWCEC	170135-99-6	2B04	C15H34NO6PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfonyl]ethyl] sulfonyl]ethyl] O-(2-methylpropyl) ester
CWCEC	170136-11-5	1B10	C16H36NO2P	Phosphonous acid, ethyl-, 2-[bis(1-methylethyl)amino]ethyl 1,2,2-trimethylpropyl ester
CWCEC	170136-13-7	1B10	C16H36NO2P	Phosphonous acid, ethyl-, 2-(dipropylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170212-43-8	1B10	C15H34NO2P	Phosphonous acid, propyl-, 2-(diethylamino)ethyl 1,2,2-trimethylpropyl ester
CWCEC	170212-44-9	2B04	C15H34NO4PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2-(diethylamino)ethyl]sulfonyl] ethyl]thio]ethyl] O-(2-methylpropyl) ester
CWCEC	170275-37-3	1B10	C8H20NO2P	Phosphonous acid, ethyl-, 2-(dimethylamino)ethyl ethyl ester
CWCEC	170275-38-4	1B10	C8H20NO2P	Phosphonous acid, propyl-, 2-(dimethylamino)ethyl methyl ester
CWCEC	170275-39-5	1B10	C8H20NO2P	Phosphonous acid, methyl-, 2-(dimethylamino)ethyl 1-methylethyl ester
CWCEC	170275-40-8	1B10	C8H20NO2P	Phosphonous acid, methyl-, 2-(dimethylamino)ethyl propyl ester

Composti chimici industriali rientranti nelle "tabelle di composti chimici" della Convenzione sulla proibizione delle armi chimiche

CWCEC	170275-41-9	1B10	C8H20NO2P	Phosphonous acid, methyl-, 2-(diethylamino)ethyl methyl ester
CWCEC	170275-42-0	1B10	C8H20NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dimethylamino)ethyl methyl ester
CWCEC	170275-46-4	2B06	C8H20NO3P	Phosphoramidic acid, bis(1-methylethyl)-, dimethyl ester
CWCEC	170275-62-4	1B10	C9H22NO2P	Phosphonous acid, propyl-, 2-(dimethylamino)ethyl ethyl ester
CWCEC	170275-63-5	1B10	C9H22NO2P	Phosphonous acid, ethyl-, 2-(diethylamino)ethyl methyl ester
CWCEC	170275-64-6	1B10	C9H22NO2P	Phosphonous acid, (1-methylethyl)-, 2-(dimethylamino)ethyl ethyl ester
CWCEC	170275-65-7	1B10	C9H22NO2P	Phosphonous acid, ethyl-, 2-(dimethylamino)ethyl 1-methylethyl ester
CWCEC	170275-66-8	1B10	C9H22NO2P	Phosphonous acid, ethyl-, 2-(dimethylamino)ethyl propyl ester
CWCEC	170425-04-4	2B04	C9H22NO3PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (dimethylamino)ethyl]sulfinyl]ethyl] O-ethyl ester
CWCEC	170425-05-5	2B04	C9H22NO3PS	Phosphonothioic acid, methyl-, S-[2-(diethylamino)ethyl] O-ethyl ester, N-oxide
CWCEC	170425-07-7	2B04	C9H22NO2PS3	Phosphonothioic acid, methyl-, S-[2-[[2-[[2- (dimethylamino)ethyl]thio]ethyl]thio]ethyl] ester
CWCEC	170425-08-8	2B04	C9H22NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2-(dimethylamino)ethyl]thio]ethyl] O-ethyl ester
CWCEC	170425-09-9	2B04	C9H22NO2PS2	Phosphonothioic acid, methyl-, S-[2-[[2-(diethylamino)ethyl]thio]ethyl] ester
CWCEC	170425-11-3	1B10	C9H22NO2P	Phosphonous acid, methyl-, butyl 2-(dimethylamino)ethyl ester
CWCEC	170425-23-7	2B04	C9H23N2O2PS	Phosphonothioic acid, methyl-, O,S-bis[2-(dimethylamino)ethyl] ester
CWCEC	170425-24-8	2B04	C9H23N2O2PS	Phosphonothioic acid, methyl-, O,O-bis[2-(dimethylamino)ethyl] ester
CWCEC	170425-25-9	2B04	C9H23N2O2P	Phosphonous acid, methyl-, bis[2-(dimethylamino)ethyl] ester
CWCEC	170425-26-0	2B04	C9H22NO4PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (dimethylamino)ethyl]sulfonyl]ethyl] O-ethyl ester
CWCEC	170425-27-1	2B04	C9H22NO4PS2	Phosphonothioic acid, methyl-, S-[2-[[2- (diethylamino)ethyl]sulfonyl]ethyl] ester
CWCEC	170425-29-3	2B04	C9H22NO3PS2	Phosphonothioic acid, methyl-, S-[2-[[2-(diethylamino)ethyl] sulfinyl]ethyl] ester
CWCEC	170800-77-8	1A03	C9H22NO2PS	Phosphonothioic acid, ethyl-, S-[2-(diethylamino)ethyl] O-methyl ester
CWCEC	171485-84-0	2B04	C17H39N2O2PS	Phosphonothioic acid, methyl-, O,O-bis[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	171741-05-2	2B04	C4H9ClFO2P	Phosphonofluoridic acid, ethyl-, 2-chloroethyl ester
CWCEC	171741-06-3	2B04	C4H9FIO2P	Phosphonofluoridic acid, ethyl-, 2-iodoethyl ester
CWCEC	171741-07-4	1A01	C11H24FO2P	Phosphonofluoridic acid, ethyl-, nonyl ester
CWCEC	171841-16-0	2B04	C7H18NO2PS	Phosphonothioic acid, methyl-, O-[2-(diethylamino)ethyl] ester
CWCEC	171869-91-3	2B04	C10H24NO2PS	Phosphonothioic acid, ethyl-, O-[2-[bis(1-methylethyl)amino]ethyl] ester
CWCEC	172201-98-8	2B04	C5H14NO2PS	Phosphonothioic acid, methyl-, O-[2-(dimethylamino)ethyl] ester

97A2727

MODALITÀ PER LA VENDITA

La «Gazzetta Ufficiale» e tutte le altre pubblicazioni ufficiali sono in vendita al pubblico:
- **presso le Agenzie dell'Istituto Poligrafico e Zecca dello Stato in ROMA: piazza G. Verdi, 10 e via Cavour, 102;**
- **presso le Librerie concessionarie indicate nelle pagine precedenti.**

Le richieste per corrispondenza devono essere inviate all'Istituto Poligrafico e Zecca dello Stato - Direzione Marketing e Commerciale - Piazza G. Verdi, 10 - 00100 Roma, versando l'importo, maggiorato delle spese di spedizione, a mezzo del c/c postale n 387001. Le inserzioni, come da norme riportate nella testata della parte seconda, si ricevono con pagamento anticipato, presso le agenzie in Roma e presso le librerie concessionarie.

PREZZI E CONDIZIONI DI ABBONAMENTO - 1997

Gli abbonamenti annuali hanno decorrenza dal 1° gennaio e termine al 31 dicembre 1997
i semestrali dal 1° gennaio al 30 giugno 1997 e dal 1° luglio al 31 dicembre 1997

PARTE PRIMA - SERIE GENERALE E SERIE SPECIALI
Ogni tipo di abbonamento comprende gli indici mensili

Tipo A - Abbonamento ai fascicoli della serie generale, inclusi tutti i supplementi ordinari:

- annuale	L.	440.000
- semestrale	L.	250.000

Tipo A1 - Abbonamento ai fascicoli della serie generale, inclusi i soli supplementi ordinari contenenti i provvedimenti legislativi:

- annuale	L.	360.000
- semestrale	L.	200.000

Tipo A2 - Abbonamento ai supplementi ordinari contenenti i soli provvedimenti non legislativi:

- annuale	L.	100.000
- semestrale	L.	60.000

Tipo B - Abbonamento ai fascicoli della serie speciale destinata agli atti dei giudizi davanti alla Corte costituzionale:

- annuale	L.	92.500
- semestrale	L.	60.500

Tipo C - Abbonamento ai fascicoli della serie speciale destinata agli atti delle Comunità europee.

- annuale	L.	236.000
- semestrale	L.	130.000

Tipo D - Abbonamento ai fascicoli della serie speciale destinata alle leggi ed ai regolamenti regionali:

- annuale	L.	92.000
- semestrale	L.	59.000

Tipo E - Abbonamento ai fascicoli della serie speciale destinata ai concorsi indetti dallo Stato e dalle altre pubbliche amministrazioni.

- annuale	L.	231.000
- semestrale	L.	126.000

Tipo F - Abbonamento ai fascicoli della serie generale, inclusi tutti i supplementi ordinari, ed ai fascicoli delle quattro serie speciali

- annuale	L.	950.000
- semestrale	L.	514.000

Tipo F1 - Abbonamento ai fascicoli della serie generale inclusi i supplementi ordinari contenenti i provvedimenti legislativi e ai fascicoli delle quattro serie speciali (escluso tipo A2):

- annuale	L.	850.000
- semestrale	L.	450.000

Integrando con la somma di L. 125.000 il versamento relativo al tipo di abbonamento della Gazzetta Ufficiale, *parte prima, prescelto si riceverà anche l'Indice repertorio annuale cronologico per materie 1997.*

Prezzo di vendita di un fascicolo della *serie generale*	L.	1.500
Prezzo di vendita di un fascicolo delle *serie speciali I, II e III*, ogni 16 pagine o frazione	L.	1.500
Prezzo di vendita di un fascicolo della *IV serie speciale Concorsi ed esami*	L.	2.800
Prezzo di vendita di un fascicolo *indici mensili*, ogni 16 pagine o frazione	L.	1.500
Supplementi ordinari per la vendita a fascicoli separati, ogni 16 pagine o frazione	L.	1.500
Supplementi straordinari per la vendita a fascicoli separati, ogni 16 pagine o frazione	L.	1.500

Supplemento straordinario «Bollettino delle estrazioni»

Abbonamento annuale	L.	140.000
Prezzo di vendita di un fascicolo ogni 16 pagine o frazione	L.	1.500

Supplemento straordinario «Conto riassuntivo del Tesoro»

Abbonamento annuale	L.	91.000
Prezzo di vendita di un fascicolo	L.	8.000

Gazzetta Ufficiale su MICROFICHES - 1997
(Serie generale - Supplementi ordinari - Serie speciali)

Abbonamento annuo (52 spedizioni raccomandate settimanali)	L.	1.300.000
Vendita singola: ogni microfiches contiene fino a 96 pagine di Gazzetta Ufficiale	L.	1.500
Contributo spese per imballaggio e spedizione raccomandata (da 1 a 10 microfiches)	L.	4.000

N.B. — Per l'estero i suddetti prezzi sono aumentati del 30%.

PARTE SECONDA - INSERZIONI

Abbonamento annuale	L.	410.000
Abbonamento semestrale	L.	245.000
Prezzo di vendita di un fascicolo, ogni 16 pagine o frazione	L.	1.550

I prezzi di vendita, in abbonamento ed a fascicoli separati, per l'estero, *nonché quelli di vendita dei fascicoli delle* annate arretrate, *compresi i supplementi ordinari e straordinari, sono* raddoppiati.

L'importo degli abbonamenti deve essere versato sul c/c postale n. 387001 intestato all'Istituto Poligrafico e Zecca dello Stato. L'invio dei fascicoli disguidati, che devono essere richiesti entro 30 giorni dalla data di pubblicazione, è subordinato alla trasmissione dei dati riportati sulla relativa fascetta di abbonamento.

Per informazioni o prenotazioni rivolgersi all'Istituto Poligrafico e Zecca dello Stato - Piazza G. Verdi, 10 - 00100 ROMA
abbonamenti ☎ (06) 85082149/85082221 - vendita pubblicazioni ☎ (06) 85082150/85082276 - inserzioni ☎ (06) 85082145/85082189

* 4 1 1 2 5 0 0 8 1 2 9 7 *

L. 12.000